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REVIEW



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Recent progress in B₄C–SiC composite ceramics: processing, microstructure, and mechanical properties

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 B_4C -SiC composite ceramics are a very promising alternative to pure B_4C ceramics and pure SiC ceramics. B_4C -SiC composite ceramics exhibit a combination of the desirable performance of B_4C and SiC. B_4C -SiC composite ceramics are a better candidate material for engineering applications as structural ceramic materials. The sintering performance, microstructure, and mechanical properties of B_4C -SiC composite ceramics are systematically elaborated in this review. Many factors can affect the sintering performance and microstructure of B_4C -SiC composite ceramics; also, the microstructure plays an important role in the mechanical properties of B_4C -SiC composite ceramics are crucial for their applications. Finally, the future development trend of B_4C -SiC composite ceramics as structural ceramic materials is proposed.

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1. Introduction

Both boron carbide (B_4C) and silicon carbide (SiC) have been recognized as important structural ceramic materials due to their outstanding properties, including high melting point,

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ultra-high hardness, high elastic modulus, good wear resistance, low density, excellent chemical stability, high thermal tolerance, etc.¹⁻⁵ Especially, B₄C has a high neutron capacity cross-sectional area and good thermoelectric properties, and SiC has high thermal conductivity, excellent thermal shock resistance, and good oxidation resistance; these properties allow B₄C and SiC to have unique applications, respectively. B₄C and SiC with excellent properties are widely used in the modern high-technology industry, such as mechanical and automotive engineering, hightemperature thermoelectric conversion, tribology, aviation, aerospace, military, chemical industry, nuclear energy, etc.6,7 In particular, the materials with a combination of low density and high hardness are more desirable than the materials without these characteristics; thus, both B₄C and SiC are very suitable for use as lightweight structural materials and rotating tribocomponents.^{8,9} Therefore, compared with other ceramics (Al₂O₃ ceramics, ZrO₂ ceramics, Si₃N₄ ceramics, etc.), B₄C and SiC ceramics serve much better as vehicle armors and rotating rings in mechanical seals. It is noteworthy that B₄C is an acronym for boron carbide, rather than its actual chemical formula, because boron carbide exists over a range of chemical compositions $B_{12+x}C_{3-x}$ (0.06 < x < 1.7).¹⁰⁻¹³

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Despite the numerous advantages of B_4C and SiC ceramics, both pure B_4C ceramics (monolithic B_4C ceramics) and pure SiC ceramics (monolithic SiC ceramics) are difficult to sinter to achieve high densification because of their high covalent bond ratios and oxide film contamination on the raw materials.^{14,15} In the case of no external pressure, extremely high sintering temperatures are necessary to fabricate pure B_4C ceramics and pure SiC ceramics. The high sintering temperature, however,



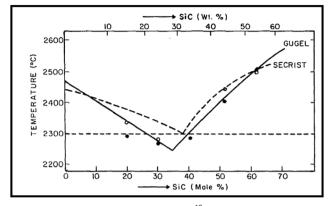


Fig. 1 Binary phase diagram of B_4C-SiC^{19} (reprinted with permission, Copyright 1979, Elsevier).

will induce abnormal grain growth, deteriorating the mechanical properties of ceramics.¹⁶ Currently, the production of pure B_4C ceramics and pure SiC ceramics with high relative density through a pressureless sintering method can be achieved only by adding sintering aids. A variety of additives are used as sintering aids to facilitate the densification of pure B_4C ceramics and pure SiC ceramics. In theory, according to the binary phase diagram of B_4C -SiC (Fig. 1),¹⁷⁻¹⁹ B_4C and SiC can be used as the sintering aid for each other to improve each other's sinterability; thus, the sintering of B_4C -SiC composite ceramics is possible at lower temperatures than pure B_4C ceramics and pure SiC ceramics.

For B₄C ceramics, Thévenot^{20,21} reported that the addition of SiC coupled with C can promote the densification of pressureless sintered B₄C ceramics. The addition of SiC can lead to segregation at grain boundaries of B₄C ceramics, thus limiting B4C grain coarsening or facilitating diffusion in grain boundaries. Zorzi et al.22 found that the addition of 4 wt% SiC alone can also promote the sintering of B₄C ceramics, which in turn increases the hardness of B4C ceramics. For SiC ceramics, the simultaneous introduction of B, which can be introduced as elemental B, LiBH₄ or B₄C,^{23,24} and C can promote the sintering of α -SiC ceramics and β -SiC ceramics.^{23–28} On the one hand, both B and C upset an unfavorable equilibrium at grain boundarypore surface intersections by reducing the grain boundary-surface energy ratio (B can reduce the grain boundary energy, and C can increase the interfacial energy), thereby inducing the driving force for diffusional mass transport necessary for solid-state sintering.^{23,25} Furthermore, B segregated at the grain boundaries of SiC ceramics can impede surface and vapor-phase transport and grain growth at low temperatures, leading to increased densification due to improved grain boundary diffusivity at high temperatures.²⁹ On the other hand, carbon forms a uniform layer on the surface of SiC grains in the first stage of sintering, which occurs because of the high grain boundary and surface diffusion coefficient of C; as the temperature increases, C can react with SiO₂ existing on the surface of SiC grains, forming a secondary SiC phase and removing the oxide film contamination, which can increase the surface energy of SiC and limit the formation of the SiO₂ glass phase.^{27,30,31} Meanwhile, C can prevent the evolution

of gaseous products in chemical reactions or the thermal decomposition of SiC.^{32,33} In order to enhance the densification of SiC ceramics by the addition of sole B_4C , Bind *et al.*³⁴ stated that B atoms can partly replace C atoms in the SiC lattice, forming a solid solution, which can improve the SiC volume diffusion. In contrast, Li *et al.*³⁵ noted that B atoms replace Si atoms, forming a solid solution in SiC ceramics, and the densification of SiC ceramics is promoted by the generation of Si and C vacancies in the SiC lattice.

Moreover, the fracture toughness of both pure B₄C ceramics and pure SiC ceramics is relatively low, especially B₄C ceramics, which is mainly attributed to their transgranular fracture mode.^{36,37} Although the utilization of nano/submicron-sized B₄C and SiC powders as starting materials can improve the fracture toughness and sinterability of pure B₄C ceramics and pure SiC ceramics,^{38,39} these nano/submicron-sized powders are limited to laboratory use because of low yield and high cost; thus, nano/submicron-sized B4C and SiC powders are not suitable for the industrial preparation of B₄C ceramics and SiC ceramics. Both B₄C powders and SiC powders obtained through industrial manufacturing are micron-sized. Adding a second phase into B4C ceramics and SiC ceramics can improve their fracture toughness to a certain extent; however, the addition of some second phases, such as Al, Al₂O₃, and ZrO₂, reduces the hardness of B₄C ceramics and SiC ceramics.^{40,41} Both B₄C and SiC have high microhardness; theoretically, B₄C and SiC can be added to each other to improve each other's mechanical properties. B₄C shows higher hardness and lower density than SiC, and SiC exhibits higher fracture toughness than B₄C. Given that each component can act as a second phase to affect matrix performance, the production of B₄C-SiC composite ceramics is an effective approach to combine the advantages of B₄C and SiC.

In brief, a uniform distribution of B_4C and SiC in B_4C -SiC composite ceramics can prevent direct contact between B_4C - B_4C and SiC-SiC; thus, B_4C and SiC seem to act as grain growth inhibitors for each other in B_4C -SiC composite ceramics, which is conducive to densification. Also, B_4C and SiC have good physical and chemical compatibility with each other; the B_4C -SiC system can offer a combination of good sinterability and relatively high fracture toughness with high hardness and low density. B_4C -SiC composite ceramics can exhibit better mechanical properties and tribological performance as compared to pure B_4C and SiC ceramics;^{42,43} thus, B_4C -SiC composite ceramics are a better candidate material for engineering applications as structural ceramic materials.

In recent years, B_4C –SiC composite ceramics have attracted more and more attention from scientific and commercial disciplines because B_4C –SiC composite ceramics provide some outstanding properties, such as mechanical properties, tribological properties, and thermoelectric properties,^{44,45} for applications in harsh environments. So far, there have been some review articles on pure B_4C ceramics^{46–49} and pure SiC ceramics;^{50,51} however, the review articles on B_4C –SiC materials are very limited. The synthesis of B_4C –SiC composite powders and tribological properties of B_4C – SiC composite ceramics have been summarized in the previous

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review papers;^{52,53} therefore, the sintering performance, microstructure, and mechanical properties of B_4C –SiC composite ceramics are systematically elaborated in this review. It is of great importance to colligate this information for current ceramic research. Furthermore, the future development trend of B_4C –SiC composite ceramics as structural ceramic materials is also proposed.

2. Sintering method of B₄C–SiC composite ceramics

The general methods used to sinter B₄C-SiC composite ceramics include pressureless sintering, hot-press (HP) sintering, spark plasma sintering (SPS), and reaction-bonded sintering. B4C-SiC ceramics are difficult to sinter due to the high covalent bond ratios of both B4C and SiC. When B4C-SiC ceramics are prepared by pressureless sintering, sintering aids are often added to promote sintering. Prior to pressureless sintering, the green body needs to be prepared from composite powders using different molding technologies, such as dry pressing, cold isostatic press (CIP), and slip casting. Hot-press sintering is used to produce B₄C-SiC composite ceramics under external pressure from composite powders without pre-molding. Spark plasma sintering is a technology that utilizes an extremely high heating rate and is assisted by a uniaxial pressure. B₄C-SiC ceramics can be prepared by spark plasma sintering in a very short processing time at relatively low sintering temperatures; thus, a fine microstructure will be obtained for B4C-SiC ceramics due to the high heating rate and short dwell time. The preparation of B4C-SiC composite ceramics by reaction-bonded sintering was first developed by Taylor in the 1970s,⁵⁴ and the preparation method is similar to that of SiC ceramics produced by reactionbonded sintering, in which molten Si with appropriate fluidity infiltrates into a porous green/partially sintered body composed of SiC and free C at high temperatures.55,56 The mechanism of reaction-bonded sintering for B4C-SiC composite ceramics is the same as that for SiC ceramics. The porous green preforms have interconnected pores, which can provide a good channel for the penetration of molten Si; molten Si infiltrates into a green preform, which is composed of only B_4C , the mixture of B_4C and free C, or B₄C-SiC-C or B₄C-SiC powders,⁵⁷ driven by capillary force in a vacuum because the wetting angle of Si with both B_4C and C is 0° at 1430 °C.⁵⁸ Then, the molten Si infiltrated reacts with C either from free C or B₄C to form SiC,^{59,60} the reaction of which leads to volume expansion occupying partial pores in the preform;⁶¹ the remaining excess pores in the preform are filled with molten Si after the reaction, making the reaction-bonded B₄C-SiC ceramics dense.⁶² The preparation of reaction-bonded B₄C-SiC ceramics is actually an *in situ* chemical reaction. In addition to the conventional process, the microwaveassisted processing method, which can shorten the processing time, is another strategy employed to prepare reaction-bonded B₄C-SiC ceramics.⁶³ Recently, a so-called ultra-high pressure (4 GPa) sintering method has been developed to successfully prepare additive-free B₄C-SiC ceramics at a low temperature (1500 °C).⁶⁴ It is noteworthy that the pressure applied during ultra-high pressure sintering is significantly higher than the pressures applied during HP and SPS, leading to the rapid densification of B_4C -SiC ceramics. This phenomenon results from the fact that the ultra-high pressure sintering allows the reduction of distance between the grains and endures the improvement of contact between individual grains resulting in plastic deformation.⁶⁵ Also, the ultra-high pressure has an influence on particle redistribution, agglomerate omission, and pore elimination.⁶⁶ The sintering performance, microstructure, and mechanical properties of the B_4C -SiC ceramics prepared through different sintering methods mentioned above will be described in detail later.

Each sintering method used to prepare B₄C-SiC ceramics has its own advantages and disadvantages. Pressureless sintering is suitable for large-scale production and products with complicated shapes or large sizes. Pressureless sintering has a much wider range of applications and is suitable for extensive industrialization. But the disadvantages of pressureless sintering to fabricate B₄C-SiC ceramics are that the sintering temperature is high and the sintering time is long; it is difficult to obtain high relative density and small grain size for B₄C-SiC ceramics. Hence, various sintering aids are often added to reduce the sintering temperature and ultra-fine powders are usually chosen as raw materials. For hot-press sintering and spark plasma sintering, highly dense B₄C-SiC ceramics without sintering aids can be prepared at relatively low temperatures via these routes, applying heat and pressure simultaneously. The sintering time of these routes is relatively short, especially SPS. The grain size of B₄C-SiC ceramics prepared via these routes, especially by SPS, is relatively small. Also, less costly coarsergrained initial powders can be densified into compacts of acceptable density via these routes. However, compared with pressureless sintering, these routes are more limiting in terms of the shape and size of products and more costly; thus, these technologies are not suitable for industrial applications. Moreover, the physical properties of B4C-SiC ceramics produced via hot-press sintering and spark plasma sintering perpendicular and parallel to the uniaxial pressure direction show direction dependence. Reaction-bonded sintering is an energy-saving process due to much lower sintering temperatures and is favorable of producing large, complex-shaped products. In the case of B₄C-SiC ceramics prepared by reaction-bonded sintering, B_4C , SiC, and residual Si particles can interconnect into a uniform and strong three-dimensional network at low sintering temperatures without the need for applied pressure; near-net shaped products with zero shrinkage can be produced.⁶⁷ Also, fine reactive starting powders capable of being densified are not required, reducing the cost of raw materials. Therefore, the preparation of B4C-SiC ceramics via reaction-bonded sintering is a low-cost method; this route is suitable for large-sized and complex-shaped products. Reaction-bonded B₄C-SiC ceramics have reached the industrial production stage; however, their characteristics of inhomogeneous microstructures and residual Si with low hardness and stiffness may limit the application of B₄C-SiC ceramics in terms of reliability and high-temperature

mechanical properties. Therefore, the B_4C -SiC products produced by reaction-bonded sintering lose the partial superior performance of B_4C -SiC ceramics.

3. Sintering performance and microstructure of B₄C–SiC composite ceramics

Although the sintering temperature of B_4C -SiC composite ceramics is lower than that of pure B_4C ceramics and pure SiC ceramics theoretically, B_4C -SiC ceramics are still difficult to sinter because both B_4C and SiC have strong bonding, high resistance to grain boundary sliding, low plasticity, and low superficial tension in the solid state. Many factors can affect the sintering performance and microstructure of B_4C -SiC ceramics, such as the ratio of B_4C to SiC, raw materials, preparation process, sintering aids, *etc.*, which will be summarized in detail in this part. High relative density can achieve some properties and applications of B_4C -SiC ceramics, such as good wear resistance in the tribo-component application and acceptable ballistic resistance in the armor application. Also, the microstructure plays an important role in the mechanical properties of B_4C -SiC ceramics.

3.1. Ratio of B₄C to SiC

Different ratios of B_4C to SiC will cause different impacts on the sintering performance and microstructure of B_4C -SiC ceramics. When the volume fraction of B_4C is more than that of SiC, SiC grains distribute in the B_4C matrix; otherwise, B_4C grains distribute in the SiC matrix. Meanwhile, the density of SiC (3.21 g cm⁻³) is higher than that of B_4C (2.51 g cm⁻³); thus, the density of B_4C -SiC ceramics increases with an increase in the ratio of SiC.

The high covalent bond ratio, which is responsible for intrinsically low diffusion mobility, is one of the factors inhibiting the sintering performance of ceramic materials. Theoretically, the densification of B_4C is more difficult than that of SiC because the covalent bond ratio in B_4C (94%) is higher than that in SiC (88%);¹⁵ thus, the B_4C -SiC ceramics with more SiC content than B_4C content can achieve better sintering performance. This means that a higher sintering temperature may be required to achieve a higher relative density for the composite ceramic containing more B_4C .

For the sintering performance and microstructure of B_4C -SiC ceramics with different ratios of B_4C to SiC prepared by different sintering methods, some regular results have been found by the researchers. Magnani *et al.*⁶⁸ found that the pressureless sintered SiC-5 vol% B_4C ceramics show a higher relative density than pure SiC ceramics in the sintering temperature range of 1950–2200 °C. The presence of B_4C as a secondary phase can improve the sinterability of SiC powders. Furthermore, the addition of B_4C reduces the abnormal growth of SiC grains; thus, the SiC-5 vol% B_4C ceramics exhibit a finer microstructure than pure SiC ceramics. Cho *et al.*⁶⁹ mentioned that the relative density of the pressureless sintered SiC ceramics decreases with the addition of B_4C particles from 1 to 5 wt%. This phenomenon can be

explained by the fact that the B₄C grains existing between SiC grains impede mass transport through surface diffusion; thus, the grain growth of SiC is slowed down with the increase in B₄C addition, resulting in the formation of large amounts of pores. Thévenot²⁰ reported that the relative density of the pressureless sintered B_4C -SiC ceramics (10/90 < B_4C wt%/SiC wt% < 96/4) increases from 93 to 99% with an increase in α-SiC content from 10 to 90 wt%. The B₄C-SiC ceramic with the highest SiC content exhibits the best sintering capability. When the SiC content is less than 10 wt%, the densification of B₄C-SiC ceramics is low despite higher sintering temperature, and the grains are coarser (<80 µm). Zhang *et al.*⁷⁰ also observed similar results for the relative density of pressureless sintered B₄C-SiC ceramics $(3/97 < B_4C \text{ wt\%/SiC wt\%} < 100/0)$. The relative density is higher and fewer pores are observed on the ceramic surfaces when the SiC content is more than the B₄C content in the B₄C-SiC ceramics (Fig. 2a-f). Yaşar and Haber⁷¹ noted that the relative density of the spark plasma sintered B₄C-SiC ceramics decreases from 99.6 to 98.9% with the increase in B₄C content from 10 to 50 wt%. So et al.72 studied the sintering performance and microstructure of the hot-press sintered B₄C-SiC ceramics with the volume ratios of B_4C to SiC of 35:65, 56:44, and 75:25. It was found that the densification mechanisms are different for B_4C -SiC ceramics with different ratios of B_4C to SiC. When the B₄C grains distribute in the SiC matrix (the volume fraction of SiC is more than that of B_4C), the partial phase transition of SiC from 6H to 4H accompanying the grain growth promotes densification. In contrast, when the SiC grains distribute in the B₄C matrix (the volume fraction of B₄C is more than that of SiC), the ceramics are densified through grain boundaries and volume diffusion, and there is no phase transition of SiC in the ceramics. The solubility of B_4C in α -SiC is approximately 0.5 wt% at a temperature between 2000 and 2100 °C,⁷³ which can decrease the surface energy at the phase boundary between $B_{4}C$ and SiC and can increase the mass transfer, promoting the densification of SiC. However, the diffusion coefficient and densification rate will decrease when the B4C content is above the solubility. The grain growth of SiC is inhibited, but the grain size of B₄C is increased with an increase in B₄C content, leading to the larger grain size of B₄C than that of SiC, which is attributed to the growth of B₄C grains by the diffusion of B and C, and the difference in grain size between B₄C and SiC is increased with an increase in B4C content in the composite ceramics. Zhang et al.74 found that the relative density of the gas-pressure sintered B₄C-SiC ceramics decreases from 94.2 to 88.9% with the increase in B_4C content from 5 to 20 wt% in the composite ceramics, and the surface morphology changes from an island-like distribution and better continuity to a plate-type structure (Fig. 2g-j). Matović et al.⁶⁴ mentioned that B₄C-SiC ceramics can achieve a high relative density (>96%) via ultrahigh pressure sintering at a relatively low temperature combined with a short holding time; the composite ceramics with the equal-weighted contributions of B4C and SiC achieve the maximal relative density, which is attributed to the best mixing of the initial raw materials and thus their best distribution in the composite powders.

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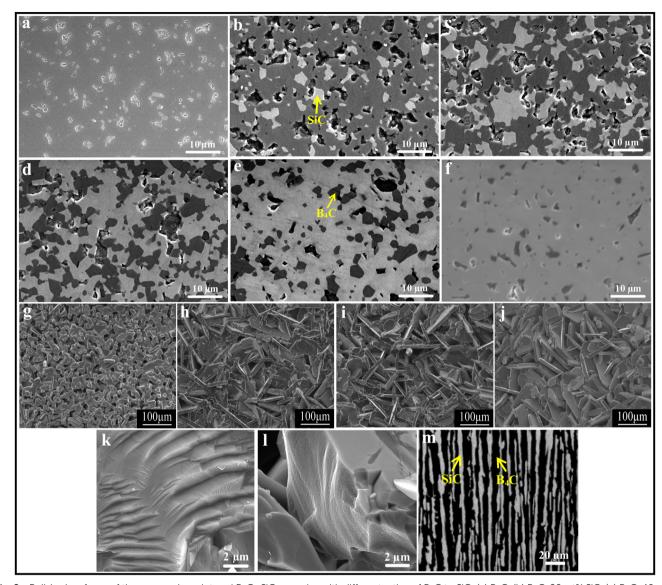


Fig. 2 Polished surfaces of the pressureless sintered B_4C -SiC ceramics with different ratios of B_4C to SiC: (a) B_4C , (b) B_4C -20 wt% SiC, (c) B_4C -40 wt% SiC, (d) B_4C -80 wt% SiC, and (f) B_4C -97 wt% SiC⁷⁰ (reprinted with permission, Copyright 2020, Elsevier); microstructure of the gaspressure sintered B_4C -SiC ceramics with different ratios of B_4C to SiC: (g) SiC-5 wt% B_4C , (h) SiC-10 wt% B_4C , (j) SiC-15 wt% B_4C , (j) SiC-20 wt% B_4C -70 wt% B_4C , (j) SiC-20 wt% B_4C -70 wt% B_4C , (j) SiC-15 wt% B_4C , (j) SiC-20 wt% B_4C^{74} (reprinted with permission, Copyright 2014, Trans Tech Publications); SEM images of B_4C -SiC ceramics revealing the cleavage surfaces: (k) B_4C -5 vol% SiC and (l) B_4C -7.5 vol% SiC⁸⁰ (reproduced with permission, Copyright 2017, Elsevier); (m) microstructure of eutectic B_4C -SiC ceramics showing lamellar texture⁸² (reproduced with permission, Copyright 2002, The Japan Institute of Metals. This is an open access article distributed under the terms of the Creative Commons Attribution License).

For the reaction-bonded B_4C –SiC ceramics, different ratios of B_4C to SiC and microstructures can be obtained by adjusting the chemical composition and microstructure of their preforms. The preforms containing high C content can form B_4C –SiC ceramics rich in SiC after Si infiltration. Zhang *et al.*⁷⁵ reported that the content of generated SiC increases with an increase in the initial amount of nano-carbon black in the reaction-bonded B_4C –SiC ceramics increases with the increase in the initial amount of carbon black (0–12 wt%), which is attributed to the gradually increased amount of SiC generated. Although the relative density of the B_4C –SiC ceramics slightly decreases with the increase

in carbon black, B_4C -SiC ceramics with different amounts of carbon black are rather dense. Li *et al.*⁷⁶ also found that the amount of fine SiC grains formed increases with the increasing amount of the C source. In contrast, Hayun *et al.*⁷⁷ mentioned that the amount of SiC generated essentially depends on the porosity of the preform, and only depends on the C source to a slight extent.

Different from these regular results mentioned above, Tomohiro *et al.*⁷⁸ found that the relative density of the hot-press sintered B_4C -SiC ceramics is independent of the SiC content from 0 to 50 vol% when the sintering temperature is 2200 °C, and the relative density of composite ceramics is nearly fully dense.

However, when the sintering temperatures are 2000 and 2100 $^{\circ}$ C, the relative density of B₄C–SiC ceramics with an SiC addition of 10–20 vol% is at a maximum, the reason for which is not explained.

The microstructure of B_4C –SiC ceramics is also related to the ratio of B_4C to SiC. Compared with pure B_4C ceramics, the B_4C -20 wt% SiC ceramics achieve a more refined and denser microstructure due to the incorporation of SiC.⁷⁹ Moradkhani and Baharvandi⁸⁰ pointed out that the addition of SiC particles in the B_4C matrix leads to the formation of cleavage surfaces within grains (Fig. 2k and l); the greater the volume fraction of the SiC additive, the greater the density of cleavage surfaces. As for the microstructure of eutectic composites, it is mainly dependent on the volume fractions of phases.⁸¹ The lamellar texture will appear when each phase is more than 30 vol%. Gunjishima *et al.*⁸² observed lamellar texture in B_4C -40 vol% SiC ceramics prepared by the floating zone method (Fig. 2m), which is the eutectic composition of the B_4C –SiC binary system. Also, the spacing between lamellae is related to the solidification rate.

Some previous studies on the effect of the ratio of B_4C to SiC on the sintering performance and microstructure of B_4C -SiC ceramics are tabulated in Table 1.

3.2. Raw material

Raw materials are the basis for the preparation of B_4C -SiC ceramics. The characteristics of raw materials, such as particle size, oxide impurity, and species, can affect the sintering performance and microstructure of B_4C -SiC ceramics.

3.2.1. Particle size. Generally, raw materials with large sizes are not easy to sinter into dense blocks; inversely, raw materials with particle sizes in the submicron or even nanometer range are easier to sinter due to higher surface energy. Shi et al.⁸³ studied the sintering performance of hot-press sintered B₄C-20 vol% SiC ceramics using B_4C powders with a size of 10.22 µm and β -SiC powders with a size of 1.07 µm as raw materials. The porosity of the B4C-SiC ceramics gradually decreases with an increase in sintering temperature from 1900 to 2100 °C; however, obvious pores can still be observed after sintering at 2100 °C. This indicates that it is difficult to obtain dense B₄C-SiC ceramics using B₄C powders with micron size as the raw material, although the increase of sintering temperature can reduce the porosity to a certain extent. Therefore, the utilization of raw materials with fine particle size is more conducive to promoting the sintering of B₄C-SiC ceramics. For the grain size of B₄C-SiC ceramics, Moradkhani and Baharvandi⁸⁰ found that the effect of the addition of SiC with nanoscale and microscale sizes on the grain size of the pressureless sintered B4C-SiC ceramics is not very significant.

Using graded particles as raw materials is an effective strategy to improve the packing density of the green body. For the reaction-bonded B_4C -SiC ceramics, theoretically, high green density is conducive to reducing the fraction of residual Si in the final product. The lower the porosity, the lower the amount of residual Si present after the infiltration with Si. Therefore, it is reasonable to decrease the porosity of the green body as much as possible before the infiltration process.

A multimodal particle size distribution results in maximal volume filling by the initial ceramic powers prior to infiltration, and thus reduces the fraction of residual Si after infiltration. Hayun *et al.*⁸⁴ used B₄C powders with different particle sizes (130, 70, 50, 13, and 1 μ m) as raw materials to prepare the preform. Compared with the relative density (65%) of the preform composed of monosized fine B₄C particles (1 µm), the relative densities (70-75%) of the preforms composed of graded B₄C particles are higher. After Si infiltration, the space between coarse B₄C particles is uniformly filled with fine B₄C, newly formed SiC, and residual Si particles. Both the preforms composed of graded B₄C particles and the preform composed of monosized fine B₄C particles are fully infiltrated; however, the amount of residual Si in the final B4C-SiC ceramics produced from the graded B₄C particles (8-10 vol%) is lower than that produced from the monosized fine B4C particles (20 vol%). Li et al.⁷⁶ also proved that the relative density of the green body composed of graded B₄C powders with 8.671 μm and 323.7 nm can reach 75%, which is higher than that of the preform composed of monosized B₄C particles (59.9%). Meanwhile, compared with the green body with a similar relative density prepared by Hayun *et al.*,⁸⁴ the particle size of B_4C used by Li et al.⁷⁶ is much smaller, which contributes to decreasing open pore size of the preform and the consequent size of free Si. On the other hand, Song *et al.*⁸⁵ found that because there are coarse B₄C particles in the reaction-bonded B₄C-SiC preform composed of graded B4C particles (14, 7, and 1.5 µm), the uniform distribution of the residual Si is prevented, leading to the formation of scattered fragments; thus, the use of fine B₄C particles makes it easier to form a uniform microstructure in the reaction-bonded B4C-SiC ceramics. Therefore, using a multimodal powder mixture including coarse B4C particles to prepare the green body is helpful for improving the relative density of the green body, which in turn contributes to reducing the amount of residual Si in the reaction-bonded B₄C-SiC ceramics; however, the use of coarse B4C particles is not conducive to the formation of uniform microstructure in the reaction-bonded B4C-SiC ceramics. Hereto, the size of coarse particles in the graded B₄C particles should be as small as possible under the premise of improving the relative density of the green body.

3.2.2. Oxide impurity. B_4C and SiC powders, as the main raw materials for preparing B_4C –SiC ceramics, have oxide layers on their surfaces.^{14,86} These oxide film impurities (B_2O_3/H_3BO_3 , SiO₂) on the raw materials can cause abnormal grain growth, increase porosity, and deteriorate sintering performance in the sintering process. In particular, the presence of these oxide impurities reduces the application potential of B_4C –SiC ceramics at high temperatures. Therefore, it is necessary to control surface oxide impurities on the raw materials. To remove these oxide impurities, there are two main approaches. One is adding C to remove these oxide layers according to the reactions between C and B_2O_3 and between C and SiO₂ in the sintering process.⁷⁰ The other is using acid etching to remove these oxide layers. HCl and HF are commonly used to wash B_4C and SiC to remove B_2O_3 and SiO₂, respectively.⁷¹ It is worth noting that the

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Table 1 Effect of the ratio of B₄C to SiC on the sintering performance and microstructure of B₄C-SiC ceramics

Ceramics	Raw material	Sintering method	temperature (°C)	Sintering aid	density (%)	Phase composition	Average grain size (µm)
SiC ⁶⁸	a-SiC (0.6 µm)	Pressureless	2150	0.6 wt% B + 2 wt% carbon black	93.5	I	> 8.0
SiC-5 vol% B ₄ C ⁶⁸	α -SiC (0.6 μ m), B ₄ C (0.7–0.9 μ m)	Pressureless	2150	1 wt% carbon black	96.0	I	SiC: 8.0, B ₄ C: 2.0
B_4C-10 wt% SiC^{20}	B_4C (<5.0 µm), α -SiC	Pressureless	2200	2.5 wt% phenolic resin	93.0		0.5 - 3.0
$B_4C-30 \text{ wt\% SiC}^{20}$	B_4C (<5.0 µm), α -SiC	Pressureless	2200	2.5 wt% phenolic resin	97.3		0.5 - 3.0
$B_4C-70 \text{ wt\% SiC}^{20}$	B_4C (<5.0 µm), α -SiC	Pressureless	2200	2.5 wt% phenolic resin	97.6		0.5 - 3.0
B_4C -90 wt% SiC ²⁰	B_4C (<5.0 µm), α -SiC	Pressureless	2200	2.5 wt% phenolic resin	0.66		0.5 - 3.0
${ m B}_4{ m C}^{70}$	$B_4C(0.8 \ \mu m)$	Pressureless	2300	3 wt% carbon black	94.4	B_4C, C	3.0 - 4.0
$B_4C-20 \text{ wt\% SiC}^{70}$	B_4C (0.8 µm), α -SiC (0.4 µm)	Pressureless	2300	3 wt% carbon black	93.8	B ₄ C, SiC, C	Ι
$B_4C-40 \text{ wt\% SiC}^{70}$	B_4C (0.8 µm), α -SiC (0.4 µm)	Pressureless	2300	3 wt% carbon black	93.5	B ₄ C, SiC, C	B_4C : 2.0, SiC: 3.0
$B_4C-60 \text{ wt\% SiC}^{70}$	$B_4C (0.8 \ \mu m), \ \alpha$ -SiC (0.4 \ \mu m)	Pressureless	2300	3 wt% carbon black	95.6	B ₄ C, SiC, C	I
B_4C -80 wt% SiC ⁷⁰	$B_4C (0.8 \ \mu m), \ \alpha - SiC (0.4 \ \mu m)$	Pressureless	2300	3 wt% carbon black	96.5	B₄C, SiC, C	
$B_4C-97 wt\% SiC^{70}$	B_4C (0.8 µm), α -SiC (0.4 µm)	Pressureless	2300	3 wt% carbon black	0.06	sic, c	
SiC-10 wt% B_4C^{71}	B_4C, α -SiC	Spark plasma (50 MPa)	1950 ($\times 5$ min)	1.5 wt% C	9.66	B ₄ C, SiC, C	I
	B_4C, α -SiC	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C	99.2	B_4C , SiC, C	
	B_4C, α -SiC	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C	98.8	B ₄ C, SiC, C	
	B_4C, α -SiC	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C	98.8	B ₄ C, SiC, C	
	B_4C, α -SiC	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C	98.9	B ₄ C, SiC, C	I
$B_4C-65 \text{ vol}\% SiC^{72}$	B_4C	Hot-press (40 MPa)	2000	No	100.0	B_4C , SiC	B_4C : 1.5, SiC: 1.3
$B_4C-44 \text{ vol}\% SiC^{72}$	B_4C	Hot-press (40 MPa)	2000	No	9.99	B ₄ C, SiC, C	B_4C : 1.6, SiC: 1.0
$B_4C-25 \text{ vol}\% SiC^{72}$	B ₄ C (0.8 μm)	Hot-press (40 MPa)	2000	No	99.8	B ₄ C, SiC, C	B_4C : 2.1, SiC: 1.1
B ₄ C-75 wt% SiC ⁶⁴	B_4C (2.5 µm), β -SiC (0.6 µm)	Ultra-high pressure (4 GPa)	$1500 (\times 1 \text{ min})$	No	96.4	B_4C , β -SiC	I
B_4C -50 wt% SiC ⁶⁴	B_4C (2.5 µm), β -SiC (0.6 µm)	Ultra-high pressure (4 GPa)	$1500 (\times 1 \text{ min})$	No	98.0	B_4C, β -SiC	I
B_4C-25 wt% SiC ⁶⁴	B_4C (2.5 µm), β -SiC (0.6 µm)	Ultra-high pressure (4 GPa)	$1500 (\times 1 \text{ min})$	No	96.9	B_4C , β -SiC	I
B_4C-SiC^{75}	~~ J	Reaction	1550	No	9.99	B ₄ C, SiC, Si, B ₁₂ (B, C, Si))3 —
B_4C-SiC^{75}	B_4C (4.08 µm), 6 wt% carbon black, Si (5–10 mm)	Reaction	1550	No	_	B ₄ C, SiC, Si, B ₁₂ (B, C, Si) ₃	3 -
B_4C-SiC^{75}	B_4C (4.08 µm), 8 wt% carbon black, Si (5–10 mm)	Reaction	1550	No	_	B ₄ C, SiC, Si, B ₁₂ (B, C, Si) ₃	3 -
B_4C-SiC^{75}	B_4C (4.08 µm), 10 wt% carbon black, Si (5–10 mm)	Reaction	1550	No		SiC, Si, B ₁₂ (B,)3 —
$B_4C-SiC^{\prime 3}$	B_4C (4.08 µm), 12 wt% carbon black, Si (5–10 mm)	Reaction	1550	No	98.7	B ₄ C, SiC, Si, B ₁₂ (B, C, Si) ₃)3 —

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acid etching treatment cannot completely remove oxide film impurities; the content of oxide film contamination is reduced through this approach. After the pre-washing of raw materials, the relative density of the obtained B_4C -SiC ceramics can be slightly increased.⁸⁷

3.2.3. Species. B₄C-SiC ceramics can be produced from different species of raw materials, which have different effects on the sintering performance and microstructure of B₄C-SiC ceramics. α -SiC and β -SiC are the two main species for SiC raw materials. Thévenot²⁰ found that B₄C-60 wt% SiC ceramics, when using β -SiC as the raw material, exhibit a poorer sintering behavior compared to those using α -SiC as the raw material. This phenomenon may be attributed to the partial transformation of $\beta \rightarrow \alpha$ -SiC during the sintering process, resulting in the formation of plate-like (or acicular) grains with a length of 15 μ m. Rocha and Melo^{88,89} also proved that the relative density of the pressureless sintered B_4C -SiC ceramics with β -SiC as the raw material decreases from 81.3 to 67.5% with an increase in SiC content from 10 to 50 wt%. This conclusion is different from that with α -SiC as the raw material mentioned in Section 3.1. During the SiC phase transformation, equiaxed shaped β -SiC grains change to plate-like shaped α -SiC grains with a high aspect ratio, and the amount of these platelet-shaped SiC grains increases with an increase in SiC content in the ceramics. The platelet-shaped SiC grains can lead to early impingement of large grains, forming a skeleton that can arrest the densification of the ceramics. The higher the amount of platelet-shaped SiC grains, the lower the relative density the B₄C-SiC ceramics achieve.

Different from the mechanical method to physically mix B₄C and SiC powders, using organic precursors is another method to prepare B₄C-SiC ceramics. SiC can be generated from the pyrolysis of organic precursors. For example, polycarbosilane (PCS) can be converted to nanocrystalline SiC after pyrolysis at high temperatures (1000-1300 °C) with a conversion yield of 60-70 wt%.90 Therefore, many researchers investigate the sintering performance and microstructure of the B₄C-SiC ceramics fabricated via the preceramic polymer (PCP) route. Thévenot²⁰ used PCS and Alnovol PN 320 as the precursors of SiC and C, respectively, mixing B₄C powders to prepare B₄C-SiC ceramics. The relative density of the green body is 60% after cold pressing, and the relative density of the resulting pressureless sintered B₄C-SiC ceramics is 95%. Du et al.⁹¹ mentioned that the introduction of SiC in the form of PCS can promote the sinterability of B₄C-SiC ceramics. The SiC obtained from PCS after pyrolyzing at 850 °C is amorphous, but β-SiC crystals are formed after hot-press sintering at 1950 $^{\circ}$ C. On the one hand, the size distribution of SiC formed ranges from 80 nm to 1 µm. The fine SiC nanocrystals with high activity can bond B4C grains together and fill spaces to generate a dense structure. On the other hand, a small amount of active carbon derived from the pyrolysis residue of PCS can remove oxide layers existing on B4C raw materials, thus improving the sinterability of the B₄C-SiC ceramics. Hwang et al.⁸⁷ found that increasing the pyrolysis temperature of PCS cannot change the phase composition and content of the spark plasma sintered B₄C-SiC ceramics; however, it can change the ceramic microstructure, which in turn improves the relative density of the ceramics. This is because the increase in the pyrolysis temperature of PCS can reduce the gas evolution during the sintering process. Moreover, organic precursors not only provide a source of raw materials but are also used as polymer additives in a warm pressing process to increase the relative density of the B₄C-SiC green body. Lin and He⁹² first used PCS as a precursor of SiC to prepare PCS-coated B₄C powders, and then the B₄C-SiC green bodies were produced from these powders by warm pressing at 300 °C. Because PCS can undergo plastic rheology at 300 °C, which can reduce the friction between B₄C particles as well as between B₄C particles and the die wall, thus, the powders can be rearranged smoothly under pressure. As a result, the relative density of the B₄C-15 wt% SiC green body (65%) produced through warm pressing (50 MPa) is higher than that of the B₄C-15 wt% SiC green body (54%) produced through cold isostatic pressing (800 MPa). The improvement in the relative density of the green body is helpful in increasing the densification of the final B₄C-SiC ceramics; therefore, the relative density of the B₄C-15 wt% SiC ceramics (97%) produced through warm pressing is higher than that of the B₄C-15 wt% SiC ceramics (91%) produced through cold isostatic pressing after pressureless sintering at 2000 °C. Meanwhile, β-SiC grains formed from PCS are uniformly distributed in the B₄C matrix.

The PCP route provides an approach for the improved microstructure control of B₄C-SiC ceramics, and it is an effective method to obtain fine-grained B4C-SiC ceramic. For the microstructure of the B₄C-SiC ceramics prepared from the SiC generated by the pyrolysis of organic precursors, compared with the microstructure of the B₄C-SiC ceramics prepared by the conventional powder mixing, Lörcher et al.93 found that B_4C -SiC ceramics show a preferable presence of SiC at the B_4C grain boundaries when the SiC phase is generated from the precursor of copolymerized polysilane containing dimethylsilylene and methylphenylsilylene groups; thus, SiC grains are more homogeneously distributed in the B4C matrix. The SiC phase existing at the grain boundaries plays a role in inhibiting the growth of B₄C grains. Du et al.⁹¹ noted that some SiC grains with nano or submicron size formed from PCS locate within B4C grains (Fig. 3a) or at B₄C grain boundaries (Fig. 3b), forming intragranular and intergranular SiC structures. These nano-sized or submicronsized SiC grains are favorable for forming a sub-boundary structure in B₄C-SiC ceramics under internal stress, which can refine B₄C grains and improve the mechanical properties of B₄C-SiC ceramics. Meanwhile, the formation of these fine SiC grains means that more barriers are placed in the way of grain boundaries, thereby pinning the migration of grain boundaries and inhibiting the growth of B₄C grains. In addition, the SiC grains formed from PCS show a layered structure (Fig. 3c), and dislocation defects appear in the SiC grains (Fig. 3b). The formation of the layered structure is caused by the pyrolysis of PCS and crystallization process. When SiC nuclei grow from an amorphous medium, the content of free C also increases, resulting in the formation of a heterogeneous material with an extremely divided microtexture: SiC nuclei are considered to be divided by a thin film of C arranged as a stack of few layers. Thus, the formation of the layered

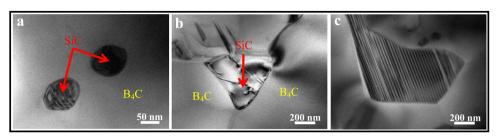


Fig. 3 TEM images of hot-press sintered B_4C-15 wt% SiC ceramics produced *via* the introduction of SiC in the form of PCS: (a) intragranular SiC structure, (b) intergranular SiC structure, and (c) SiC grains with a layered structure⁹¹ (reproduced with permission, Copyright 2013, Elsevier).

structure within the SiC grains generated from PCS pyrolysis is due to the presence of disordered residual C between SiC layers. The microstructure characteristics of the layered structure and dislocation can affect the mechanical properties of B₄C–SiC ceramics produced by the introduction of SiC in the form of PCS, especially the fracture toughness, which will be discussed in Section 4.3.2. The use of PCS is a suitable approach to achieve a homogeneous structure in B₄C–SiC ceramics, which helps avoid the polluting milling process; however, the main drawback is that the β -SiC obtained from PCS pyrolysis will be transformed into α -SiC coarse grains during sintering.

Besides directly mixing commercial B_4C and SiC powders, B_4C -SiC ceramics can also be produced *in situ* through chemical reactions of two or more raw materials. Zhang *et al.*^{94,95} first used B_4C , Si, and amorphous carbon powders to prepare B_4C -20 wt% SiC nanocomposite powders (50–150 nm) *in situ via* highenergy ball milling; then, B_4C -SiC ceramics were produced from these B_4C -SiC nanocomposite powders *via* hot-press sintering at 1950 °C or spark plasma sintering at 1800 °C. The relative densities of the resulting B_4C -SiC ceramics were in the range of 98.5% to 99.5%, and fine grains were obtained in the ceramics *via* this route. Sahin *et al.*⁹⁶ used B_4C , SiO₂, and carbon black as raw materials to produce B_4C -SiC ceramics *via* spark plasma sintering at 1750 °C, the formation of which is shown as follows:

$$B_4C + SiO_2 + 3C \rightarrow B_4C + SiC + 2CO$$
(1)

The relative density of the resulting B₄C-SiC ceramics decreased linearly from 97.7% to 88.3% with the increase in in situ formed SiC content from 5 to 20 vol%. This phenomenon is caused by the fact that the in situ formed SiC is oxidized by the intermediate product of B_2O_3 to SiO gas during the sintering process, resulting in the formation of residual pores in the B₄C-SiC ceramics; the formation of more SiC content in situ is accompanied by an increase in residual pores. This suggests that B₄C-SiC ceramics with a high SiC content are not easily densified through this route. In addition, Pánek97 used B powders, Si platelets, and carbon black as raw materials to produce B4C-SiC ceramics in situ (reaction (2)) by combustion hot-press sintering, which is based on the combination of the self-propagating hightemperature synthesis technique and hot-press sintering. The resulting B4C-SiC ceramics can achieve an extremely low porosity (0.3%), and their purity is rather high.

$$4B + Si + 2C \rightarrow B_4C + SiC \tag{2}$$

Some previous studies on the effect of raw material on the sintering performance and microstructure of B_4C -SiC ceramics are tabulated in Table 2.

3.3. Preparation process

The sintering performance and microstructure of B_4C -SiC ceramics vary depending on the processing conditions and parameters. Various factors including powder mixing methods, preparation of the green body, and parameters during sintering affect the sintering performance and microstructure of B_4C -SiC ceramics.

3.3.1. Powder mixing method. In general, B₄C–SiC composite powders are prepared from multiple single-component powders by dry mixing or wet mixing. The difference between dry mixing and wet mixing is the presence of a liquid medium. Ethanol and water are commonly used as media for wet mixing to prepare B₄C-SiC composite powders. Yaşar and Haber⁷¹ compared the effects of dry mixing and wet mixing methods of B₄C-SiC composite powders on the sintering performance and microstructure of spark plasma sintered B₄C-SiC ceramics. The B₄C-SiC ceramics produced from B₄C-SiC composite powders prepared by dry mixing cannot achieve a uniform microstructure; there are some large pockets of individual components (Fig. 4a), while the microstructure of the B_4C -SiC ceramics produced from B4C-SiC composite powders prepared by wet mixing is uniform (Fig. 4b). Compared with the relative density of the B₄C-SiC ceramics produced from the B₄C-SiC composite powders prepared by dry mixing, the relative density of the B₄C-SiC ceramics produced from the B₄C-SiC composite powders prepared by wet mixing is higher. The agglomeration problem caused by dry mixing has a negative impact on the mechanical properties of B₄C-SiC ceramics.

Ball milling and high-energy ball milling are two common methods for mixing multiple single-component powders. Zhang *et al.*⁹⁸ first prepared B₄C–SiC composite powders by ball milling and high-energy ball milling, and then compared the sintering performance of B₄C–SiC ceramics produced from these B₄C–SiC composite powders synthesized by the two milling methods. Although the particle sizes of raw materials of B₄C and SiC used in the high-energy ball milling method are larger than those used in the ball milling method (Table 3), the resulting mean particle size (0.7 µm) after high-energy ball milling. In the B₄C–SiC ceramics produced from the B₄C–SiC composite powders

Table 2 Effect of raw material on the sintering performance and microstructure of B₄C-SiC ceramics

Ceramics	Raw material	Sintering method	Sintering temperature (°C)	Sintering aid	Relative density (%)	Phase composition	Average grain size (µm)
$B_4C-20 \text{ vol}\% SiC^{83}$	B_4C (10.22 µm), β-SiC (1.07 µm)	Hot-press (20 MPa)	1900	No	73.7	B_4C , SiC	
B_4C-20 vol% SiC ⁸³	$B_4C (10.22 \ \mu m), \beta$ -SiC (1.07 $\mu m)$	Hot-press (20 MPa)	2000	No	77.8	B_4C , SiC	
$B_4C-20 \text{ vol}\% SiC^{83}$	$B_4C (10.22 \ \mu m), \beta$ -SiC (1.07 $\mu m)$	Hot-press (20 MPa)	2100	No	87.0	B_4C , SiC	
B_4C-5 vol% SiC ⁸⁰	$B_4C (307 \text{ nm}), \text{ SiC} (80 \text{ nm})$	Pressureless	2200	No		B_4C , SiC	16.1
B_4C-5 vol% SiC ⁸⁰	B_4C (307 nm), SiC (1.0 µm)	Pressureless	2200	No		B_4C , SiC	16.3
$B_4C-7.5$ vol% SiC ⁸⁰	B_4C	Pressureless	2200	No		B_4C , SiC	15.8
$B_4C-7.5$ vol% SiC ⁸ ⁰	B_4C	Pressureless	2200	No	Ι	B_4C , SiC	15.8
B_4C-10 vol% SiC ⁸⁰	B_4C	Pressureless	2200	No	I	B_4C , SiC	15.6
$B_4C-10 \text{ vol}\% \text{ SiC}^{80}$	$B_4C (307 \text{ nm}), \text{ SiC} (1.0 \mu\text{m})$	Pressureless	2200	No		B_4C , SiC	14.8
$B_4C-60 wt\% SiC^{20}$	B_4C (<5.0 µm), α -SiC	Pressureless	2200		97.5	B ₄ C, SiC, C	
				phenolic resin			
$B_4C-60 wt\% SiC^{20}$	$B_4C (<5.0 \mu\text{m}), \beta\text{-SiC}$	Pressureless	2200		95.7	B_4C , SiC, C	
				phenolic resin			
B_4C-10 wt% SiC ⁸⁸	B₄C, β-SiC	Pressureless	2000	No	81.3	B_4C , α -SiC, (β -SiC)	
$B_4C-30 \text{ wt\% SiC}^{88}$	B₄C, β-SiC	Pressureless	2000	No	74.0	B_4C , α -SiC, (β -SiC)	
$B_4C-50 wt\% SiC^{88}$	B4C, β-SiC	Pressureless	2000	No	67.5	B_4C , α -SiC, (β -SiC)	
B_4C-5 wt% SiC ²⁰	B_4C , PCS	Pressureless	2175	Phenolic resin	95.0	B_4C , SiC	32.0
B_4C^{91}	$B_4C (3.5 \ \mu m)$	Hot-press (30 MPa)	1950	No	91.7	B_4C	
B_4C-15 wt% SiC ⁹¹	B_4C (3.5 µm), PCS	Hot-press (30 MPa)	1950	No	96.1	B_4C , β -SiC	SiC < 1.0
$B_4C-10 \text{ wt\% SiC}^{87}$	$\mathrm{B_4C}~(0.3-0.6~\mu\mathrm{m},~\mathrm{as-received}),~\mathrm{PCS}~(\mathrm{pyrolyzed}~\mathrm{at}~800~^\circ\mathrm{C})$	Spark plasma (50 MPa)	$1900 (\times 5 min)$	No	96.2		
$B_4C-10 \text{ wt\% SiC}^{87}$	B_4C (0.3–0.6 µm, washed off by HCl), PCS (pyrolyzed at 800 °C)	Spark plasma (50 MPa)	$1900 (\times 5 min)$	No	97.2	sic,	
$B_4C-10 \text{ wt\% SiC}^{8/}$	B_4C (0.3–0.6 µm, washed off by HCl), PCS (pyrolyzed at 1385 °C)	Spark plasma (50 MPa)	$1900 (\times 5 min)$	No	99.7	sic,	
$B_4C-20 \text{ wt\% SiC}^{87}$	B_4C (0.3–0.6 µm, washed off by HCl), PCS (pyrolyzed at 1385 °C)	Spark plasma (50 MPa)	$1900 (\times 5 min)$	No	99.5	B4C, SiC, C	
B_4C-20 wt% SiC ⁹⁴	B_4C , SiC, mean particle size of 50–150 nm	Hot-press (30 MPa)	1950	No	98.6	B_4C , SiC	$B_4C = 1.0-3.0,$
;							SiC < 2.0
B_4C -20 wt% SiC ⁹⁵	B_4C , SiC, mean particle size of 50–150 nm	Spark plasma (30 MPa)	1800 (×5 min)	No	99.2	B_4C , SiC	$B_4C = 1.0$, SiC < 1.0
B_4C -5 vol% SiC ⁹⁶	B ₄ C, SiO ₂ , carbon black	Spark plasma (40 MPa)	$1750 (\times 5 min)$	No	97.7		Ι
$B_4C-10 \text{ vol}\% \text{ SiC}^{96}$	B ₄ C, SiO ₂ , carbon black	Spark plasma (40 MPa)	$1750 (\times 5 \text{ min})$	No	93.8	B_4C , SiC, C	
B_4C-15 vol% SiC ⁹⁶	B_4C , SiO ₂ , carbon black	Spark plasma (40 MPa)	$1750 (\times 5 min)$		91.2	B ₄ C, SiC, C, SiO ₂	
$B_4C-20 \text{ vol}\% SiC^{96}$	B ₄ C, SiO ₂ , carbon black	Spark plasma (40 MPa)	$1750 (\times 5 \text{ min})$		88.3	B_4C , SiC, C, SiO ₂	
$B_4C-50 \text{ vol}\% SiC^{3/3}$	B powders (1.5 μm), Si platelets, carbon black	Combustion hot-press (30 MPa)	1900 (×20 min)	No	99.7	B_4C , SiC	1

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Review

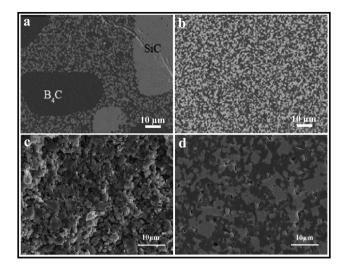


Fig. 4 Microstructure of spark plasma sintered SiC-40 wt% B₄C ceramics produced from the B₄C-SiC composite powders prepared by: (a) dry mixing and (b) wet mixing⁷¹ (reproduced with permission, Copyright 2020, Elsevier). Fracture surfaces of hot-press sintered B₄C-50 wt% SiC ceramics using B₄C-SiC composite powders prepared by: (c) ball milling and (d) high-energy ball milling⁹⁸ (reprinted with permission, Copyright 2013, Elsevier).

synthesized via usual wet ball milling, there are a lot of pores and separate fine powders (Fig. 4c); the relative density of the ceramics is 85%. However, under the same sintering conditions, few pores and no separate fine powders exist in the B₄C-SiC ceramics produced from the B₄C-SiC composite powders synthesized via high-energy ball milling (Fig. 4d), whose relative density is up to 96%. With the same particle size and sintering conditions, using high-energy ball milling to prepare B₄C-SiC composite powders can decrease the sintering temperature and promote the sintering for the preparation of B₄C-SiC ceramics. High-energy ball milling can induce transformation of B4C and SiC composite powders from an ordered to disordered structure during the milling process; then these composite powders with a disordered structure are transformed into B4C-SiC ceramics with an ordered structure in the subsequent sintering process. The energy released during the transformation of disorderorder can serve as a sintering driving force. Therefore, using the composite powders prepared by high-energy ball milling can improve the sintering performance of B₄C-SiC ceramics.

Some previous studies on the effect of the powder mixing method on the sintering performance and microstructure of B_4C -SiC ceramics are tabulated in Table 3.

3.3.2. Preparation of the green body. For some preparation methods of B_4C -SiC ceramics, such as pressureless sintering and reaction-bonded sintering, multiple single-component powders need to be pre-compacted into the green body. At first, the mixed composite powders are loosely stacked in the mold; even after the compaction, there are still a large number of pores present in the green body. The improvement of the relative density of the green body can increase the relative density and mechanical properties of the resulting ceramics.

As mentioned in Section 3.2.1, the particle size and packing structure affect the relative density of the green body.

Table 3 Effect of t	he powder mixing method on the	Table 3 Effect of the powder mixing method on the sintering performance and microstructure of B ₄ C–SiC ceramics	ure of B ₄ C–SiC ceramics					
Ceramics	Raw material	Powder mixing method	Sintering method	Sintering temperature (°C)	Sintering aid	Relative density (%)	Phase composition	Average grain size (µm)
SiC-10 wt% B_4C^{71}	B_4C , SiC	Dry mixing	Spark plasma (50 MPa)	$1950 (\times 5 min)$	1.5 wt% C	98.6	B4C, SiC, C	
SiC-10 wt% B_4C^{71}	B_4C , SiC	Wet mixing (ethanol)	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B ₄ C, SiC, C	
SiC-20 wt% B_4C^{71}	B_4C , SiC	Dry mixing	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C	98.7	B_4C , SiC, C	
SiC-20 wt% B_4C^{71}	B_4C , SiC	Wet mixing (ethanol)	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B_4C , SiC, C	
SiC-30 wt% B_4C^{71}	B_4C , SiC	Dry mixing	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B_4C , SiC, C	
SiC-30 wt% B_4C^{71}	B_4C , SiC	Wet mixing (ethanol)	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B_4C , SiC, C	
SiC-40 wt% B_4C^{71}	B_4C , SiC	Dry mixing	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B_4C , SiC, C	
SiC-40 wt% B_4C^{71}	B_4C , SiC	Wet mixing (ethanol)	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B_4C , SiC, C	
SiC-50 wt% B_4C^{71}	B_4C , SiC	Dry mixing	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B_4C , SiC, C	
SiC-50 wt% B_4C^{71}	B_4C , SiC	Wet mixing (ethanol)	Spark plasma (50 MPa)	$1950 (\times 5 \text{ min})$	1.5 wt% C		B_4C , SiC, C	
B_4C -50 wt% SiC ⁹⁸	$B_4C (0.7 \ \mu m)$, SiC (0.8 μm)	Ball milling (ethanol)	Hot-press (30 MPa)	1950	No		B_4C , SiC	1.0
B_4C -50 wt% SiC ⁹⁸	B_4C (2.57 µm), SiC (3.11 µm), mean particle size of 0.7 µm after high-energy ball milling	High-energy ball milling (ethanol)	Hot-press (30 MPa)	1950	No	96.0	B_4C , SiC	<1.0

Furthermore, to achieve the maximal relative density of the green body without generating internal cracks, the compaction pressure during compaction should be taken into account.⁹⁹ A suitable compaction pressure is rather important to achieve the maximal relative density of the ceramic preform. Hayun *et al.*⁸⁴ found that the relative density of the green body composed of either graded B_4C particles or monosized fine B_4C particles increases with an increase in compaction pressure from 40 to 160 MPa. The relative density remains constant under a higher compaction pressure (180 MPa); however, excessive compaction pressure may result in the generation of internal cracks in the green body.

Warm pressing is one of the methods to increase the relative density of the green body. Adding a polymer into ceramic powders and pressing the green body above the softening temperature of the polymer can lead to the production of a green body with higher relative density by using the viscous flow of the polymer, thus improving the relative density and mechanical properties of the obtained ceramic. As mentioned in Section 3.2.3, the addition of PCS, which can be used as a precursor of SiC, can increase the relative density of the green body by warm pressing at 300 °C.

For the green body produced for the preparation of reactionbonded B₄C-SiC ceramics, interconnected pores that can provide a penetration path for molten Si are necessary; thus, a necessary minimum porosity should be provided for capillary impregnation. Meanwhile, the high volume expansion caused by the siliconisation reaction easily blocks the capillary channels, inhibiting Si infiltration; thus, the pore size also needs to be considered. Both pore volume fraction and pore size control the impregnation efficiency and phase composition. On the one hand, increasing pore parameters can improve the impregnation efficiency of molten Si and increase the amount of SiC generated;⁷⁷ on the other hand, decreasing pore parameters contributes to limiting the fraction of residual non-reacted Si after infiltration.⁸⁴ Therefore, it is necessary to balance the two aspects to achieve an optimum relative density of the green body. In addition, the addition of C affects the porosity of the green body. Li et al.⁷⁶ found that carbon black can decrease the open pore size of the green body prepared by slip casting, but can increase the porosity of the green body, which is attributed to the particle agglomeration and consequently increased slipcasting slurry viscosity.

For the reaction-bonded B_4C -SiC ceramics, the properties of the green body decide the final properties of the ceramics. The forming technique for the green body affects the microstructures of the green body and the resulting B_4C -SiC ceramics. Conventionally, the green body composed of B_4C and carbon black is prepared by uniaxial compaction. However, the distribution of density and pores in the green body is not uniform *via* this route due to the inhomogeneous mold pressure, leading to the formation of some inhomogeneous carbon black agglomerates,¹⁰⁰ which in turn is not conducive to the homogenization of the microstructure of the obtained B_4C -SiC ceramics; many largesized SiC zones and relatively large, uneven residual Si phases are formed in the obtained ceramics.¹⁰¹ Xu *et al.*¹⁰² found an

alternative solution to prepare the green body with a uniform microstructure, viz., gel-casting technique. A hierarchical porous B₄C-C green body with both mesopores and macropores is produced by the gel-casting method. The polymerization-induced phase separation and pyrolysis result in the formation of mesopores on the carbon matrix; the space occupied by solvent becomes macropores after evaporation. The hierarchical porous green body is suitable for the molten Si infiltration process and favors the reduction in the size of residual Si islands. Upon molten Si infiltration, such hierarchically porous structure in the Cbonded B₄C green body prepared by the gel-casting method can not only improve the uniformity of the microstructure but also generate a SiC-bonded B₄C scaffold structure in the resulting B₄C-SiC ceramics. In addition, the pore structure and porosity of the green body will control the content and size of the residual Si, which in turn affects the mechanical properties of the reactionbonded B₄C-SiC ceramics. Therefore, the performance of reactionbonded B₄C-SiC ceramics can be adjusted by controlling the pore characteristics of the green body. Ren et al.¹⁰³ found that adjusting the content of the catalyst Na₂CO₃ can help control the pore characteristics of the B₄C-C green body prepared by gel-casting, whose mechanism is that the degree of cross-linking within the gel is modified to control the phase separation process by adjusting the content of the catalyst. With an increase in catalyst content, the porosity and pore size of the green body decrease, and the pore structure of the green body changes from a single macroporous or mesoporous structure to a hierarchical macroporous-mesoporous structure, reducing the residual Si content in the B₄C-SiC ceramics.

3.3.3. Parameters during sintering

3.3.3.1. Sintering temperature. Sintering temperature is a crucial parameter for the preparation of B_4C –SiC ceramics in the sintering process. Generally, increasing the sintering temperature can accelerate the diffusion rate of atoms, which is beneficial for improving the densification of B_4C –SiC ceramics. Also, the grain size of B_4C –SiC ceramics increases with an increase in sintering temperature; however, excessive sintering temperature can cause grain coarsening and abnormal grain growth. For reaction-bonded sintering, increasing infiltration temperature can enhance the liquid–solid wettability and liquid Si fluidity,¹⁰⁴ thus improving its permeability in the preform; meanwhile, high temperature will accelerate the diffusion of C atoms in molten Si, accelerating the grain growth of SiC.^{105,106}

For B₄C–SiC ceramics produced *via* pressureless sintering, Zhu *et al.*¹⁰⁷ studied the effect of sintering temperature in the range of 2100 to 2200 °C on the sintering performance and microstructure of B₄C–15 wt% SiC ceramics under the mechanism of solid-state sintering. The phase composition of the composite ceramics is B₄C, SiC, and graphite after sintering at different temperatures. The formation of graphite suggests that amorphous carbon black that is used as a sintering aid undergoes crystallization, whose degree increases with the increase in sintering temperature. The relative density of B₄C–SiC ceramics increases first and then decreases with increasing temperature from 2100 to 2200 °C; the grain size of the ceramics increases with an increase in sintering temperature. At 2100 °C, most of the

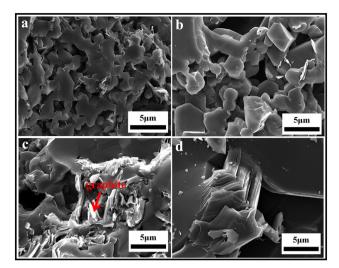


Fig. 5 Fracture surfaces of pressureless sintered B_4C -15 wt% SiC ceramics sintered at: (a) 2100 °C, (b) 2125 °C, (c) 2150 °C, and (d) 2175 °C¹⁰⁷ (reprinted with permission, Copyright 2019, Elsevier).

sintered necks do not grow, and there are a lot of pores in the matrix (Fig. 5a). With an increase in sintering temperature to 2150 °C, sintered necks grow gradually, and the number of pores is reduced (Fig. 5b and c). Meanwhile, some fine SiC grains uniformly distribute at the grain boundary, pinning the migrating grain boundaries and inhibiting the growth of B₄C grains. The lamellar graphite is located on the surface of B₄C grains. However, when the sintering temperature is further increased to more than 2150 °C, the movement of the grain boundary is so rapid that pores cannot be eliminated, resulting in the decreased relative density of B4C-SiC ceramics. Also, the sizes of lamellar graphite and pore increase (Fig. 5d). Vandeperre and Teo¹⁰⁸ investigated the effect of sintering temperature in the range of 1950 to 2200 °C on the sintering performance of B₄C-SiC ceramics with different ratios of B4C to SiC. The relative density of SiC-rich ceramics can reach up to 95% after sintering at 2050 °C. However, higher sintering temperatures are needed for B4C-rich ceramics to achieve better sintering performance, and the relative density of B₄C-rich ceramics is 95% only after sintering at 2200 °C. This phenomenon may be caused by the greater proportion of covalent bonds in B₄C. Moradkhani and Baharvandi⁸⁰ found that the grain size of B₄C-10 wt% SiC ceramics slightly increases with the increase in sintering temperature from 2100 to 2200 °C. In addition, the excessive sintering temperature is also not beneficial for improving the densification of B4C-SiC ceramics under the mechanism of liquid-phase sintering. Zhang et al.¹⁰⁹ observed that the relative density of SiC-10 wt% B4C ceramics with the sintering aids of Al₂O₃ and La₂O₃ increases first and then decreases with the increase in sintering temperature from 1800 to 1935 °C. Higher sintering temperatures result in the volatilization of the liquid phase with a low melting point and the anisotropic growth of the SiC grains, decreasing the relative density.

For B_4C -SiC ceramics prepared by hot-press sintering, Zhang *et al.*⁹⁸ reported that the relative density of B_4C -50 wt% SiC ceramics increases linearly with an increase in sintering temperature in the

range of 1800–1950 °C. At 1800 °C, the densification of B_4C –SiC ceramics begins, but most of the particles are not sintered. When the sintering temperature rises to 1950 °C, there are few pores in the ceramics and the relative density of B_4C –SiC ceramics is up to 96%. Chen *et al.*¹¹⁰ found that the grains of B_4C –20 wt% SiC ceramics become smaller and the microstructure becomes denser with the increase in sintering temperature from 1800 to 1900 °C, which is attributed to the elimination of pores between grains due to the movement of grain boundaries with the increase in sintering temperature.

For spark plasma sintered B₄C-SiC ceramics, Wu et al.¹¹¹ observed that the relative density of the B4C-20 vol% SiC ceramics increases with the increase in sintering temperature from 1900 to 2100 °C. When the sintering temperature is lower than 2000 °C, a large number of pores exist in the ceramics, but many sintered necks have been formed. When the sintering temperature is 2000 °C, the grown grains are tightly connected, and the pores almost completely disappear. When the sintering temperature is higher than 2000 °C, the microstructure of the ceramics no longer changes significantly. Moshtaghioun et al.¹¹² reported that the grain sizes of both B₄C and SiC in the B₄C-15 wt% SiC ceramics are independent of the sintering temperature in the range of 1650 to 1700 °C. Although the particle sizes of B₄C and SiC raw materials are the same, the B₄C grains are larger than the SiC grains in the resulting B₄C-SiC ceramics. This is because B_4C is the connected phase in the microstructure; as a result, the diffusion of B and C resulting in B₄C grain growth is easier.

The sintering temperature not only affects the porosity and grain size but also affects the crystallization of B_4C -SiC ceramics. Zhang *et al.*^{94,95} noted that the structure of B_4C -SiC ceramics undergoes a disorder-order transformation from 1700 to 1900 °C *via* hot-press sintering or from 1600 to 1700 °C *via* spark plasma sintering when B_4C -SiC composite powders composed of B_4C with increased volume of lattice defects and amorphous SiC, which are prepared by high-energy ball milling, are used as raw materials. This indicates that increasing the sintering temperature within a certain range can increase the stacking order of the structure.

For B₄C-SiC ceramics fabricated by reaction-bonded sintering, because the melting temperature of Si is 1410 °C, there is little difference in phase composition between the sintered ceramics and the original powder mixture when the sintering temperature is lower than 1410 °C, indicating that no reaction occurs among B₄C, C, and Si.¹¹³ When the sintering temperature is higher than 1410 °C, Si can melt and infiltrate into the top part of the green body to rapidly react with C to form β -SiC.¹¹³ Although Si can infiltrate into the green body composed of B₄C and graphite, the resulting B₄C-SiC ceramics are still quite porous because the viscosity of molten Si at 1410 °C is relatively high, preventing the infiltration to the porous green body. This suggests that infiltration temperature affects the viscosity of molten Si, and a sufficient temperature is needed to ensure a good fluidity of molten Si. With the increase in sintering temperature to 1450 $^{\circ}$ C, the reaction between B₄C and Si is further promoted; thus, the obtained B₄C-SiC ceramics are very dense and nearly nonporous. Ordan'yan et al.¹¹⁴

also pointed out that the temperature of the impregnation process (1450-1800 °C) generally exceeds the melting temperature of Si, resulting from the need to decrease the viscosity of Si melt and enhance the wetting of B_4C and C to facilitate capillary impregnation. Therefore, 1410 °C is a critical temperature for Si infiltration and reaction bonding. Nesmelov and Perevislov¹¹⁵ mentioned that the temperature interval of 1600-1800 °C is sufficient for Si viscosity to wet the total porous preform. Sun et al.¹¹⁶ noted that the relative density of B₄C-SiC ceramics increases with the increase in sintering temperature from 1660 to 1780 °C. During the molten Si infiltration, C atoms on carbon particles are dissolved at the Si/C interface where a submicron SiC layer is formed; then this SiC layer rapidly cracks into crystalline particles because of the lattice mismatch between the carbon particles and SiC layer. After being dissolved in molten Si, the crystalline SiC particles precipitate on the initial SiC particles. Therefore, the dissolution rate of C atoms and the precipitation rate of crystalline SiC are the main factors affecting the reaction rate. A high sintering temperature is beneficial for increasing the solubility of C atoms and crystalline SiC, improving the reaction rate.

When the infiltration temperature is higher than 1410 $^{\circ}$ C, the sintering temperature will affect the phase amount of reactionbonded B₄C–SiC ceramics. Zhang *et al.*¹¹⁷ found that the amount of B₄C decreases, but the amounts of generated SiC phase and residual Si phase increase with the increase in infiltration temperature from 1450 to 1650 $^{\circ}$ C. On the one hand, the solubility of B and C in molten Si increases with an increase in infiltration temperature, leading to the increased amount of dissolved B₄C particles; on the other hand, the interface reaction between B₄C and molten Si (reaction (3)), which is negligible at 1450 $^{\circ}$ C but significant at 1650 $^{\circ}$ C, is gradually intensified with increasing infiltration temperature, causing further dissolution of B₄C particles in molten Si and increasing the amounts of generated SiC and precipitated B₁₂(C, Si, B)₃ on the original B₄C particles.

$$3B_4C(S) + Si(l) \rightarrow SiC(S) + B_{12}(C, Si, B)_3(S)$$
 (3)

Moreover, the grain shape and grain size of reaction-bonded B₄C–SiC ceramics are also affected by the infiltration temperature.¹¹⁸ When the sintering temperature is 1450 °C, the grain shape of B₄C basically maintains the original irregular shape of initial B₄C particles with flexuous edges due to the mild dissolution of B_4C grains in molten Si at temperatures below 1550 °C. When the sintering temperature is increased to 1650 °C, the shape of partial large B₄C grains evolves from an irregular shape to a faceted shape with sharp corners and straight edges; the small B₄C grains evolve into a spherical shape because the dissolution of B4C grains in molten Si is intensified. The grain shape evolution of B₄C can be described by Ostwald ripening: the dissolution of the smaller grains and the precipitation of dissolved components on the grains that are larger than the critical ones.119 The dissolved materials transfer and precipitate as $B_{12}(B, C, Si)_3$ on the defective concave surface of the large B_4C grains. Thus, the large B₄C grains exhibit the growth shape and the small grains show the dissolution shape. When the sintering

temperature is further increased to 1750 °C, the grain shape of B₄C is mostly faceted. Zhang *et al.*¹¹⁷ also observed that the B₄C particles with the precipitation of $B_{12}(C, Si, B)_3$ gradually develop a multifaced surface morphology with angular shapes and triangular prisms when the sintering temperature is between 1600 and 1650 °C. Meanwhile, the shape of the formed SiC is also affected by the sintering temperature.¹¹⁷ The SiC morphology evolves from discontinuous, cloud-like SiC to continuous, integrated SiC zones with the increase in sintering temperature from 1450 to 1650 °C. With the increase in the amount of generated SiC, the original discontinuous SiC grains coalesce and connect to each other, forming continuous, integrated SiC zones. Also, the amount and size of these integrated SiC zones increase with an increase in sintering temperature. On the other side, the grain sizes of both B₄C with the precipitation of $B_{12}(C, Si, B)_3$ and generated SiC particles increase with an increase in infiltration temperature.¹¹⁷ The increased grain size of B₄C with the precipitation of $B_{12}(C, Si, B)_3$ is attributed to the coalescence of neighboring B₄C particles. With the increase in infiltration temperature, there is a greater precipitation of the $B_{12}(C, Si, B)_3$ phase on the surfaces of original B₄C particles, increasing the chance for neighboring B4C particles to coalesce. Most SiC grains are generated via the reaction between molten Si and carbon black, which is controlled by the dissolution-precipitation mechanism at the beginning,¹⁰⁵ and then by the diffusion of Si and C atoms in solid SiC when molten Si is not in contact with C.¹⁰⁶ With the increase in infiltration temperature, the dissolution of C in molten Si is promoted because of the higher solubility of C in molten Si, and the diffusion of Si and C atoms in solid SiC is accelerated; thus, the generated SiC grains grow and ripen at higher temperatures. Zhang et al.¹¹⁸ pointed out that the growth behavior of B_4C grains depends on the sintering temperature and the grain shape. The grain size of B₄C increases with an increase in the sintering temperature. When the sintering temperature is below 1750 °C, the B₄C grains show a unimodal size distribution, suggesting normal grain growth; the grain growth of B4C is primarily controlled by diffusion. However, when the sintering temperature is above 1750 °C, the B4C grains exhibit a bimodal size distribution, indicating an abnormal grain growth; the grain growth of B₄C is controlled by coalescence-enhanced two-dimensional nucleation. Abnormal grain growth only occurs when the grain shape of B₄C is faceted.

Some previous studies on the effect of sintering temperature on the sintering performance and microstructure of B_4C -SiC ceramics are tabulated in Table 4.

3.3.3.2. Holding time. Holding time is another factor affecting the microstructure and phase composition of B_4C -SiC ceramics. Tomohiro *et al.*⁷⁸ reported that the grain size of the hot-press sintered B_4C -15 vol% SiC ceramics increases from 2–3 to 10 µm with the increase in holding time from 30 to 120 min when the sintering temperature is 2200 °C; however, the relative density of the ceramics is independent on the holding time. For reaction-bonded B_4C -SiC ceramics, when the sintering temperature is fixed at 1550 °C, increasing the holding time can enhance the transformation of B_4C grains from irregular shape to faceted

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Ceramics	Raw material	Sintering method	Sintering temperature (°C)	Sintering aid	Relative density (%)	Phase composition	Average grain size (µm)
$B_4C-15 wt\% SiC^{107}$		Pressureless	2100	2 wt% carbon black	91.6 02.6	B ₄ C, SiC, graphite	2.3
B4C-15 wt% SIC ¹⁰⁷	В4С (0.8 µпп), S1С (0.5 µпп) В4С (0.8 µm). SiC (0.5 µm)	Pressureless	2150	2 wt% carbon black 2 wt% carbon black	93.0 95.3	— B.C. SiC. graphite	11.2
$B_4C-15 \text{ wt\% SiC}^{107}$	(0.8 μm), SiC	Pressureless	2175	2 wt% carbon black	93.1		17.2
$B_4C-15 \text{ wt\% SiC}^{107}$	B_4C (0.8 µm), SiC (0.5 µm)	Pressureless	2200	2 wt% carbon black		I	27.9
$B_4C-10 \text{ vol}\% \text{ SiC}_{S0}^{80}$	B_4C (307 nm), SiC (1.0 μ m)	Pressureless	2100	No		B_4C , SiC	14.1
B_4C-10 vol% SiC ⁸⁰	B_4C (307 nm), SiC (1.0 μ m)	Pressureless	2150	No	Ι	B_4C , SiC	14.3
$B_4C-10 \text{ vol}\% SiC^{80}$	B_4C (307 nm), SiC (1.0 μ m)	Pressureless	2200	No		B ₄ C, SiC	14.8
SiC-10 wt% B_4C^{109}	α-SiC (1.0 μm), B₄C (0.5 μm)	Pressureless	1800	$10 \text{ wt\%} (\text{Al}_2\text{O}_3 : \text{La}_2\text{O}_3 = 1 : 1, \text{molar ratio})$	90.2	SiC, B₄C, LaAlO₃	
SiC-10 wt% B_4C^{109}	α-SiC (1.0 μm), B ₄ C (0.5 μm)	Pressureless	1835	10 wt% $(Al_2O_3: La_2O_3 = 1:1)$	91.8	SiC, B ₄ C, LaAlO ₃	
2109		-		molar ratio)			
SiC-10 wt% B_4C^{10}	α-SiC (1.0 μm), B₄C (0.5 μm)	Pressureless	1875	10 wt% (Al ₂ O ₃ : La ₂ O ₃ = 1 : 1, molar ratio)	94.0	SiC, B₄C, LaAlO ₃	
SiC-10 wt% B_4C^{109}	α-SiC (1.0 μm), B_4C (0.5 μm)	Pressureless	1900	$10 \text{ wt\%} (Al_2O_3 : La_2O_3 = 1:1,$	96.8	SiC, B ₄ C, LaAlO ₃	
SiC-10 wt% B_4C^{109}	α-SiC (1.0 μm), B_4C (0.5 μm)	Pressureless	1935	molar ratio) $10 \text{ wt\%} (\text{Al}_2\text{O}_3: \text{La}_2\text{O}_3 = 1:1,$	95.3	SiC, B ₄ C, LaAlO ₃	
				molar ratio)			
$B_4C-50 wt\% SiC^{98}$	B_4C , SiC, mean particle size of 0.7 μm	Hot-press (30 MPa)	1800	No	74.0	B_4C , SiC	I
$B_4C-50 wt\% SiC$	B_4C , SiC, mean particle size of 0.7 μ m	Hot-press (30 MPa)	1850	No	79.2	B4C, SiC	Ι
B4C-50 WT% SIC	B ₄ C, SIC, mean particle size of 0./ μm D C siC mean muticle size of 0.7 μm	Hot-press (30 MPa) Hot-press (20 MPa)	1060	NO	89.2 06 4		
B.C ¹¹⁰	B.C. (0.8 mm)	Hot-press (30 MPa) Hot-press (30 MPa)	1800	$100 \text{ wr}(6 \text{ A}_{-} \text{ O}_{-} + \text{ V}_{-} \text{ O}_{-})$	4.06 07 0	B.C.	
$B_{4}C-20 \text{ wt\% SiC}^{110}$	B,C (0.8 um). SiC (0.45 um)	Hot-press (30 MPa)	1800	$10 \text{ wt\%} (A_{1}^{2}O_{3} + Y_{2}O_{3})$	94.0	B_{AC} . SiC	I
$\mathrm{B_4C^{110}}$		Hot-press (30 MPa)	1900	$10 \text{ wt\% } (\text{Al}_2 \text{O}_3 + \text{Y}_2 \text{O}_3)$	98.6	B_4C	
B ₄ C-20 wt% SiC ¹¹⁰	0.8 µm), SiC	Hot-press (30 MPa)	1900	10 wt% $(Al_2O_3 + Y_2O_3)$		B_4C , SiC	
$B_4C-20 \text{ vol}\% \text{ SiC}^{111}$	(3.5 μm), SiC	Spark plasma (40 MPa)	$1900 (\times 10 \text{ min})$	No		B_4C , SiC	Ι
$B_4C-20 \text{ vol}\% \text{ SiC}^{111}$	(3.5 μm), SiC	Spark plasma (40 MPa)	$1950 (\times 10 \text{ min})$	No	91.0	B_4C , SiC	
B ₄ C-20 vol% SiC ¹¹¹		Spark plasma (40 MPa)	$2000 (\times 10 \text{ min})$	No		B4C, SiC	Ι
B4C-20 VOI% SIC	B4C (3.5 μm), SIC (0.5 μm) Β C (3 5 μm) SiC (0 5 μm)	Spark plasma (40 MPa)	$2050 (\times 10 \text{ min})$	NO NO	90.0 06.0		
B C-15 wt06 SiC ¹¹²		Spark plasilia (40 MFa) Spark plasma (75 MDa)	2100 (×10 IIIII) 1650 (×5 min)	NO	90.0 06.6		— B C: 0 537
DIC 0/1M CT-DFG	()	opain piasilla (7.2 Mra)			0.06	D40, 010	B4C: 0.05-0.25
$B_4C-15 wt\% SiC^{112}$	B₄C (0.5 μm), β-SiC (0.5 μm)	Spark plasma (75 MPa)	1700 (×3 min)	No	99.4	B_4C , SiC	$B_4C: 0.537, \ldots$
D C-30 m+0% c;C ⁹⁴	D C CiC maan nontiolo circo of E0 1E0 nm	Uot-meee (30 MDa)	1000		C 10	ניטיים	SIC: 0.05-0.25
B ₄ C-20 wt% SiC ⁹⁴	B ₄ C, SiC, mean particle size of 50–150 nm	Hot-press (30 MPa)	1950	No		B_4C , SiC	$B_4C = 1.0-3.0,$
				;			SiC < 2.0
$B_4C-20 \text{ wt\% SiC}^{-20}$	B ₄ C, SiC, mean particle size of 50–150 nm	Spark plasma (30 MPa)	$1700 (\times 5 \text{ min})$	No	96.7 08.2	B4C, SIC	
D4C-20 WL%0 31C	B4C, SIC, IIICAII PARUCIE SIZE UI 30–130 IIIII D C SiC maan nartiolo sizo of 50 150 nm		$1/50 (\times 5 \text{ min})$		90.3 00.7		
D40-20 WL% 210	$B_4 \cup$, SIC, IIIEAII PALICIE SIZE OL SU-13U IIII			NO	73.66	D4C, 31C	$B_4 C = 1.0$, SiC < 1.0
B_4C-SiC^{113}	B_4C (45 µm), graphite (10 µm), Si lump	Reaction	1380	No		B ₄ C, graphite	
B_4C-SiC^{113}	B_4C (45 µm), graphite (10 µm), Si lump	Reaction	1410	No		B ₄ C, SiC, graphite, B ₄ C si B) B C si	
$\mathrm{B_4C}{-\mathrm{SiC}^{113}}$	$\mathrm{B_4C}~(45~\mu\mathrm{m}),$ graphite (10 $\mu\mathrm{m}),$ Si lump	Reaction	1450	No	I	B ₄ C, SiC, graphite,	I
SiC-50 wt% B ₄ C ¹¹⁶	$B_{4}C$ (1.5 µm), α -SiC (7.0 µm), phenolic resin,	Reaction	1660	No	92.7	D12(U,J1,D)3, D10U, J1 	I
	carbon black, Si powder						
SiC-50 wt% B ₄ C ¹¹⁶	B_4C (1.5 µm), α -SiC (7.0 µm), phenolic resin, carbon black Si nowder	Reaction	1690	No	94.6	1	
	cal DOLL DIACN, DI POWACI						

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Review

Table 4 (continued)

Ceramics	Raw material	Sintering method	Sintering temperature (°C)	Sintering aid	Relative density (%)	Average g Phase composition size (µm)	Average grain size (µm)
SiC-50 wt% B ₄ C ¹¹⁶	SiC-50 wt% $B_4 C^{116} = B_4 C$ (1.5 µm), $\alpha\text{-SiC}$ (7.0 µm), phenolic resin, carbon black, Si powder	Reaction	1720	No	97.2	I	1
SiC-50 wt% B ₄ C ¹¹⁶		Reaction	1750	No	98.0		I
SiC-50 wt% B ₄ C ¹¹⁶	- ·	Reaction	1780	No	98.2		Ι
$\mathrm{B_4C} ext{-SiC}^{117}$	B_4C (4.08 μ m), carbon black, Si lump	Reaction	1450	No	8.66	$\mathrm{B_4C, SiC,} \mathrm{B_{12}(C,Si,B)_3, Si}$	B ₄ C: 2.9, SiC: 5.8
B_4C-SiC^{117}	$\mathrm{B_4C}\ (4.08\ \mathrm{\mu m}),$ carbon black, Si lump	Reaction	1500	No	99.8	B_4C , SiC, $B_{12}(C,Si,B)_3$, Si	B ₄ C: 3.2, SiC: 5.8
$\mathrm{B_4C-SiC^{117}}$	$\mathrm{B_4C}$ (4.08 $\mu\mathrm{m}$), carbon black, Si lump	Reaction	1550	No	6.66	B_4C , SiC, $B_{12}(C,Si,B)_3$, Si	B ₄ C: 3.3, SiC: 6.0
$\mathrm{B_4C} ext{-SiC}^{117}$	$\rm B_4C~(4.08~\mu m),$ carbon black, Si lump	Reaction	1600	No	6.66	B_4C , SiC, $B_{12}(C,Si,B)_3$, Si	B ₄ C: 3.8, SiC: 6.5
B_4C-SiC^{117}	B_4C (4.08 µm), carbon black, Si lump	Reaction	1650	No	8.66	B_4C , SiC, $B_{12}(C,Si,B)_3$, Si	B ₄ C: 4.6, SiC: 6.7

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shape, and most of the B₄C grains evolve to the faceted shape after infiltration for 40 h.118 Karandikar et al.120 found that infiltration time has an effect on the phase composition of the reaction-bonded B4C-SiC ceramics. When the infiltration temperature is 1530 °C, only the β -SiC phase is present at low infiltration time (60–120 min); however, some α -SiC is generated at a longer infiltration time (240-360 min), and the α -SiC content increases with the increase in infiltration time. Meanwhile, part of the B_4C phase is converted to the $B_{4-r}Si_rC$ phase when the infiltration time is within 60-120 min, while all the B_4C phase is converted to the $B_{4-x}Si_xC$ phase when the infiltration time is within 240-360 min. This indicates that the conversion of the B_4C phase to the $B_{4-r}Si_rC$ phase is a timedependent phenomenon, whose mechanism is the diffusion of Si into the B₄C grain (lattice) or solution of the B₄C grain in molten Si and reprecipitation.

3.3.3.3. Sintering pressure. For some preparation methods, B_4C -SiC ceramics have to be sintered under a pressure, such as hot-press sintering and spark plasma sintering; pressure causes particle rearrangement, plastic flow, and grain boundary movement, promoting the sintering of B_4C -SiC ceramics. The sintering pressure will affect the sintering performance and microstructure of B_4C -SiC ceramics. According to Rahaman,¹²¹ in the presence of sintering pressure, the densification rate of the ceramic can be described as follows:

$$\rho = \frac{1 \, \mathrm{d}\rho}{1 \, \mathrm{d}t} = \frac{HD(\Phi P_{\mathrm{a}})^n}{G^m kT} \tag{4}$$

where ρ is the densification rate, *H* is a numerical constant, *D* is the diffusion coefficient of the rate-controlling species, Φ is the intensification factor, P_a is the applied pressure, *G* is the grain size, *k* is the Boltzman constant, and *T* is the absolute temperature. When other factors are constant, the densification rate is exponentially influenced by the sintering pressure. Chen *et al.*¹²² found that the hot-press sintered B₄C-20 wt% SiC ceramics becomes denser and the grain size becomes smaller as the sintering pressure increases from 30 to 40 MPa (Fig. 6). During the sintering process, the growth of B₄C and SiC grains is inhibited due to the higher sintering pressure, leading to the formation of more refined grains.

Some previous studies on the effect of sintering pressure on the sintering performance and microstructure of B_4C -SiC ceramics are tabulated in Table 5.

3.4. Sintering aid

 B_4C -SiC ceramics are difficult to sinter to obtain a sufficiently dense product, especially in the absence of externally applied pressure during sintering. Generally, a sintering temperature higher than 2000 °C is required to obtain a dense B_4C -SiC ceramics produced *via* hot-press sintering without sintering aids. Thus, to reduce the sintering temperature, one approach is to add sintering aids to promote the densification of B_4C -SiC ceramics; also, the use of some sintering aids can hinder grain growth. Various elements and compounds have been sought as suitable sintering aids for B_4C -SiC ceramics. The application of

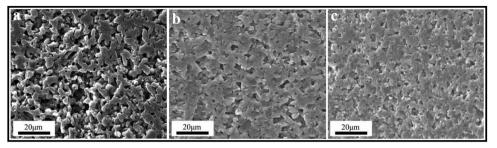


Fig. 6 Microstructure of hot-press sintered B_4C-20 wt% SiC ceramics sintered under different sintering pressures: (a) 30 MPa, (b) 35 MPa, and (c) 40 MPa.¹²²

Table 5	Effect of sintering pressure	on the sintering performance and	I microstructure of B ₄ C–SiC ceramics
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Ceramics	Raw material	Sintering method	Sintering temperature (°C)	Sintering pressure (MPa)	Sintering aid	Relative density (%)	Phase composition	Average grain size (μm)
B_4C-20 wt% SiC ¹²²	$\begin{array}{l} B_4C \; (0.8\; \mu m), SiC \; (0.45\; \mu m) \\ B_4C \; (0.8\; \mu m), SiC \; (0.45\; \mu m) \\ B_4C \; (0.8\; \mu m), SiC \; (0.45\; \mu m) \end{array}$	Hot-press	1900	30 35 40	$\begin{array}{c} 10 \ wt\% \ \left(Al_2O_3+Y_2O_3\right) \\ 10 \ wt\% \ \left(Al_2O_3+Y_2O_3\right) \\ 10 \ wt\% \ \left(Al_2O_3+Y_2O_3\right) \end{array}$	98.6	B_4C , SiC B_4C , SiC B_4C , SiC	_ _ _

sintering aids can affect the sintering performance and microstructure of B_4C -SiC ceramics. The sintering mechanisms of B_4C -SiC ceramics with the addition of sintering aids include solid-state sintering and liquid-phase sintering. Under the solid-state sintering mechanism, no liquid phase is generated; thus, B_4C -SiC ceramics have sufficient strength, especially at high temperatures. However, the sintering temperature for B_4C -SiC ceramics is relatively high. For liquid-phase sintering, liquid phases are formed at high temperatures. B_4C -SiC ceramics can be densified at relatively low temperatures; however, some amorphous secondary phases are generated at grain boundaries, causing grain coarsening, changing the crack propagation mode, and reducing the strength of B_4C -SiC ceramics.

3.4.1. C. Generally, oxide films (B_2O_3/H_3BO_3 , SiO₂) are easily formed on the surfaces of B_4C and SiC raw powders during processing and storage. These oxide film impurities contribute to the evaporation-condensation process in the sintering process, resulting in the coarsening of grain rather than densification.¹²³ To prepare dense B_4C -SiC ceramics, it is necessary to eliminate these oxide film impurities. The addition of C into the B_4C -SiC system is an excellent method because C can remove surface oxides of B_4C and SiC raw powders by reacting with B_2O_3 and SiO₂, respectively, forming carbides and gas according to the following reactions,¹²⁴

$$C + B_2 O_3 \rightarrow B_4 C + CO(CO_2) \uparrow$$
(5)

$$C + SiO_2 \rightarrow SiC + CO(CO_2) \uparrow$$
 (6)

As a result, the surfaces of B_4C and SiC particles are purified, increasing the contact area of sintered particles; thus, the driving force for the densification of B_4C –SiC ceramics is improved. Furthermore, C does not generate a liquid phase in the system; thus, it is used as a sintering aid for solid-state sintering.²³ C can be added in the form of carbon black, phenolic resin, graphite, *etc.* In the case of preparing B_4C -SiC ceramics by pressureless sintering, if the B_4C -SiC composite powders contain a C precursor, the advantages of using such a precursor include: (1) it can serve as a binder and plasticizer for the subsequent cold-pressing process; and (2) it can distribute on the surface of composite powders uniformly and activate the sintering process.

Related studies have shown that C sintering aids can improve the densification of B4C-SiC ceramics. Thévenot20 found that the addition of C can promote the sintering of pressureless sintered B₄C-3.8 wt% SiC ceramics. When the amount of C precursor is 2.5 wt%, the relative density of B4C-SiC ceramics can reach 95%. Most importantly, the obtained composite ceramics do not contain free carbon which is considered to impair the mechanical performance of B4C-SiC ceramics. Furthermore, for B₄C-SiC ceramics with different ratios of B₄C to SiC, an increase in C precursor amount (2-9 wt%) does not change the final relative density (97-98%) of the composite ceramics, but increases the final free C content. Vandeperre and Teo¹⁰⁸ also demonstrated that 3 wt% C addition can allow pressureless sintered B₄C-SiC ceramics with different ratios of B_4C to SiC to achieve a high relative density. Moshtaghioun et al.¹¹² stated that the addition of graphite is beneficial for more intimate contact favoring the diffusion between the powders in B₄C-SiC ceramics during the first moment of spark plasma sintering. First, graphite is an effective processcontrol agent that can minimize the formation of agglomerates during the milling of brittle ceramics.¹²⁵ Second, graphite can lubricate the contacts during the compaction stage, improving the particle packing. As a result, graphite can further promote the densification of spark plasma sintered B4C-SiC ceramics (Fig. 7a and b). The grain sizes of B₄C and SiC in the spark plasma sintered B₄C-SiC ceramics with graphite are slightly larger than those in the B₄C-SiC ceramics without graphite, the reason for which is not explained.126

3.4.2. Oxide. To promote the sintering of B_4C -SiC ceramics, some oxide sintering aids, such as Al_2O_3 and Y_2O_3 , have been

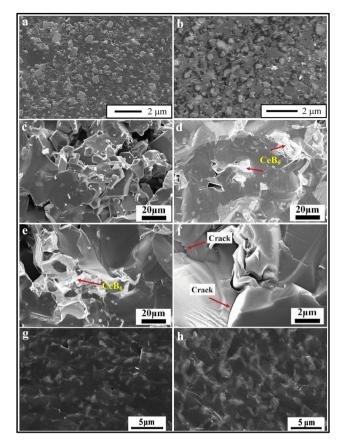


Fig. 7 Microstructure of B₄C–SiC ceramics with different sintering aids: (a) spark plasma sintered B₄C–15 wt% SiC ceramics without graphite and (b) spark plasma sintered B₄C–15 wt% SiC ceramics with 2 wt% graphite¹¹² (reprinted with permission, Copyright 2013, Elsevier); (c) pressureless sintered B₄C–15 wt% SiC ceramics without CeO₂, (d) pressureless sintered B₄C–15 wt% SiC ceramics with 5 wt% CeO₂, and (e) and (f) pressureless sintered B₄C–15 wt% SiC ceramics with 9 wt% CeO₂¹²⁹ (reprinted with permission, Copyright 2019, Elsevier); (g) hot-press sintered B₄C–15 wt% SiC ceramics with 8 wt% Si⁹¹ (reprinted with permission, Copyright 2013, Elsevier).

extensively investigated. Oxide sintering aids are mainly used to achieve liquid-phase sintering.

Jamale and Kumar¹²⁷ found that the addition of Al_2O_3 can improve the densification of spark plasma sintered B₄C-10 wt% SiC ceramics due to the formation of liquid-phase Al₂SiO₅, and the relative density of the obtained ceramics is more than 99%. Sahin et al.⁹⁶ noted that three new phases (YBO₃, YB₄, and YB_2C_2) are formed after 5 wt% Y_2O_3 is added into the spark plasma sintered B₄C-SiC ceramics, and the formation of these liquid phases improves the densification of B₄C-SiC ceramics. Therefore, the relative densities of B₄C-SiC ceramics with the addition of 5 wt% Y2O3 are higher than those of B4C-SiC ceramics without Y₂O₃. Rocha and Melo^{88,89} reported that the addition of sintering aids of Al2O3-Y2O3 or AlN-Y2O3 can promote the sintering of the pressureless sintered B₄C-SiC ceramics. Compared with the sintering aids of Al₂O₃-Y₂O₃, the sintering aids of AlN-Y₂O₃ can better promote the densification of B₄C-SiC ceramics. B₄C-10 wt% SiC ceramics with AlN-Y₂O₃ exhibit the highest relative density. According to the observation

of fracture surfaces of B4C-SiC ceramics with sintering aids of AlN-Y2O3, platelet-shaped SiC grains are formed, which is attributed to the phase transformation from β -SiC to α -SiC at high temperatures. Regarding different sintering aids, on the one hand, it is possible that Al₂O₃ promotes the formation of a more elongated and interlocking structure;¹²⁸ thus, the use of sintering aids of Al₂O₃-Y₂O₃ leads to the formation of more platelet-shaped SiC grains in the B₄C-SiC ceramics, resulting in lower relative densities of B₄C-SiC ceramics with Al₂O₃-Y₂O₃ than those of B₄C-SiC ceramics with AlN-Y₂O₃. On the other hand, AlN can reduce the problem of volatilization of sintering aids at high temperatures. Zhang et al.¹⁰⁹ mentioned that the addition of Al₂O₃-La₂O₃ can promote the sintering of pressureless sintered SiC-10 wt% B4C ceramics, which is attributed to the formation of the LaAlO₃ liquid phase through the reaction between Al₂O₃ and La₂O₃. Zhang *et al.*⁷⁴ noted that the densification of gas-pressure sintered B4C-SiC ceramics can be improved using the Al₂O₃-Er₂O₃-SiO₂ sintering aid system. Al₂O₃ can react with Er₂O₃ and SiO, generating a eutectic point phase, which can reduce the sintering temperature and promote sintering.

Besides the sintering aid systems based on Al_2O_3 or Y_2O_3 systems, rare-earth oxide CeO₂ can also be used as a sintering aid for B₄C–SiC ceramics. Zhu *et al.*¹²⁹ studied the effect of CeO₂ addition on the sintering performance of pressureless sintered B₄C–15 wt% SiC ceramics. The phase compositions of the resulting B₄C–SiC ceramics with different CeO₂ contents are B₄C, SiC, and CeB₆. The formation of CeB₆ is according to the following reaction:

$$(3x+1)B_4C + 2xCeO_2 \rightarrow 2xCeB_6 + 4xCO\uparrow + B_4C_{1-x}$$
(7)

The relative density of the ceramics first increases and then decreases with an increase in CeO₂ content from 0 to 9 wt% (Fig. 7c-f). B₄C-SiC ceramics achieve the highest relative density of 96.4% when the CeO₂ content is 5 wt%. The improvement in the sintering performance of B4C-SiC ceramics by the addition of CeO₂ can be attributed to the following facts. First, the thermal conductivity of CeB_6 formed during sintering is 34.02 W m⁻¹ K⁻¹, which is higher than that of B_4C (13.2 W m⁻¹ K⁻¹); the formation of CeB₆ with a higher thermal conductivity can benefit the delivery of heat quantity, promoting the sintering of B₄C-SiC ceramics.¹³⁰ Second, according to reaction (7), B-rich transition zones, such as B51.02C1.82 and B38.22C6, are formed between CeB6 and B_4C grains, causing local lattice distortion of the B_4C matrix. The lattice distortion can increase the chemical potential energy and consequently the sintering driving force. Furthermore, some vacancies are formed in some local areas, where C atoms combine with O atoms, forming CO gas that escapes from the ceramics, facilitating substance transport. However, when the CeO2 content is more than 5 wt%, more CO gas is generated, and the gas cannot be timely discharged from inside the ceramics, resulting in a large number of residual pores (Fig. 7e). CeB₂ grains grow to form large grains, which introduce large residual stress between B4C and CeB6 as well as cracks because the irregular CeB₆ grains are subjected to uneven forces from the adjacent grains (Fig. 7f). The formation of a large number of pores and cracks results in a decrease in the relative density.

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3.4.3. Si. In addition to C and oxide sintering aids, Si can also be used as a sintering aid for B₄C-SiC ceramics. On the one hand, the addition of an appropriate amount of Si can promote the sintering of the ceramics by forming a liquid phase; on the other hand, free C released from B4C can react with molten Si to form SiC at high temperatures, increasing the SiC content.¹³¹ Du et al.^{91,132} reported that the addition of Si can not only improve the densification of the hot-press sintered B₄C-SiC ceramics produced with PCS as the precursor of SiC because of the formation of the liquid phase (Fig. 7g and h) but also react with C derived from pyrolysis residue of PCS and B₄C powders, increasing the SiC content. The dissolution of Si in B4C can facilitate mass transfer in solid-state sintering of B₄C-SiC ceramics. The content of SiC increases with the increase in the content of added Si, leading to the refinement of B₄C grains. Compared with B₄C-SiC ceramics without Si additives, the grain size of B₄C is smaller in the B₄C-SiC ceramics with Si additives, which is attributed to the more efficient grain boundary pinning by the larger amount of SiC grains. Most SiC grains are located at B₄C grain boundaries; thus these SiC grains are dragged along as grain boundaries move. The more the SiC content, the more obvious the pinning effect is. This suggests that a larger SiC content is more helpful in inhibiting the growth of B₄C grains. Furthermore, the total area of the B_4C -SiC phase boundary increases with the increase in the Si additive; thus, the energy requirements for phase boundary diffusion and phase boundary mobility are increased. Therefore, the introduction of Si can refine B₄C grains. Although the addition of Si slightly increases the grain size of SiC, the average grain size of SiC is still less than 2 μ m. Sahani and Chaira¹³¹ mentioned that the improvement in the sintering performance of SiC-B₄C ceramics depends on the amount of Si added and the sintering method. When the SiC-B₄C ceramics are sintered by pressureless sintering, adding 2 or 5 wt% Si cannot improve the sintering performance of SiC-B₄C ceramics. Vandeperre and Teo¹⁰⁸ also demonstrated that the addition of 4 wt% Si cannot promote the sinterability for pressureless sintered B₄C-SiC ceramics. The mechanism that the low addition of Si cannot promote the sintering for B₄C-SiC ceramics needs to be further studied. However, the sintering performance of pressureless sintered SiC-B4C ceramics is improved when the addition of Si is 10 or 20 wt%.¹³¹ When the SiC-B₄C ceramics are sintered by spark plasma sintering, adding 2, 5, 10, or 20 wt% Si can improve the sintering performance of SiC-B₄C ceramics. The addition of Si is helpful for homogeneous microstructural distribution. When the amount of Si added is 10 wt%, the relative density of SiC-B₄C ceramics prepared by either pressureless sintering or spark plasma sintering is the highest.

Some previous studies on the effect of sintering aids on the sintering performance and microstructure of B_4C -SiC ceramics are tabulated in Table 6.

3.5. Microstructure characteristics of B₄C–SiC composite ceramics

 B_4C -SiC composite ceramics have some unique microstructure characteristics different from those of pure B_4C or SiC ceramics. The microstructure of B_4C -SiC ceramics is controlled by

many factors, which have been discussed in Sections 3.1 to 3.4. In this section, the microstructure characteristics of B_4C -SiC ceramics affected by the sintering mechanism and sintering method are described.

3.5.1. Phase boundary characteristics of B_4C -SiC ceramics prepared by solid-state sintering. Generally, the grain boundary is clean when the ceramics are produced by a solid-state sintering mechanism,¹³³ whereas the intergranular phase exists at the grain boundary when the sintering mechanism is liquid-phase sintering.^{134,135}

For the phase boundary of B₄C-SiC ceramics, Matović et al.⁶⁴ found that there is no amorphous phase or secondary phase at the phase boundary of the ultra-high pressure sintered B₄C-SiC ceramics without sintering aids. Both Zhang et al. 136 and Zhu *et al.*¹⁰⁷ observed that the phase boundary between B₄C and SiC grains in the pressureless sintered B4C-SiC ceramics with the sintering aid of carbon black is clean and clear (Fig. 8). Both B₄C and SiC grains reveal lattice fringes up to the phase boundary, and B₄C and SiC grains are in direct mutual contact. Such phase boundary characteristics indicate that the bonding between B₄C and SiC is very strong. The reason for this phenomenon is that the interplanar spacing between B4C lattice planes and SiC lattice planes matches, leading to the direct connection between lattice planes of B₄C crystals and lattice planes of SiC crystals. This suggests that similar lattice parameters result in a good interfacial structure. Such a phase boundary is an advantage when the mechanical properties of the composite ceramics are concerned, especially at high temperatures. Good phase boundary strength between B₄C and SiC plays an important role in the crack growth and mechanical properties of B4C-SiC ceramics, which will be discussed in Section 4.1.1.

3.5.2. Microstructure characteristics of B_4C -SiC ceramics prepared by reaction-bonded sintering. The preparation method of reaction-bonded sintering is different from other preparation methods to obtain B_4C -SiC ceramics; thus, the microstructure of reaction-bonded B_4C -SiC ceramics has its own characteristics.

3.5.2.1. Core-rim structure. When liquid and solid phases participate in the microstructure evolution, the core-rim structure is a common phenomenon in composites produced by powder metallurgy. Hayun *et al.*¹³⁷ observed the core-rim structure characteristic of the B₄C particles in the reaction-bonded B₄C-SiC ceramics for the first time. After the infiltration process of a green B₄C compact with molten Si, the resulting B₄C-SiC ceramics are composed of B₄C, B₁₂(B, C, Si)₃, β-SiC, and some residual Si. It is interesting to note that the microstructure of B₄C-SiC ceramics exhibit a core-rim structure of the B₄C particles, with B₄C cores being surrounded by a 3-7 µm thick B₁₂(B, C, Si)₃ envelope (Fig. 9a). Furthermore, the bonding between B₄C and B₁₂(B, C, Si)₃ is strong; no crack deflection occurs along the boundary between B₄C and B₁₂(B, C, Si)₃ (Fig. 9b).¹³⁸

For the formation of the $B_{12}(B, C, Si)_3$ rim, different mechanisms are proposed. Hayun *et al.*¹³⁷ insisted that the original B_4C particles dissolve partially in molten Si during the infiltration process, and then the newly formed ternary $B_{12}(B, C, Si)_3$ carbide phase, which is treated as a solid solution of Si in B_4C , precipitates

$ \begin{array}{c} 123 \mbox{stress} 820^{(6)} {\rm Ke} (G {\rm S} {\rm mi}) \ \ 3 \mbox{stress} 840^{(1)} {\rm Ke} (S {\rm mi}) \ \ 2 \mbox{stres} 840^{(1)} {\rm Ke} (S {\rm mi}) \ \ 2 \mbox{stres} 840^{(1)} {\rm K$	$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	Ceramics	Raw material	Sintering method	Sintering temperature (°C)	Sintering aid	Relative density (%)	Phase composition	Average grain size (µm)
web, SiG ¹⁰ , B,C,G,E, min, Sjock, Jahama, (75 Mra) Total Sign (75 min) Synek, SiG, SiG, MQ, AJS(O, AlSO) Sone, SiG, SiG, MQ, AJS(O, AlSO) web, SiG ¹¹ , B,C, SiC Spick, Jahama (10 Mra) Total SiG, SiG, MQ, AJS(O, AlSO) Sone, SiG, SiG, MQ, AJS(O, AlSO) with SiG ¹¹ , B,C, SiC Spick, Jahama (10 Mra) Total SiG, SiG, MQ, AJS(O, SiG, SiG, MQ, AJSO) Sone, SiG, SiG, MQ, AJSO) with SiG ¹¹ , B,C, SiC Spick, Jahama (10 Mra) Total SiG, SiG, MQ, AJSO) Sone, SiG, SiG, SiG, MQ, AJSO) with SiG ¹¹ , B,C, SiG Spick, Jahama (10 Mra) Total SiG, SiG, MQ, AJSO) Sone, SiG, SiG, SiG, MQ, AJSO) with SiG ¹¹ , B,C, SiG Spick, Jahama (10 Mra) Total SiG, SiG, MQ, AJSO) Sone, SiG, SiG, SiG, MQ, AJSO) with SiG ¹¹ , B,C, SiG Spick, Jahama (10 Mra) Total SiG, SiG, MQ, AJSO) Sone, SiG, SiG, SiG, SiG, SiG, SiG, SiG, SiG	weights Startik Jame	¹ ₄ C-15 wt% SiC ¹²⁶		Spark plasma (75 MPa)	$1700 (\times 3 \text{ min})$	No	99.4	B_4C , SiC	B ₄ C: 0.53, SiC: 0.05–0.25
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	weige SIC ¹¹ R.G. SIC Spark plasme (a) MPA 1300 ($\times 100$ min) 300 ($\times 100$ min) 3	4C-15 wt% SiC ¹²⁶		Spark plasma (75 MPa)		2 wt% graphite	100.0	B4C, SiC	B_4C : 0.61, SiC: 0.09–0.30
Ower Start Start Distant (a) (a) (b) (b) (b) (b) (b) (b) (b) (b) (b) (b	Owley SIC ¹¹ E.G. SKC Spark plasma (0 MPa) TS0 (5 3 min) Some A ₁ A ₂ A Sould S	C-10 wt% SiC ¹²⁷		Spark plasma (40 MPa)		$3 \text{ wt\% Al}_{2} \tilde{O}_{3}$	99.5	B_4C , SiC, Al ₂ O ₃ , Al ₂ SiO ₅	$B_{4}C = 2.0-4.0$, SiC = 1.0-2.0
Odds Stev B,G, SeK Syntk plasma (0.MPz) T570 (55 min) No B,G,S,S,C,N,M,M,S,G,N,M,M,M,S,C,N,M,M,S,C,N,M,M,S,G,N,M,M,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,G,S,C,N,M,M,S,C,N,M,M,S,C,N,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,S,C,N,M,M,M,M,M,M,M,M,M,M,M,M,M,M,M,M,M,M	oulls SIC ⁶ B, C, SSC Spark plasma (a MPa) 1750 (S5 min) No 94.0 volds SIC ⁶ B, C, SSC Spark plasma (a MPa) 1750 (S5 min) No 94.0 volds SIC ⁶ B, C, SSC Spark plasma (a MPa) 1750 (S5 min) No 94.3 volds SIC ⁶ B, C, SSC Spark plasma (a MPa) 1750 (S5 min) No 94.3 volds SIC ⁶ B, C, SSC Spark plasma (a MPa) 1750 (S5 min) No 94.3 volds SIC ⁶ B, C, SSC Spark plasma (a MPa) 1750 (S5 min) No 94.3 volds SIC ⁶ B, C, SSC Spark plasma (a MPa) 1750 (S5 min) No 94.3 volds SIC ⁶ B, C, SSC Pressureless 2000 No 94.3 94.3 volds SIC ⁶ B, C, SSC Pressureless 2000 No 94.3 94.3 volds SIC ⁶ B, C, SSC B, C, SSC Pressureless 2000 No 94.3 volds SIC ⁶ B, C, SSC B, C, SSC Pressureless 2000	C-10 wt% SiC ¹²⁷		Spark plasma (40 MPa)		$6 \text{ wt\% Al}_{2}\text{O}_{3}$	99.1	B ₄ C, SiC, Al ₂ O ₃ , Al ₂ SiO ₅	$B_{4}C = 2.0-4.0$, SiC = 1.0-2.0
	oulls Stark Spark plasma (a MPa) 1750 ($\times 5$ min) 5 webs Y_20, 98.3 webs Stark plasma (a MPa) 1750 ($\times 5$ min) 5 webs Y_20, 98.0 webs Stark plasma (a MPa) 1750 ($\times 5$ min) 5 webs 9.2 9.2 webs Stark plasma (a MPa) 1750 ($\times 5$ min) 5 webs 9.2 9.2 webs Stark plasma (a MPa) 1750 ($\times 5$ min) 5 webs 9.2 9.2 webs Stark plasma (a MPa) 1750 ($\times 5$ min) 5 webs 9.2 9.2 webs Stark Stark plasma (a MPa) 1750 ($\times 5$ min) 5 webs 9.2 webs Stark Stark Stark 9.2 9.2	C-5 vol% SiC ⁹⁶		Spark plasma (40 MPa)		No	98.0	B_4C , SiC	
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	vollsk S(C^{10}_{0} B, C, z-SiC Spark plasma (40 MPa) 1750 (×5 min) No 92.0 vollsk S(C^{10}_{0} B, C, z-SiC Spark plasma (40 MPa) 1750 (×5 min) No 92.2 vollsk S(C^{10}_{0} B, C, z-SiC Spark plasma (40 MPa) 1750 (×5 min) No 92.2 vollsk S(C^{10}_{0} B, C, z-SiC Spark plasma (40 MPa) 1770 (×5 min) No 92.2 vollsk S(C^{10}_{0} B, C, p-SiC Pressureless 2000 No 97.8 92.3 vollsk S(C^{10}_{0} B, C, p-SiC Pressureless 2000 No 91.3 91.3 vollsk S(C^{10}_{0} B, C, p-SiC Pressureless 2000 No 91.3 91.3 vollsk S(C^{10}_{0} B, C, p-SiC Pressureless 2000 No 91.4 91.3 vollsk S(C^{10}_{0} B, C, p-SiC Pressureless 2000 No 91.4 91.3 vollsk B, C^{10}_{0} B, C, p-SiC Pressureless 2000 No 91.3 91.3 vollsk B, C^{10}_{0} B, C, p-SiC Pressureless 2000 No 91.4 91.3	C-5 vol% SiC ⁹⁶		Spark plasma (40 MPa)		$5 \text{ wt\% } Y_2O_3$	98.3	BAC, SiC, YBA, YB,C,	[
	Queros Spark Distanta (100 MF) (1750 (55 min) South Yeb	C-10 vol% SiC ⁹⁶		Spark plasma (40 MPa)		No	98.0	B _a C, SiC	
	webs Stort B,C, 5-SiC Spark plasma (40 MPa) 1750 (55 min) No 97.3 webs Stort B,C, 5-SiC Spark plasma (40 MPa) 1750 (55 min) No 97.3 webs Stort B,C, 5-SiC Spark plasma (40 MPa) 1750 (55 min) No 97.3 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, Y, y_0, 5 = 5; 3, 2) 91.3 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, Y, y_0, 5 = 5; 3, 2) 91.3 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, Y, y_0, 5 = 5; 3, 2) 91.3 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, Y, y_0, 5 = 5; 3, 2) 95.3 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, Y, Y_0, 5 = 5; 3, 2) 97.4 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, Y, Y_0, 5 = 5; 3, 2) 97.5 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, 0, Y, Y_0, 5 = 5; 3, 2) 97.5 webs Stort B,C, 5-SiC Pressureless 2000 10 vol9s (All, 0, Y, Y_0, 5 = 7; 3, 2) 97	C-10 vol% SiC ⁹⁶		Spark plasma (40 MPa)		$5 \text{ wt\% } Y_{2}O_{2}$	98.8	B,C, SiC, YB, YB,C, YBO,	
wides Ref. Start Start <th< td=""><td>works Steff B.C. $5:51C$ Spark plasma (10 MPa) 1750 (X3 min) Swefs Y_2O_3 99.2 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 91.3 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 93.4 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 93.4 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 74.0 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 73.5 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 73.5 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 73.5 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 : Y_O_3 = 5:3, 2) 73.0 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 : Y_O_3 = 5:3, 2) 74.0 werks Steff<td>C-15 vol% SiC⁹⁶</td><td></td><td>Spark plasma (40 MPa)</td><td>$1750 (\times 5 min)$</td><td>NO</td><td>97.8</td><td>B.C. SiC</td><td> </td></td></th<>	works Steff B.C. $5:51C$ Spark plasma (10 MPa) 1750 (X3 min) Swefs Y_2O_3 99.2 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 91.3 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 93.4 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 93.4 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 74.0 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 73.5 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 73.5 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 = 5:3, 2) 73.5 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 : Y_O_3 = 5:3, 2) 73.0 werks Steff B.C. $5:51C$ Pressureless 2000 10 works (Al_{Y}O_3 : Y_O_3 = 5:3, 2) 74.0 werks Steff <td>C-15 vol% SiC⁹⁶</td> <td></td> <td>Spark plasma (40 MPa)</td> <td>$1750 (\times 5 min)$</td> <td>NO</td> <td>97.8</td> <td>B.C. SiC</td> <td> </td>	C-15 vol% SiC ⁹⁶		Spark plasma (40 MPa)	$1750 (\times 5 min)$	NO	97.8	B.C. SiC	
	webs Sic ⁶⁶ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 5:3, 91.5 webs SiC ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 5:3, 91.5 webs SiC ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 5:3, 91.5 webs SiC ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 5:3, 91.5 webs SiC ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 5:3, 91.5 webs SiC ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 5:3, 75.5 webs SiC ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 3:2, 75.0 webs SiC ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 3:2, 75.0 webs Bic ⁶⁸ B.C. Beit Pressureless 2000 10 volbs (ALO ₃ , YO ₃ = 3:2, 75.0 webs Bic ⁶⁸ B.C. Beit Pressureless 1000 10 volbs (ALO ₃ , YO ₃ = 3:2, 75.0 webs Bic ⁶⁸ B.C. Beit Pressureless 1000 10 volbs (ALO ₃ , YO ₃ = 3:2, 75.0 webs Bic ⁶⁸ B.C. Beit Pressureless 1000 10 volbs (ALO ₃ , YO ₃ = 3:2, 7	C-15 vol% SiC ⁹⁶		レマ	1750 (×5 min)	5 wr% V.O.	98.2	B.C. SIC VR. VR.C.	
with Stell B,C, ISSC Frestureless 200 involves (A), (A), (Y, Q), = 5:1, A 31.3	were Sizes Edge Pressureties 2000 10 volts (Al,O_1, Y,O_1 = 5: 3, 2, 3; 3, 2, 3; 3, 3, 3, 3, 3, 3, 3, 3, 3, 3, 3, 3, 3,			Ľ			10.00		
with SIG ¹⁰ B.C. (SAC Pressureless 200 molar relation 21.2 23.4 - - - with SIG ¹⁰ B.C. (SAC Pressureless 200 molar relation 31.3 31.4 -	weye SiC ⁴⁸ B ₄ C, F-SiC Pressureless 2000 moler ratio, notar ratio, weye SiC ⁴⁸ B ₄ C, F-SiC Pressureless 2000 moler ratio, notar ratio, revelosities 2010 2010 2014 2014 weye SiC ⁴⁸ B ₄ C, F-SiC Pressureless 2000 10 volles (AI), Y ₂ O ₃ = 5:3, Pressureless 2000 10 volles (AI), Y ₂ O ₃ = 5:3, Pressureless 2015 weye SiC ⁴⁸ B ₄ C, F-SiC Pressureless 2000 10 volles (AI), O ₃ ; Y ₂ O ₃ = 5:3, Pressureless 2000 10 volles (AI), O ₃ ; Y ₂ O ₃ = 5:3, Pressureless 2020 weye SiC ⁴⁸ B ₄ C, F-SiC Pressureless 2000 10 volles (AI), O ₃ ; Y ₂ O ₃ = 5:3, Pressureless 2020 weye SiC ⁴⁸ B ₄ C, F-SiC Pressureless 2000 10 volles (AI), O ₃ ; Y ₂ O ₃ = 5:3, Pressureless 2020 weye B ₄ C ¹⁴ 2-SiC (1.0 µm), B ₄ C (0.5 µm) Pressureless 2000 10 volles (AI), O ₃ ; Y ₂ O ₃ = 5:3, Pressureless 2100 weye B ₄ C ¹⁴ 2-SiC (2.0 µm), B ₄ C (0.5 µm) Pressureless 1900 10 volles (AI), O ₃ ; Fr ₂ O ₃ ; Er ₂ O ₃ 211, 0.5, Pressureless 211, 0.5, Pressureless 2120 wey	C-10 wt% SiC ⁸⁸	B.C. B-SiC	Pressureless	2.000	$M_{\rm Al_{s}O_{s}} $ (Al_sO_s : Y_sO_s	01.5 91.5	D4C, & 3IC, (p-3IC) —	
	webs Br Br Cols Pressureless 2000 10 volgs (ÅN: Y_2O_3 = 3: 2, 3; 75.5) 93.4 webs BrC, Br Br, G, BrSC Br, G, BrSC Br, G, BrSC Pressureless 2000 No No 74.0 74.0 webs StC ⁸⁸ Br, G, FSiC Pressureless 2000 No No 74.0, 9.5 75.5 webs StC ⁸⁸ Br, G, FSiC Pressureless 2000 No No 74.0, 9.5 75.5 webs StC ⁸⁸ Br, G, FSiC Pressureless 2000 No No No No 74.0 95.8 webs Br, G, FSiC Pressureless 2000 No No No No 97.5 97.5 97.5 webs Br, G, SiC StC (1.0 µm), Br, G (0.5 µm) Pressureless 2000 No No 97.8 97.5 97.5 97.8 97.5 97.6 97.5 97.8 97.6 97.5 97.6 97.6 97.6 <td< td=""><td></td><td></td><td></td><td></td><td>molar ratio</td><td></td><td></td><td></td></td<>					molar ratio			
	weys Ste ⁸⁸ B ₄ C, β_5 Sic Pressureless 2000 No molar ratio 74.0 weys Ste ⁸⁸ B ₄ C, β_5 Sic Pressureless 2000 10 vol96 (Al, O ₃ , Y, O ₃ = 3: 2, R, S,	0-10 wt% SiC ⁸⁸	B,C. B-SiC	Pressureless	2000	$10 \text{ vol}\% \text{ (A]N: } Y, O_2 = 3:2.$	93.4		
week SiC ^{all} B,C, F,SiC Pressureless 200 No	web Sic ⁴⁸ B ₄ C, B ₅ C Pressureless 2000 No No 74.0 web Sic ⁴⁸ B ₄ C, B ₅ C Pressureless 2000 10 vol% (Al ₂ O ₃ ; Y ₂ O ₃ = 5: 3, 78.5 74.0 web Sic ⁴⁸ B ₄ C, B ₅ C Pressureless 2000 10 vol% (Al ₂ O ₃ ; Y ₂ O ₃ = 5: 3, 78.5 74.0 web Sic ⁴⁸ B ₄ C, B ₅ C Pressureless 2000 10 vol% (Al ₁ O ₃ ; Y ₂ O ₃ = 5: 3, 78.5 75.0 web Sic ⁴⁸ B ₄ C, B ₅ C Pressureless 2000 10 vol% (Al ₁ O ₃ ; Y ₂ O ₃ = 3: 2, 75.0 67.5 web B ₄ C ¹⁴⁰ ~ scSiC (1.0 µm), B ₄ C (0.5 µm) Pressureless 2000 10 vol% (Al ₁ O ₃ ; L ₂ O ₃ = 1: 1, 96.8 97.4 web B ₄ C ¹⁴¹ ~ scSiC (2.0 µm), B ₄ C (0.5 µm) Pressureless 1900 10 vol% (Al ₁ O ₃ ; L ₂ O ₃ = 1: 1, 96.8 91.7 web B ₁ C ¹⁴¹ ~ scSiC (2.0 µm), B ₄ C (0.5 µm) Gas-pressure (0.08 MPa) 1900 8 web (Al ₁ O ₃ ; L ₂ O ₃ = 1: 1, 96.8 91.7 web B ₁ C ⁷⁴¹ ~ scSiC (2.0 µm), B ₄ C (0.5 µm) Gas-pressure (0.08 MPa) 1900 8 web (Al ₁ O ₃ ; L ₂ O ₃ = 1: 1, 10.5 91.2 91.2 web B ₁ C					molar ratio)			
web, SiCa R_{1C}^{10} First pistor Tensurelise 2000 In object ratio) Tensurelise 2000 In object ratio) Tensurelise 2000<	web SiG ⁸⁸ B ₁ C, B ₂ C, B_2C, B_2C	-30 wt% SiC ⁸⁸	B.C. B-SiC	Pressureless	2,000	NO	74.0	B.C. v-SiC (B-SiC)	
with SIC ¹⁰ B, C, B, SIC Pressureless 200 molar ratio) 57.3 B, C, arSIC, (PSIC) $$ $$ with SIC ¹⁰ B, C, B, SIC Pressureless 2000 00 volts/(Al)(Y; Y_0) = 3:1, 57.3 B, C, arSIC, (PSIC) $$ $-$	were sizes Each product fraction Each product fraction <theach fraction<="" product="" th=""> Each product fraction Each product fractin Each product fractin Each pro</theach>	-30 wt% SiC ⁸⁸	B.C. B-SiC	Dressureless	2000	vol% (Al _o O _o · Y _o O _o =	78.5		
	web B,C, FSIC Pressureless 2000 TO voles (AI) $Y_2O_3 = 3:2$, $8.7.5$ web SiC ⁴⁸ B,C, FSiC Pressureless 2000 TO voles (AI) $Y_2O_3 = 3:2$, $8.7.5$ web SiC ⁴⁸ B,C, FSiC Pressureless 2000 TO voles $(AI)_2O_3$ $Y_2O_3 = 3:2$, 67.5 web B,C, FSiC Pressureless 2000 TO voles $(AI)_2O_3$ $Y_2O_3 = 3:2$, 67.5 web B,C, FSiC Descreteless 2000 TO voles $(AI)_2O_3$ F_2 F_2 web B,C Inder ratio Pressureless 1900 No P_1 P_1 P_2 web B,C ⁴ $2 \cdot SiC$ Lo Imb B_4C B_1 P_1 P_1 P_2 P_1 P_1 P_2 web B_1 $2 \cdot SiC$ LO Imb B_1 P_1 P_1 P_1 <td< td=""><td></td><td></td><td></td><td></td><td>· · · · · · · · · · · · · · · · · · ·</td><td></td><td></td><td></td></td<>					· · · · · · · · · · · · · · · · · · ·			
with Sic Bit Cit Sic S	werebe werebe siteEach backPressureles2000 probleNo67.5 bc.werebe werebeB4C, β -SitePressureless2000NoNo67.5 bc.67.5werebe werebeB4C, β -SitePressureless2000NoNo67.5 bc.67.5werebe werebeB4C, β -SitePressureless2000NoNo67.5 bc.67.5werebe werebeB4C, β -SitePressureless2000NoNo67.5 bc.67.5werebe werebeB4C, β -SitePressureless2000NoNo67.5 bc.67.5werebe werebeB4C, β -SiteC0.5 \mumPressure (0.08 MPa)1900894.294.2werebe werebeB4C ¹¹ 2 -Site2.0 µmB4.09.1 T94.2werebe werebeB4C ¹¹ 2 -Site2.0 µmB4.09.1 T94.2werebe werebeB4.0B4.0B4.09.1 T94.2werebe werebeB4.0B4.0B4.09.1 T94.2werebe werebeB4.0B4.0B4.09.1 T94.2werebe werebeB4.0B4.0B4.09.1 T94.2werebe werebeB4.0B4.0B4.09.1 T94.2werebe werebeB4.0B4.0B4.09.1 T94.2werebe werebeB4.0B4.0B4.09.1 T94.2werebe werebeB4.0B4.0<	0-30 wt% SiC ⁸⁸	B,C. B-SiC	Pressureless	2000	$10 \text{ vol}\% \text{ (AIN: } Y, O_2 = 3:2.$	87.5		
	wer% SIC ⁸⁸ B ₄ C, β -SiC Pressureless 2000 No 67.5 wer% SIC ⁸⁸ B ₄ C, β -SiC Pressureless 2000 10 vol% (Al ₂ O ₃ : Y ₂ O ₃ = 5:3, bold molar ratio) 69.8 wer% SIC ⁸⁸ B ₄ C, β -SiC Pressureless 2000 10 vol% (Al ₂ O ₃ : LA ₂ O ₃ = 1:1, bold molar ratio) 67.5 wer% B ₄ C ⁷¹ α -SiC (1.0 µm), B ₄ C (0.5 µm) Pressureless 1900 10 vol% (Al ₂ O ₃ : LA ₂ O ₃ = 1:1, bold molar ratio) 94.2 wer% B ₄ C ⁷⁴ α -SiC (2.0 µm), B ₄ C (0.5 µm) B ₄ C (Al ₂ O ₃ : El ₂ O ₃) 94.2 94.2 wer% B ₄ C ⁷⁴ α -SiC (2.0 µm), B ₄ C (0.5 µm) Gas-pressure (0.08 MPa) 1900 SiO ₂ = 1:1:0.5, molar ratio) 91.7 wer% B ₄ C ⁷⁴ α -SiC (2.0 µm), B ₄ C (0.5 µm) Gas-pressure (0.08 MPa) 1900 SiO ₂ = 1:1:0.5, molar ratio) 91.7 wer% SiC ¹²³ B ₄ C (Al ₂ O ₃ : El ₂ O ₃) B ₄ C (Al ₂ O ₃ : El ₂ O ₃) 91.7 94.6 wer% SiC ¹²³ B ₄ C (0.5 µm) Bas-pressure (0.08 MPa) 1900 SiO ₂ = 1:1:0.5, molar ratio) 91.7 wer% SiC ¹²³ B ₄ C (0.8 µm), SiC (0.5 µm) Pressurele					molar ratio)			
	wefw SiCs ⁸⁸ B_4C, \beta-SiCPressureless20010 vol% (Al_3O_3: Y_2O_3 = 5:3, 69.8wefw SiCs ⁸⁸ B_4C, \beta-SiCPressureless200010 vol% (Al_3O_3: La_2O_3 = 3: 2, 75.0wefw B_4C ¹⁰⁹ ∞ -SiC (1.0 µm), B_4C (0.5 µm)Pressureless190010 wefw (Al_3O_3: La_2O_3 = 1:1, 96.8wefw B_4C ⁷⁴ ∞ -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)19008 wefw (Al_3O_3: La_2O_3 = 1:1, 96.8wefw B_4C ⁷⁴ ∞ -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)19008 wefw (Al_3O_3: La_2O_3 = 1:1, 96.8wefw B_4C ⁷⁴ ∞ -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)19008 wefw (Al_3O_3: La_2O_3 = 1:1, 96.8wefw B_4C ⁷⁴ ∞ -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)19008 wefw (Al_2O_3: Er_2O_3 = 1:1, 9.5, molar ratio)wefw B_4C ⁷⁴ ∞ -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)19008 wefw (Al_2O_3: Er_2O_3 = 1:1, 9.5, molar ratio)wefw B_4C ⁷⁴ ∞ -SiC (2.0 µm), B_4C (0.5 µm)Pressureless21508 wefw (Al_2O_3: Er_2O_3 = 1:1, 9.5, molar ratio)wefw SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wefw (Al_2O_3: Er_2O_3 = 1:1, 9.5, molar ratio)wefw SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wefw (Al_2O_3: Er_2O_3 = 1:1, 9.5, molar ratio)wefw SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wefw (CO_2wefw SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wefw (CO_2wefw SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pr	0-50 wt% SiC ⁸⁸	B,C, B-SiC	Pressureless	2000	No	67.5	$B_{A}C, \alpha$ -SiC, (β -SiC)	
	wtw BirCi ⁸⁸ BirCi β_{12} Pressureless 2000 molar ratio 75.0 wtw BirCi β_{12} γ_{23}	C-50 wt% SiC ⁸⁸	B,C, B-SiC	Pressureless	2000	10 vol% (Al ₂ O ₃ : Y ₂ O ₃ = 5 : 3,	69.8	B,C, œ-SiC	
	wt% SiC ⁴⁸ B,C, β-SiC Pressureless 2000 10 vol% (AlN: Y_2O_3 = 3:2, and arratio) 75.0 wt% B_4C ^{10°} \$\$-SiC (1.0 µm), B_4C (0.5 µm) Pressureless 1900 10 wt% (Al_2O_3: I.B_2O_3 = 1:1, box) 96.8 wt% B_4C ⁷⁴ \$\$-SiC (2.0 µm), B_4C (0.5 µm) Ressureless 1900 10 wt% (Al_2O_3: I.B_2O_3 = 1:1, box) 94.2 wt% B_4C ⁷⁴ \$\$-SiC (2.0 µm), B_4C (0.5 µm) Gas-pressure (0.08 MPa) 1900 8 wt% (Al_2O_3: I.B_2O_3 = 1:1, box) 91.3 wt% B_4C ⁷⁴ \$\$-SiC (2.0 µm), B_4C (0.5 µm) Gas-pressure (0.08 MPa) 1900 8 wt% (Al_2O_3: I.B_2O_3) 91.1 wt% SiC ¹²⁹ SiC (2.0 µm), B_4C (0.5 µm) Gas-pressure (0.08 MPa) 1900 8 wt% (Al_2O_3: I.B_2O_3) 91.7 wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Bas-pressure (0.08 MPa) 1900 SiO_2 = 1:1:0.5, molar ratio) 91.7 wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 NW 91.0 wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 NW 91.2 92.6 wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µ					molar ratio)			
	wt% $B_4 C^{100}$ α -SiC (1.0 µm), $B_4 C$ (0.5 µm)Pressureless1900nodar ratio)nodar ratio)wt% $B_4 C^{74}$ α -SiC (2.0 µm), $B_4 C$ (0.5 µm) $B_4 C$ (0.6 µm) $B_4 C$ (0.8 µm) $B_4 C$	C-50 wt% SiC ⁸⁸	B_4C , β -SiC	Pressureless	2000	10 vol% (AIN: $Y_2O_3 = 3:2$,	75.0	B_4C , α -SiC	
	wt% B_4C^{103} $z \cdot SiC (10 \ \mum), B_4C (0.5 \ \mum), B_4C (0.6 \ \mum), B_4C (0.5 \ \mum), SiC (0.5 \$					molar ratio)			
		-10 wt% B ₄ C ¹⁰⁹		Pressureless	1900	10 wt% $(Al_2O_3:La_2O_3 = 1:1)$	96.8	SiC, B ₄ C, LaAlO ₃	
	wt% B_4C^{-4} x -SiC (2.0 µm), B_4C (0.5 µm) (Gas-pressure (0.08 MPa) 1900 8 wt% (Al_2O_3: Er_2O_3: Molar ratio) 94.2 SiC, B_4C wt% B_4C^{-4} x -SiC (2.0 µm), B_4C (0.5 µm) (Gas-pressure (0.08 MPa) 1900 8 wt% (Al_2O_3: Er_2O_3: Molar ratio) 93.4 SiC, B_4C wt% B_4C^{-4} x -SiC (2.0 µm), B_4C (0.5 µm) (Gas-pressure (0.08 MPa) 1900 8 wt% (Al_2O_3: Er_2O_3: Molar ratio) 91.7 SiC, B_4C wt% B_4C^{-4} x -SiC (2.0 µm), B_4C (0.5 µm) Gas-pressure (0.08 MPa) 1900 8 wt% (Al_2O_3: Er_2O_3: Molar ratio) 91.7 SiC, B_4C wt% B_4C^{-4} x -SiC (2.0 µm), B_4C (0.5 µm) Pressureless 2150 8 wt% (Al_2O_3: Er_2O_3: Molar ratio) 91.7 SiC, B_4C <td>1</td> <td>,</td> <td></td> <td></td> <td>molar ratio)</td> <td></td> <td></td> <td></td>	1	,			molar ratio)			
	wt% B_4C^{74} a -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)1900 $B_{102}^{2} = 1:1:0.5$, molar ratio)93.4SiC, B_4C wt% B_4C^{74} a -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)1900 8 wt% (Al_2O_3: Er_2O_3:91.7SiC, B_4C wt% B_4C^{74} a -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)1900 8 wt% (Al_2O_3: Er_2O_3:91.7SiC, B_4C wt% B_4C^{74} a -SiC (2.0 µm), B_4C (0.5 µm)Barc (0.6 µm), SiC (0.5 µm)Pressureless21508 wt% (Al_2O_3: Er_2O_3:88.9SiC, B_4C wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless2150No8 wt% (Al_2O_3: Er_2O_3:84.6SiC, B_4C wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless2150No91.2 B_4C SiC, B_4C wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_291.4 B_4C , SiC, $Wt%$ wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_292.6 B_4C , SiC, $Wt\%$ wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_292.6 B_4C , SiC, $Wt\%$ wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_292.6 B_4C , SiC, $Wt\%$ wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_292.6 B_4C , SiCwt% SiC ¹²⁹ B_4C (3.5 µm)Pressureless21509 wt% CeO_29	-5 wt% B4C ^{/4}	α-SiC (2.0 μm), B₄C (0.5 μm)	Gas-pressure (0.08 MPa)	1900	8 wt% (Al ₂ O ₃ : Er_{2O_3} :	94.2	SiC, B ₄ C	1
	wtw B_4C^{-1} $x = SiC (2.0 \ \mum), B_4C (0.5 \ \mum)$ Gas-pressure (0.08 MPa)19008 wtw $(A_12, 0_3; Er_2, 0_3; Er_3, 0_3; Er_$	10 101 074				$SIO_2 = 1:1:0.5$, molar ratio)			
wt% $B_4 C^{74}$ $z \cdot SiC (2.0 \ \mum), B_4 C (0.5 \ \mum)$ Gas pressure (0.08 MPa)1900 $B wt% (A_1^2, O_3; Er_2 O_3; Er_2 O_3;$ 91.7SiC, $B_4 C$ $-$ wt% $B_4 C^{74}$ $z \cdot SiC (2.0 \ \mum), B_4 C (0.5 \ \mum)$ Gas pressure (0.08 MPa)1900 $B wt% (A_1^2, O_3; Er_2 O_3;$ 91.7SiC, $B_4 C$ $ -$ wt% SiC ¹²⁹ $B_4 C (0.5 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150No $B wt% (A_1^2, O_3; Er_2 O_3;$ 88.9SiC, $B_4 C$ $ -$ wt% SiC ¹²⁹ $B_4 C (0.8 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150No $ -$ wt% SiC ¹²⁹ $B_4 C (0.8 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150 $ -$ wt% SiC ¹²⁹ $B_4 C (0.8 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150 $ -$ wt% SiC ¹²⁹ $B_4 C (0.8 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150 $ -$ wt% SiC ¹²⁹ $B_4 C (0.8 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150 $ -$ wt% SiC ¹²⁹ $B_4 C (0.8 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150 $ -$ wt% SiC ¹²⁹ $B_4 C (0.8 \ \mum), SiC (0.5 \ \mum)$ Pressureless2150 $ -$ <td>wt% $B_4C^{74}$$x$-SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)1900$B_{4}C^{74}$$B_{4}C^{74}$$z$-SiC (2.0 µm), B_4C (0.5 µm)$Gas-pressure (0.08 MPa)$1900$B_{4}Wt%$ (Al_2O_3: Er_2O_3:$B.9$$SiC, B_4C$wt% $B_4C^{74}$$x$-SiC (2.0 µm), B_3C (0.5 µm)$Gas-pressure (0.08 MPa)$1900$B_{4}Wt%$ (Al_2O_3: Er_2O_3:$B.9$$SiC, B_4C$wt% SiCl²¹⁹$B_4C$ (0.8 µm), SiC (0.5 µm)$Pressureless$$2150$$N_0$$Wt%$ (Al_2O_3: Er_2O_3:B_4C, SiCwt% SiCl²¹⁹B_4C (0.8 µm), SiC (0.5 µm)$Pressureless$$2150$$N_0$$Wt%$ ($CO_2$$91.2$$B_4C$, SiCwt% SiCl²¹⁹$B_4C$ (0.8 µm), SiC (0.5 µm)$Pressureless$$2150$$3$ wt% CO_2$92.4$$B_4C$, SiCwt% SiCl²¹⁹$B_4C$ (0.8 µm), SiC (0.5 µm)$Pressureless$$2150$$3$ wt% CO_2$94.6$$B_4C$, SiCwt% SiCl²¹⁹$B_4C$ (0.8 µm), SiC (0.5 µm)$Pressureless$$2150$$9$ wt% CO_2$94.6$$B_4C$, SiCwt% SiCl²¹⁹$B_4C$ (0.8 µm), SiC (0.5 µm)$Pressureless$$2150$$9$ wt% CO_2$94.6$$B_4C$, SiCwt% SiCl²¹⁹$B_4C$ (0.8 µm), SiC (0.5 µm)$Pressureless$$2150$$9$ wt% CO_2$94.6$$B_4C$, SiCwt% SiCl²¹⁹$B_4C$ (0.8 µm), SiC (0.8 µm)$Pressureless$$2150$$9$ wt% SiC_9$9$ wt% SiC$91.7$$B_4C$wt% SiCl²¹⁹$B_4C$ (0.8 µm)$SiC (0.8 µm)$$Pressureless$$1950$$9$ wt% SiC$91.7$$B_4C$<td>$-10 \text{ wt\% } B_4 C^{\prime 4}$</td><td>α-SiC (2.0 μm), B₄C (0.5 μm)</td><td>Gas-pressure (0.08 MPa)</td><td>1900</td><td>$8 \text{ wt\% (Al}_{2}O_3: \text{Er}_{2}O_3:$ siO = 1 : 1 : 0 : molor metic)</td><td>93.4</td><td>SIC, B₄C</td><td>I</td></td>	wt% B_4C^{74} x -SiC (2.0 µm), B_4C (0.5 µm)Gas-pressure (0.08 MPa)1900 $B_{4}C^{74}$ $B_{4}C^{74}$ z -SiC (2.0 µm), B_4C (0.5 µm) $Gas-pressure (0.08 MPa)$ 1900 $B_{4}Wt%$ (Al_2O_3 : Er_2O_3 : $B.9$ SiC, B_4C wt% B_4C^{74} x -SiC (2.0 µm), B_3C (0.5 µm) $Gas-pressure (0.08 MPa)$ 1900 $B_{4}Wt%$ (Al_2O_3 : Er_2O_3 : $B.9$ SiC, B_4C wt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.5 µm) $Pressureless$ 2150 N_0 $Wt%$ (Al_2O_3 : Er_2O_3 : B_4C , SiCwt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.5 µm) $Pressureless$ 2150 N_0 $Wt%$ (CO_2 91.2 B_4C , SiCwt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.5 µm) $Pressureless$ 2150 3 wt% CO_2 92.4 B_4C , SiCwt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.5 µm) $Pressureless$ 2150 3 wt% CO_2 94.6 B_4C , SiCwt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.5 µm) $Pressureless$ 2150 9 wt% CO_2 94.6 B_4C , SiCwt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.5 µm) $Pressureless$ 2150 9 wt% CO_2 94.6 B_4C , SiCwt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.5 µm) $Pressureless$ 2150 9 wt% CO_2 94.6 B_4C , SiCwt% SiCl ²¹⁹ B_4C (0.8 µm), SiC (0.8 µm) $Pressureless$ 2150 9 wt% SiC_9 9 wt% SiC 91.7 B_4C wt% SiCl ²¹⁹ B_4C (0.8 µm) $SiC (0.8 µm)$ $Pressureless$ 1950 9 wt% SiC 91.7 B_4C <td>$-10 \text{ wt\% } B_4 C^{\prime 4}$</td> <td>α-SiC (2.0 μm), B₄C (0.5 μm)</td> <td>Gas-pressure (0.08 MPa)</td> <td>1900</td> <td>$8 \text{ wt\% (Al}_{2}O_3: \text{Er}_{2}O_3:$ siO = 1 : 1 : 0 : molor metic)</td> <td>93.4</td> <td>SIC, B₄C</td> <td>I</td>	$-10 \text{ wt\% } B_4 C^{\prime 4}$	α-SiC (2.0 μm), B ₄ C (0.5 μm)	Gas-pressure (0.08 MPa)	1900	$8 \text{ wt\% (Al}_{2}O_3: \text{Er}_{2}O_3:$ siO = 1 : 1 : 0 : molor metic)	93.4	SIC, B ₄ C	I
wtw B_4C^{74} $\alpha \text{-SiC} (2.0 \ \mum), \text{ B}_4 C (0.5 \ \mum)$ $B_4 C (0.5 \ \mum), \text{ B}_4 C (0.5 \ \mum$	wt% B_4C^{74} x -Sic $(2.0 \ \mum)$, B_4c $(0.5 \ \mum)$ Gas-pressure $(0.08 \ MPa)$ 1900 $SiO_2 = 1:1:0.5$, molar ratio) $SiO_3 = E_7O_3$: $SiO_4 = 1:2.0.5$, molar ratio)wt% SiC^{129} B_4C $(0.8 \ \mum)$, $SiC (0.5 \ \mum)Pressureless2150SiO_2 = 1:1:0.5, molar ratio)SiO_3 = E_7O_3:SiO_3 = E_7O_3:SiO_3 = E_7O_3:wt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless2150NOSiO_2 = 1:1:0.5, molar ratio)wt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless21501 \ wt\%, CeO_291.2B_4C, SiC, SiC, Wt\%, CeO_2wt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless21501 \ wt\%, CeO_291.2B_4C, SiC, SiC, Wt\%, CeO_2wt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless21509 \ wt\%, CeO_292.4B_4C, SiC, SiC, Wt\%, SiC^{129}wt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless21509 \ wt\%, CeO_291.7B_4C, SiC, SiC, Wt\%, SiC^{129}wt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless21509 \ wt\%, CeO_291.7B_4C, SiCwt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless21509 \ wt\%, CeO_291.6B_4C, SiCwt% SiC^{129}B_4C (0.8 \ \mum), SiC (0.5 \ \mum)Pressureless21509 \ wt\%, CeO_291.6B_4C, SiCwt% SiC^{1219}B_4C (0.8 \ \mum), $	-15 w/0% B C ⁷⁴	~-SiC (2 0 11m) B (C (0 2 11m)	Gas-pressure (0.08 MDa)	1 900	$310_2 = 1.1.0.3$, III0Ia1 1au0) 8 wt% [Al-O- · Fr-O- ·	7 7		
	wt% B_4C^{74} x -SiC (2.0 µm), B_4C (0.5 µm) Gas-pressure (0.08 MPa) 1900 B wt% (Å2.0, $\Xi_{7.05}$, molar ratio) 85.8 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 NO 50.2 = 1:1:0.5, molar ratio) 85.8 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 1 wt% CeO ₂ 91.2 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 1 wt% CeO ₂ 91.2 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% CeO ₂ 94.6 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% CeO ₂ 94.6 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% CeO ₂ 94.6 B_4C , SiC wt% CeO ₂ 94.6 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% CeO ₂ 94.6 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% CeO ₂ 94.6 B_4C , SiC wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% SiC ¹²⁰ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% SiC ¹²¹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% SiC ¹²¹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% SiC ¹¹¹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% SiC ¹¹¹ B_4C (0.8 µm), SiC (0.7 µm) Pressureless 2150 7 wt% SiC ¹¹¹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2150 7 wt% SiC ¹¹¹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless (0.8 µm) SiC (0.7 µm) Pressureless (0.8 µm) SiC (0.8 µm), SiC (0.7 µm) Pressureless (0.8 µm) SiC (0.5 µm) Pressureless (0.8 µm) SiC (0.7 µm) Pressureless (0.8 µm) SiC (0.7 µm) Pressureless (0.8 µm) SiC (0.7 µm) Pressureless (0.8 µm) SiC (0.8 µm)			and breast (and and		$SiO_{2} = 1:1:0.5$ molar ratio)			
wt% SiC129B1C (0.8 µm), SiC (0.5 µm)Pressureless2150NOSiO2 = 111.0.5, molar ratioB1C, SiC, CeB, $$ wt% SiC129B1C (0.8 µm), SiC (0.5 µm)Pressureless21501 wt% CeO_291.2B4,C, SiC, CeB, $$ wt% SiC129B1C (0.8 µm), SiC (0.5 µm)Pressureless21501 wt% CeO_292.6B4,C, SiC, CeB, $$ wt% SiC129B1,C (0.8 µm), SiC (0.5 µm)Pressureless21503 wt% CeO_294.6B4,C, SiC, CeB, $$ wt% SiC129B1,C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_294.4B4,C, SiC, CeB, $$ wt% SiC129B1,C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_294.4B4,C, SiC, CeB, $$ wt% SiC129B1,C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% CeO_294.4B4,C, SiC, CeB, $$ wt% SiC129B1,C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% SiC,91.7B4,CSiC, CeB, $$ wt% SiC129B1,C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% SiC,91.7B4,CSiC, CeB, $$ wt% SiC1219B1,C (0.8 µm), SiC (0.5 µm)Pressureless21509 wt% SiC,91.7B4,CSiC, CeB, $$ wt% SiC1219B1,C (0.8 µm), SiC (0.8 µm), PCSHot-press (30 MPa)1950No91.7B4,CSiC, CeB, $$ wt% SiC118B1,C (SiC (SiC (SiC (SiC (SiC (SiC (SiC (Si	wt% SiC129 wt% SiC129 B4C (0.8 µm), SiC (0.5 µm)Fressureless resourcless2150 2150SiO2 = 1:1:0.5, molar ratio)S:8 B4C, SiC 91.2B4C, SiC 	$-20 \text{ wt}^{-0} \text{ B}, \text{C}^{74}$	w-SiC (2.0 mm), B.C (0.5 mm)	Gas-pressure (0.08 MPa)	1900	$8 \text{ wt}\% (Al_{\circ}O_{\circ} \cdot Fr_{\circ}O_{\circ} \cdot$	88.9	SIC B.C	
wt% SiC129 wt% SiC129 SiC (0.5 µm)SiC (0.8 µm), SiC (0.5 µm) PresurelessPressureless2150No85.8 91.2B4C, SiC, CEB, B4C, SiC, CEB, $$ wt% SiC129 wt% SiC129 wt% SiC129 Wt% SiC129 SiC (0.5 µm), SiC (0.5 µm)Pressureless21501 wt% CeO_291.2B4C, SiC, CEB, 92.6 $$ wt% SiC129 wt% SiC129 Wt% SiC129 Wt% SiC129 SiC (0.5 µm), SiC (0.5 µm)Pressureless21507 wt% CeO_294.6B4C, SiC, CEB, 92.6 $$ wt% SiC129 Wt% SiC129 Mt% SiC129 Mt% SiC1213 Mt% SiC1213B4C (0.8 µm), SiC (0.5 µm)Pressureless21507 wt% CeO_294.6B4C, SiC, CEB, 91.7 $$ wt% SiC129 Mt% SiC1213 Mt% SiC131 Mt% SiC131 Mt% SiC131 B4C, SiCB4C (0.8 µm), SiC (0.5 µm)Pressureless21507 wt% CeO_291.7B4C, SiC, CEB, 91.7 $$ wt% SiC131 Mt% SiC131 Mt% SiC131 Mt% SiC131 Mt% SiC131 B4C, SiCB4C, SiC92.0B4C, SiC, SiC $$ wt% SiC131 Mt% SiC131 Mt% SiC131 Mt% SiCB4C, SiC99.1B4C, SiC, SiC $$	wt% SiC123 wt% SiC123 wt% SiC123 B4C (0.8 µm), SiC (0.5 µm) wt% SiC123 B4C (0.8 µm), SiC (0.5 µm) merseureless wt% SiC123 B4C (0.8 µm), SiC (0.5 µm) merseureless wt% SiC123 B4C (0.8 µm), SiC (0.5 µm) merseureless wt% SiC123 B4C (0.8 µm), SiC (0.5 µm) merseureless muth SiC (0.8 µm), SiC (0.5 µm) merseureless muth SiC (0.8 µm), SiC (0.8 µm), SiC (0.5 µm) merseureless muth SiC (0.8 µm), SiC (0.5 µm) merseureless muth SiC (0.8 µm), SiC (0.8 µm), SiC (0.5 µm) merseureless muth SiC (0.8 µm), SiC (0.8 µm), SiC (0.5 µm) merseureless muth SiC (0.8 µm), SiC (0.8 µm), SiC (0.6 µm), SiC (0.6 µm), SiC (0.6 µm), SiC (0.6 µm), SiC (0.7 µm) muth SiC (0.8 µm), SiC (0.8 µm), SiC (0.8 µm), SiC (0.6 µm), SiC (0.6 µm), SiC (0.7 µm) muth SiC (0.8 µm), SiC (0.8 µm), SiC (0.7 µm) muth SiC (0.8 µm), PCS muth SiC (0			(n man and annound anno		$SiO_2 = 1:1:0.5$, molar ratio)			
	wt% SiC129 wt% SiC129 SiC (0.8 µm), SiC (0.5 µm) FresurelessPressureless2150 3 wt% CeO21 wt% CeO2 3 wt% CeO291.2 92.6 94.6 94.6 B_4C , SiC, 84.C, SiC, 92.691.2 84.C, SiC, 92.6 B_4C , SiC, 92.691.2 84.C, SiC, 94.6 B_4C , SiC, 92.691.2 84.C, SiC, 94.6 B_4C , SiC, 94.691.2 84.C, SiC, 94.6 B_4C , SiC, 94.691.2 84.C, SiC, 94.6 B_4C , SiC, 94.691.2 84.C, SiC, 94.6 B_4C , SiC, 94.691.2 84.C, SiC, 94.6 B_4C , SiC, 94.691.7 84.C, SiC, 94.6 B_4C , SiC, 94.691.7 84.C, SiC, 94.6 B_4C , SiC, 94.691.7 84.C, SiC, 94.6 B_4C , SiC, 94.691.7 84.C, SiC, 94.6 B_4C , SiC, 94.1 B_4C , SiC, 94.6 B_4C , SiC, 94.1 B_4C , SiC, 94.6 </td <td>C-15 wt% SiC¹²⁹</td> <td></td> <td>Pressureless</td> <td>2150</td> <td>No</td> <td>82.8</td> <td>B₄C. SiC</td> <td> </td>	C-15 wt% SiC ¹²⁹		Pressureless	2150	No	82.8	B ₄ C. SiC	
	wt% SiC129 wt% SiC129 SiC (0.8 µm), SiC (0.5 µm)Pressureless2150 $3 wt% CeO_2$ 92.6 $B_4C, SiC,$ wt% SiC129 wt% SiC129 wt% SiC129 B_4C (0.8 µm), SiC (0.5 µm)Pressureless 2150 $5 wt% CeO_2$ 94.6 $B_4C,$ SiC,wt% SiC129 wt% SiC129 B_4C (0.8 µm), SiC (0.5 µm)Pressureless 2150 $7 wt\% CeO_2$ 94.6 $B_4C,$ SiC,wt% SiC129 wt% SiC129 B_4C (0.8 µm), SiC (0.5 µm)Pressureless 2150 $7 wt\% CeO_2$ 94.6 $B_4C,$ SiC,wt% SiC129 B_4C (3.5 µm) B_4C (0.5 µm)Pressureless 2150 $9 wt\% CeO_2$ 91.7 $B_4C,$ SiC,wt% SiC131 wt% SiC131 B_4C, SiC B_4C (3.5 µm), PCSHot-press (30 MPa) 1950 No 91.7 $B_4C,$ SiC,wt% SiC131 wt% SiC131 wt% SiC131 $B_4C,$ SiCPressureless 1950 No 94.6 Si $B_4C,$ SiC,wt% SiC131 wt% SiC131 wt% SiC131 wt% SiC131 $B_4C,$ SiCPressureless 1950 No 92.0 $B_4C,$ SiC,wt% SiC131 wt% SiC131 wt% SiC131 wt% SiC131 $B_4C,$ SiCPressureless 1950 No 92.0 $B_4C,$ SiC,wt% SiC131 wt% SiC131 wt% SiC131 $B_4C,$ SiCPressureless 1950 No 92.0 $B_4C,$ SiC,wt% SiC131 wt% SiC131 $B_4C,$ SiCPressureless 1950 $10 wt\%$ SiC, 92.0 $B_4C,$ SiC,	C-15 wt% SiC ¹²⁹		Pressureless	2150	1 wt% CeO,	91.2	B,C, SiC, CeB,	
wt% SiC129 wt% SiC129 SiC (0.8 µm), SiC (0.5 µm) FresurelessPressureless2150 5 wt% CeO25 wt% CeO2 96.4 94.6 Bd, SiC (0.8 µm), SiC (0.5 µm) FressurelessPressureless2150 7 wt% CeO25 wt% CeO2 94.6 Bd, SiC CeB6 $$ $$ wt% SiC129 wt% SiC129 Bd, C (0.8 µm), SiC (0.5 µm) Bd, C (0.5 µm) Bd, SiC (0.5 µm) Fressureless2150 7 wt% CeO29 wt% CeO2 94.6 Bd, SiC, CeB6 $$ $$ $$ $$ $$ $$ $$ $$ $$ $$ $$ $$		0-15 wt% SiC ¹²⁹		Pressureless	2150	3 wt% CeO.	92.6	B,C. SiC. CeBe	
wtw SiC 129 B4 C (0.8 µm), SiC (0.5 µm)resurces21507 wtw CeO294.6 B4C, SiC, CeB6wt% SiC 129 B4 C (0.8 µm), SiC (0.5 µm)Pressureless21507 wt% CeO294.4 B4C, SiC, CeB6wt% SiC 129 B4 C (3.5 µm)Pressureless21509 wt% CeO294.4 B4C, SiC, CeB6wt% SiC 91 B4 C (3.5 µm)Hot-press (30 MPa)1950No91.7 B4Cwt% SiC 91 B4 C (3.5 µm), PCSHot-press (30 MPa)1950No90.1 B4C, SiCSiC <1.0	wt% SiC 129 B_4^{-} C (0.8 µm), SiC (0.5 µm)Pressureless21507 wt% CeO294.6 B_4^{-} C, SiC, SiC, SiC, SiC, SiC, SiC, SiC, Si	-15 wr0% SiC ¹²⁹		Pressureless	2.150	5 wt% CeO	96 4	B.C. SiC. CeB.	
wt% SiC ¹²⁹ B_4^{c} (0.8 µm), SiC (0.5 µm) Pressureless 2150 9 wt% CeO ₂ 9.44 , SiC, CeB ₆ $-$ wt% SiC ¹²⁹ B_4^{c} (0.8 µm), SiC (0.5 µm) Hot-press (30 MPa) 1950 No $9.1.7$ B_4^{c} (SiC, CeB ₆ $-$ wt% SiC ⁹¹ B_4^{c} (3.5 µm), PCS Hot-press (30 MPa) 1950 No $9.1.7$ B_4^{c} (SiC, CeB ₆ $-$ wt% SiC ⁹¹ B_4^{c} (Si, 5 µm), PCS Hot-press (30 MPa) 1950 No $9.1.7$ B_4^{c} (SiC, CeB ₆ $-$ wt% SiC ⁹¹ B_4^{c} (Si, 5 µm), PCS Hot-press (30 MPa) 1950 No $9.1.84^{c}$ (SiC, SiC B_4^{c} (SiC B_4^{c} (SiC $-$ wt% SiC ¹³¹ B_4^{c} (SiC Pacsureless 1950 No 8 B_4^{c} (SiC, Si $ -$ wt% SiC ¹³¹ B_4^{c} (SiC Pac, SiC B_4^{c} (SiC, Si $ -$	wt% SiC ¹²⁹ B_4C (0.8 µm), SiC (0.5 µm) Pressureless 2.150 9 wt% GeO_2 9.3.4 B_4C , SiC, SiC, SiC, SiC, SiC (0.5 µm) wt% SiC ⁹¹ B_4C (3.5 µm), SiC (0.5 µm) Hot-press (30 MPa) 1950 No 91.7 B_4C , SiC, SiC wt% SiC ⁹¹ B_4C (3.5 µm), PCS Hot-press (30 MPa) 1950 No 96.1 B_4C , SiC wt% SiC ⁹¹ B_4C (3.5 µm), PCS Hot-press (30 MPa) 1950 No 96.1 B_4C , SiC wt% SiC ⁹¹ B_4C SiC No 99.1 B_4C , SiC wt% SiC ¹³¹ B_4C SiC No 99.1 B_4C , SiC wt% SiC ¹³¹ B_4C , SiC Pressureless 1950 No 89.0 B_4C , SiC wt% SiC ¹³¹ B_4C , SiC Pressureless 1950 No 89.0 B_4C , SiC wt% SiC ¹³¹ B_4C , SiC Pressureless 1950 No 89.0 B_4C , SiC wt% SiC ¹³¹ B_4C , SiC Pressureless 1950 St 89.0 B_4C , SiC wt% SiC ¹³¹ B_4C , SiC Pressureless 1950 St St	C-15 wt% SiC ¹²⁹	B.C (0.8 mm) SiC	Dressureless	2.150	7 wr% CeO	946	B.C. SIC CeR	
wt/9 SiC ⁹¹ B_4C (55 µm), 5C (0.5 µm) Tresurces 2.1.0 9.1.7 B_4C (5.6 µm), 5C (0.5 µm) wt/9 SiC ⁹¹ B_4C (3.5 µm), PCS Hot-press (30 MPa) 1950 No 9.1.7 B_4C (5.6 µm) 5.0, SiC < 1.0	wt/w SiC ⁹¹ B_4C (35 µm), or (0.5	7-15 mt06 cir ¹²⁹		Dracentralace	2150		0.2 4		
	wt% SiC91 B_4C (35 µm), PCSHotpres (30 MPa)1.200NO9.1 B_4C , SiCwt% SiC91 B_4C (3.5 µm), PCSHotpress (30 MPa)1950NO99.1 B_4C , SiCwt% SiC91 B_4C (3.5 µm), PCSHotpress (30 MPa)1950NO99.1 B_4C , SiCwt% SiC131 B_4C (SiCPressureless1950NO8 wt% Si99.1 B_4C , SiCwt% SiC131 B_4C , SiCPressureless1950NO8 wt% Si99.0 B_4C , SiCwt% SiC131 B_4C , SiCPressureless19502 wt% Si88.0 B_4C , SiCwt% SiC131 B_4C , SiCPressureless19502 wt% Si89.0 B_4C , SiC, SiC, Nt% SiC, SiC, SiC, SiC, SiC, SiC, SiC, SiC,		$B_{1}C(3.5 \text{ mm})$	Hot-press (30 MDa)	1950		F.CC	, ĵ	
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	15 mt0/ civ ⁹¹		Hot press (20 MDs)	1050	No	1 20		
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	B_4C (3::. Jun), FC3 HOUPLES (30 Mera) 1930 No 99.1 B_4C , SiC B_4C (SiC Pressureless 1950 No 89.0 B_4C , SiC B_4C (SiC Pressureless 1950 2 wt% Si 88.0 B_4C , SiC B_4C , SiC Pressureless 1950 2 wt% Si 89.0 B_4C , SiC, SiC B_4C , SiC Pressureless 1950 5 wt% Si 89.0 B_4C , SiC, SiC B_4C , SiC Pressureless 1950 10 wt% Si 92.0 B_4C , SiC, SiC, SiC, SiC, SiC, SiC, SiC, SiC	7 15+0/ 010	$D_4 C (3.5 \mu m), \Gamma C3$	IIUCPICSS (30 MIL a)	1050	0.1140 1	1.00		
B ₄ C, SIC Pressuretees 1950 NO 89.0 B ₄ C, SIC B ₄ C, SiC Pressuretees 1950 2 wt% Si 88.0 B ₄ C, SiC, SiC B ₄ C, SiC Pressuretees 1950 2 wt% Si 88.0 B ₄ C, SiC, SiC, SiC B ₄ C, SiC Pressuretees 1950 5 wt% Si 89.0 B ₄ C, SiC, SiC, SiC B ₄ C, SiC Pressuretees 1950 10 wt% Si 92.0 B ₄ C, SiC, SiC, SiC	B_4 C, SIC Pressureless 1950 NO 89.0 B_4 C, SIC B_4 C, SiC Pressureless 1950 2 wt% Si 88.0 B_4 C, SiC B_4 C, SiC Pressureless 1950 5 wt% Si 89.0 B_4 C, SiC, SiC B_4 C, SiC Pressureless 1950 10 wt% Si 92.0 B_4 C, SiC, SiC	С-13 WL% 310		nucpress (au mra)	1020	0 WL%0 JI	1.99		< 0.0, 01C <
B ₄ C, SIC Pressureless 1950 2 wt% SI 88.0 B ₄ C, SIC B ₄ C, SiC Pressureless 1950 5 wt% Si 89.0 B ₄ C, SiC, SiC B ₄ C, SiC Pressureless 1950 10 wt% Si 92.0 B ₄ C, SiC, SiC, SiC	B_4C , SIC Pressureless 1950 2 W7% SI 88.0 B_4C , SIC Pressureless 1950 5 W7% Si 89.0 B_4C , SiC, B $_4C$, SiC Pressureless 1950 10 W7% Si 92.0 B_4C , SiC, B $_4C$, SiC, Pressureless 1950 10 W7% Si 92.0 B_4C , SiC, SiC, SiC, SiC, SiC, SiC, SiC, SiC	C-60 WT% SIC		Pressureless	1950	NO 0 00 50 50	89.U		
B ₄ C, SIC Pressureless 1950 5 wt% Si 89.0 B ₄ C, SIC B ₄ C, SIC Pressureless 1950 10 wt% Si 92.0 B ₄ C, SIC	B ₄ C, SIC Pressureless 1950 5 wt% SI 89.0 B ₄ C, SIC, SIC, B ₄ C, SIC, B ₄ C, SIC, SIC, B ₄ C, SIC, SIC, B ₄ C, SIC, B ₄ C, SIC, SIC, B ₄ C, SIC, SIC, SIC, SIC, SIC, SIC, SIC, SI	C-60 WT% SIC ¹³¹		Pressureless	1950	2 WT%0 SI	88.0		
B ₄ C, SiC Pressureless 1950 10 wt% Si 92.0 B ₄ C, SiC,	B4C, SiC Pressureless 1950 10 wt% Si 92.0 B4C, SiC,	C-60 WT% SIC ¹²¹		Pressureless	1950	5 Wt% S1	89.0	B4C, SIC, SI	
				Pressureless	1950	10 Wt% S1	92.0	B4C, SIC, SI	

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Effect of sintering aids on the sintering performance and microstructure of B4C-SiC ceramics

Table 6

Materials Advances

Ceramics Raw material	al Sintering method	Sintering temperature (°C) Sintering aid		Relative density (%)	Relative density (%) Phase composition	Average grain size (µm)
$\begin{array}{c} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ B_4C, \ sic} B_4C-60 \ wt\% \ sic^{131} \ b_{4C} \ sic} B_{4C}-60 \ wt\% \ sic^{131} \ \ $	Pressureless Spark plasma (50 MPa) Spark plasma (50 MPa) Spark plasma (50 MPa) Spark plasma (50 MPa) Spark plasma (50 MPa)	1950 1600 (×5 min) 1350 (×5 min) 1350 (×5 min) 1350 (×5 min) 1350 (×5 min)	20 wt% Si No 2 wt% Si 5 wt% Si 10 wt% Si 20 wt% Si	90.0 94.0 94.6 96.3 98.0	B ₄ C, SiC, Si B ₄ C, SiC — B ₄ C, SiC, Si, B ₄ Si B ₄ C, SiC, Si, B ₄ Si B ₄ C, SiC, Si, B ₄ Si	

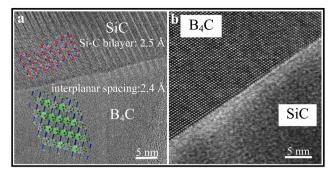


Fig. 8 HRTEM images of B₄C–SiC ceramics prepared by solid-state sintering revealing the phase boundary characteristics between B₄C and SiC: (a) B₄C–40 wt% SiC ceramics with 3 wt% carbon black¹³⁶ (reprinted with permission, Copyright 2019, Elsevier) and (b) B₄C–15 wt% SiC ceramics with 2 wt% carbon black¹⁰⁷ (reproduced with permission, Copyright 2019, Elsevier).

on the surface of original B4C particles when the solubility of B and C in molten Si becomes saturated, forming rim regions. This indicates that the formation of the $B_{12}(B, C, Si)_3$ rim is the dissolution-precipitation process. This newly formed ternary phase $B_{12}(B, C, Si)_3$ at the boundaries of neighboring B_4C particles through dissolution-reprecipitation mechanism is also supported by Zhang et al.¹¹⁷ in the reaction-bonded B₄C–SiC ceramics. In contrast, Jannotti et al.¹³⁹ proposed a different view that the B₁₂(B, C, Si)₃ phase is a Si-doped B₄C phase. The Si substitutes for the C atoms on the ends of the linear chain and inserts into the icosahedrons in the B4C lattice, and C atoms react with liquid Si, generating SiC. Wang *et al.*¹⁴⁰ mentioned that the $B_{12}(B, C, Si)_3$ rim surrounding B₄C is generated by Si inward diffusion in B₄C from a liquid. Sun et al.¹⁴¹ put forward that there are two types of $B_{12}(B, C, Si)_3$ phases in the reaction-bonded B_4C -SiC ceramics. One is $B_{12}(B, C, Si)_3$ with high Si content, derived from the reaction between Si and decomposed B₄C (Si, B, and a part of C react to generate $B_{12}(B, C, Si)_3$, and the remaining C diffuses into the liquid Si, generating plate-like SiC; the other is B₁₂(B, C, Si)₃ with low Si content, resulting from the diffusion of Si into B₄C (solid solution process).

The core-rim structure of B_4C is formed in the B_4C -SiC ceramics produced *via* a conventional reaction-bonded sintering route; however, Thuault *et al.*⁶³ found that there is no core-rim structure of B_4C in the reaction-bonded B_4C -SiC ceramics prepared by the microwave assisted processing method in an Ar-H₂ atmosphere. The compositions of the obtained composite ceramics are B_4C , β -SiC, and Si; there is no $B_{12}(B, C, Si)_3$ phase. The reason why the core-rim structure is not formed is that the rapid heating generated by microwaves and the infiltration process under an Ar-H₂ gas flow at atmospheric pressure prevents the secondary reaction among Si, C, and B.

In addition, when the preform containing α -SiC is used to prepare reaction-bonded B₄C–SiC ceramics, besides the core– rim structure of B₄C surrounded by the B₁₂(B, C, Si)₃ rim, the core–rim structure of primary α -SiC surrounded by the secondary β -SiC rim is also observed (Fig. 9c).^{85,140} C first dissolves in molten Si and then diffuses to the vicinity of the original α -SiC

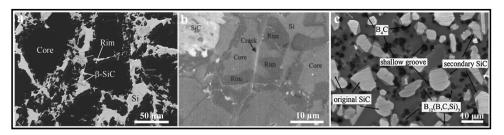


Fig. 9 SEM images of reaction-bonded B_4C -SiC ceramics exhibiting: (a) core-rim structure of B_4C particles¹³⁷ (reproduced with permission, Copyright 2009, Elsevier), (b) crack propagation path passing through the core-rim structure of B_4C^{138} (reproduced with permission, Copyright 2010, John Wiley and Sons), and (c) core-rim structure of SiC particles⁸⁵ (reproduced with permission, Copyright 2016, Elsevier).

grains, forming supersaturated liquid Si[C]. Compared with the homogeneous nucleation in a liquid phase, the supersaturated liquid Si[C] is more prone to heterogeneously crystallize to form β -SiC attached to the original α -SiC grains because of the relatively lower energy. The initial α -SiC grains are interconnected by the newly formed β -SiC rim structure to generate a cluster of SiC grains. Because the β -SiC grows fast at a much lower temperature than that of the initial α -SiC, many faults (twinning and lattice distortion) generate inside the β -SiC grains. Song et al.⁸⁵ considered that the dissolution process is exothermic, allowing the local temperature to increase at the dissolution sites. When the C gradually dissolves in molten Si, the C activity gradient within Si will cause a rapid diffusion of C away from the dissolution sites. The C diffuses to locally cooler sites (the initial SiC particles) until a supersaturation occurs in the molten Si and then the C precipitates as an epitaxial SiC rim. β-SiC cannot nucleate on B₄C with rim, which is attributed to the lattice mismatch between β -SiC and B₁₂(B, C, Si)₃.

3.5.2.2. Morphology of SiC. Reaction-bonded B_4C -SiC ceramics can be produced with or without free C in the preform. The C used to form SiC *in situ* can come from free C or/and C originally present in B_4C . When the free C is present in the preform, the siliconization chemical reaction (8) predominates.

$$Si + C \rightarrow SiC$$
 (8)

The reaction (3) also occurs in parallel in the region where the free carbon concentration is locally reduced. However, when only B_4C is used as the C source, the formation of SiC is completely based on the reaction (3). Different C sources give rise to different morphologies of SiC grains *in situ* generated.

Hayun *et al.*¹³⁷ noted that the β -SiC particles have a plate-like shape (Fig. 10a) when B₄C acts as the sole source of C (without free C addition), while β -SiC particles show a polygonal shape (Fig. 10b) and only a small fraction of SiC displays a plate-like shape in the presence of 5 wt% free C, which is added by infiltration with an aqueous sugar solution. In the absence of free C, the gradual diffusion of C from B₄C favors the plate-like shape of the obtained secondary SiC. In fact, the polygonal β -SiC particles are built by mutually bonded plate-like particles; thus, a key factor that determines the morphology of the β -SiC particles is the available amount of C. Two C sources are available for β -SiC formation in the presence of free C, resulting in the formation of polygonal SiC particles. SiC particles precipitate at the melt/graphite interface after the dissolution of free C in the melt. Liquid Si continues to react with B₄C after the consumption of free C and some additional plate-like SiC particles are formed. Although the addition of C controls the morphology of the formed SiC particles, it is very interesting to note that the relative amounts of the SiC formed are similar for the B₄C-SiC ceramics produced with and without free C addition for a certain initial porosity of the preforms.¹⁴² This indicates the following two points: (1) porosity of the preform is a key factor determining the amount of SiC formed. As the initial porosity of the preform increases from 20 to 40 vol%, the amount of SiC formed slightly increases from 8 to 12 vol%; and (2) B₄C-SiC ceramics can be produced by molten Si infiltration even in the absence of free C (external C source). Although secondary SiC particles with a plate-like morphology were observed by Hayun et al.¹³⁷ in the B₄C-SiC ceramics produced from the preform composed of sole B₄C without free C addition, Aroati et al.¹⁴³ found that no plate-like SiC particles are formed

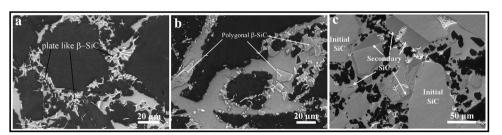


Fig. 10 Morphology of SiC grains in reaction-bonded B_4C -SiC ceramics produced from the preforms with different compositions: (a) B_4C without free C addition, (b) B_4C with 5 wt% free C addition¹³⁷ (reproduced with permission, Copyright 2009, Elsevier), and (c) the mixture of B_4C and SiC without free C addition¹⁴³ (reproduced with permission, Copyright 2010, Elsevier).

in the B_4C -SiC ceramics produced from the preform composed of a mixture of SiC and B_4C without free C addition (Fig. 10c). This is because there are SiC particles in the preform, so heterogeneous nucleation of secondary SiC occurs on the surface of these initial SiC particles.

3.5.2.3. Particle size. The particle sizes of B₄C and SiC in reaction-bonded B₄C-SiC ceramics are also related to C sources and contents. Gao *et al.*¹⁴⁴ reported that B₄C–SiC ceramics can be produced without the addition of C via reaction-bonded sintering; however, the particle sizes of B₄C and SiC are not uniform in the case of without adding C, which is attributed to the difficulty of B₄C sintering. The addition of C in the range of 5 to 10 vol% can make the particle sizes of B4C and SiC smaller and make their particle size distributions more uniform. However, largesized particles, which come from the aggregation of SiC formed, and Si spots are generated in the B4C-SiC ceramics when the addition of C is more than 10 vol%. This indicates that the addition of excessive C will lead to the increase in the particle size of B4C-SiC ceramics and less uniform phase distribution. Li et al.⁷⁶ also found that compared with no C addition, the grain sizes of SiC and Si are smaller in the case of carbon black addition, which may result from the decreased pore size in the preform as the content of carbon black increases.

The particle size of B₄C is affected by two competing factors; one is the dissolution and reaction of B_4C with liquid Si, consuming the B4C particles and decreasing the particle size and the other is the precipitation of $B_{12}(C, Si, B)_3$, forming the coarsened B₄C particles and increasing the particle size. Meanwhile, the formed $B_{12}(C, Si, B)_3$ promotes the generation of a sintering neck between neighboring B₄C grains. The distance between neighboring B₄C grains is decreased with further expansion of the sintering neck, allowing the neighboring B_4C grains to grow together and increasing the particle size of B₄C. Therefore, the formation of $B_{12}(C, Si, B)_3$ results in the loss of B₄C, which reduces the hardness of B₄C-SiC ceramics, the aggregation and bonding of neighboring B4C grains, and the consequent increase in particle size. In order to protect the B₄C grains from dissolution and reaction in liquid Si, several methods can be used to limit the formation of a large number of $B_{12}(B, C, Si)_3$ phases.

First, the pre-production of C-coated B_4C particles. Zhang *et al.*¹⁰¹ first used the phenolic resin as an external C source to prepare C (10 wt%)-coated B_4C particles by pyrolysis and carbonization, during which the phenolic resin uniformly attached to the B_4C particles is transformed into an amorphous C layer or C nanoparticles, which were then used to fabricate the reaction-bonded B_4C -SiC ceramics. As a result, the C layer acts a barrier between B_4C grains and molten Si, and the molten Si preferentially reacts with the C layer. The C-coating can effectively protect the B_4C grains from reacting with molten Si, reducing the dissolution and reaction loss of B_4C . Compared with the reaction-bonded B_4C -SiC ceramics prepared from a mixture of B_4C and carbon black powders (an external C source), which is formed only by the mechanical mixing of the two, the content of B_4C in the B_4C -SiC ceramics prepared from the C-coated B_4C

particles is higher and the B4C grains can maintain the initial irregular shape. In contrast, the B4C grains in the B4C-SiC ceramics prepared from uncoated B4C particles change from irregular shape to faceted shape. It is reported that the B₄C grains will grow rapidly after they are transformed into the faceted shape;¹¹⁸ thus, the grain size of B_4C in the B_4C -SiC ceramics prepared from the C-coated B4C particles is smaller than the ones in the B₄C-SiC ceramics prepared from the mixture of uncoated B₄C and carbon black. On the other hand, in situ formed nano-SiC grains wrap the B₄C grains forming a nano-SiC grain-coating layer in the B₄C-SiC ceramics prepared from the C-coated B₄C particles; the neighboring B₄C grains can be bonded together with these nano-SiC grains, generating a continuous ceramic skeleton. In contrast, for the B4C-SiC ceramics prepared from a mixture of uncoated B₄C and carbon black, most of the formed SiC grains with a size of 1 µm are isolated in free Si, and many large-sized SiC zones of 50 μm are formed, which is attributed to the nonuniform dispersion of the nano-carbon black. Although the pre-production of C-coated B₄C particles is relatively complex for the production of B₄C-SiC ceramics, this method can achieve not only a uniform distribution of B4C and SiC but also a continuous ceramic skeleton composed of nano-SiC grain-coated and -bonded B4C grains.

Second, the introduction of free B into the preform; free B dissolves in molten Si and decreases the Si activity towards B_4C .¹¹⁵ This method increases the possibility that a mixture of boron silicides with varying stoichiometry will be present in the resulting ceramics, lowering the additive cracking resistance.¹¹⁵

Third, a decrease in the siliconization temperature to approximately 1450–1550 $^{\circ}$ C, at which the predominant process is reaction (8); an improvement in the sintering temperature to 1600 $^{\circ}$ C leads to an appreciable acceleration of reaction (3).¹¹⁵ This method may increase the viscosity of molten Si and decrease the relative density, leading to the formation of residual C and deteriorated mechanical properties.

Actually, although these methods can protect the B_4C grains and limit the formation of $B_{12}(B, C, Si)_3$, their effects on the microstructure and other properties of B_4C –SiC ceramics should also be considered.

3.5.2.4. Residue and morphology. B_4C -SiC ceramics produced by reaction-bonded sintering often contain undesirable residual phases. If the ceramics have a Si deficit or are poorly homogenized, there will be some incompletely siliconized regions containing C in the resulting B_4C -SiC ceramics. Similarly, residual C also forms in cases where the porosity of the preform lies below the threshold for molten Si to flow through the porous preform, the sintering temperature is too low for molten Si to reach the required viscosity, or the holding time is too short. In contrast, residual Si will form in the case of a C deficit or excessive porosity. These residues affect the mechanical properties of B_4C -SiC ceramics, which will be discussed in Section 4.2.2.

The source of free C can not only come from carbon black, but also from carbon fibers. Two different sources of free C affect the morphology of residual Si. Song *et al.*⁸⁵ used carbon fibers as a carbon source to produce reaction-bonded B₄C–SiC

ceramics. The porous self-supporting interpenetrating network structure of carbon fibers is helpful for Si infiltration. During the Si infiltration, homogeneously and randomly distributed carbon fibers completely react with the molten Si, whose dominant mechanism is diffusion, and the residual Si particles occupy the original positions of carbon fibers, forming fiberlike extensions. This microstructure is different from that of the reaction-bonded B₄C-SiC ceramics using carbon black as the C source. The residual Si with fiber-like extensions is a revamped form of residual Si, and the residual Si is spread out throughout the matrix, reducing the dimensions of the Si islands. With the increase in carbon fiber content, the amount of newly formed β-SiC is increased and the amount of residual Si is reduced. Meanwhile, the formation of β -SiC during the siliconisation reaction between the carbon fibers and molten Si causes a large volume expansion, which is favorable for decreasing the space of residual Si.

4. Mechanical properties of B_4C -SiC composite ceramics

The mechanical properties of B₄C-SiC ceramics are crucial for their applications. Hardness, fracture toughness, and bending strength are important mechanical properties of B₄C-SiC ceramics. Higher hardness will make B₄C-SiC ceramics a very interesting material for applications where high wear resistance is required, and higher bending strength will make B4C-SiC ceramics an interesting material from the structural application point of view. For example, due to excellent mechanical and physical properties, *i.e.*, high hardness, high bending strength, relatively high fracture toughness, and low density, B4C-SiC ceramics are one of the most potential candidates for novel bulletproof materials. To obtain desirable mechanical properties for polycrystalline B₄C-SiC ceramics, various aspects have been investigated. The research works focus on the effect of the microstructure, phase composition, raw materials, preparation process, and sintering aids on the mechanical properties of B4C-SiC ceramics, which will be discussed in detail in this part.

4.1. Microstructure

The good mechanical properties of B_4C -SiC ceramics are related to the control of the microstructure, which mainly includes the grain characteristics, grain boundary characteristics, pores, and flaws. In general, when the composition of the material is determined, the hardness is controlled by its relative density and grain size. To improve the hardness of B_4C -SiC ceramics, their grain size should be as low as possible, and their relative density should be as high as possible. The bending strength of B_4C -SiC ceramics is determined by the flaw size, and the bending strength increases with decreased flaw size. Generally, the flaws generated at the interface propagate to a maximum of up to one grain size.¹⁴⁵ Pores, as a major flaw, are also detrimental to the bending strength of B_4C -SiC ceramics. On the one hand, pores can reduce the cross-sectional areas across which a load is applied; on the other hand, pores act as stress concentrators. Therefore, reducing the porosity is beneficial for improving the hardness and bending strength of B_4C -SiC ceramics. There are many methods to reduce the porosity to improve the mechanical properties of B_4C -SiC ceramics, such as refinement of raw materials, improvement of sintering temperature, and addition of sintering aids, *etc.*, which will be described later. The fracture toughness of B_4C -SiC ceramics is closely related to the crack propagation mode, which is decided through various factors, such as the phase boundary characteristics between B_4C and SiC grains (bonding strength of the interface), residual stress development, and grain morphology. In addition, dislocations, as a kind of crystal defect, can change the course of the crack when a crack runs into dislocations; also, complicated dislocation lines can be regarded as a second refinement on matrix grains.

4.1.1. Phase boundary characteristics between B₄C and SiC. For composite materials, the characteristics of the twophase interface play a crucial role in the mechanical properties. For B₄C-SiC ceramics, the phase boundary characteristics decide the interfacial bonding between B4C and SiC. Cracks always propagate along the weak joint in the stress field. If the interfacial bonding between B4C and SiC is weak, cracks will extend along the phase boundary, causing an intergranular crack. In contrast, if the interfacial bonding is stronger than the cohesion strength of individual B₄C and SiC grains, a transgranular crack will be the predominant fracture mode. Intergranular fracture contributes to increasing fracture toughness, while transgranular fracture plays a positive role in strength. As reported in the liquid-phase sintered SiC ceramics, the aluminosilicate interphase provides a tortuous path for cracks and facilitates crack branching; the comparatively weak intergranular interphase is the preferential path for crack propagation, improving the fracture toughness.¹⁴⁶ Generally, the phase boundary of solidstate sintered B4C-SiC ceramics is clean (Fig. 8); conversely, some secondary phase or amorphous layer exists between B₄C and SiC grains after liquid-phase sintering.

The clean phase boundary makes the bond between B₄C and SiC grains very strong. Zhang et al.98 and Yaşar and Haber⁷¹ found that cracks cross the B₄C and SiC grains, rather than propagating along the phase boundary, when cracks propagate in the hot-press sintered B₄C-50 wt% SiC ceramics without any sintering aid (Fig. 11a) and spark plasma sintered 10-50 wt% B₄C-SiC ceramics with a sintering aid of 1.5 wt% C, respectively. This indicates that interface cohesion between B₄C and SiC is powerful, and no crack deflection happens at the clean phase boundary. Normally, intergranular fracture plays a positive role in toughness. Although transgranular fracture is the predominant fracture mode of solid-state sintered B4C-SiC ceramics, the fracture toughness of B₄C-SiC ceramics is higher than that of pure B₄C ceramics,⁹⁸ which solves the problem that the widespread application of pure B₄C ceramics is restricted due to their low fracture toughness. The powerful interfacial bonding between B₄C and SiC plays a key role in fracture toughness. For B₄C-SiC ceramics with transgranular cracks, the usual toughening mechanisms of crack propagation, such as crack bridging, deflection, and branching, are not applicable.

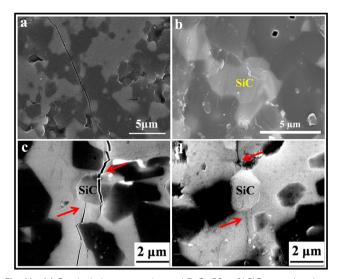


Fig. 11 (a) Cracks in hot-press sintered B_4C-50 wt% SiC ceramics showing a transgranular mode⁹⁸ (reprinted with permission, Copyright 2013, Elsevier), (b) fracture surface of spark plasma sintered B_4C-20 vol% SiC ceramics exhibiting rougher SiC grains than B_4C grains,¹¹¹ and indentation crack propagation in reaction-bonded B_4C-SiC ceramics revealing: (c) crack branching and (d) crack bridging¹¹⁷ (reprinted with permission, Copyright 2014, John Wiley and Sons).

With regard to the increased fracture toughness of B₄C-SiC ceramics, different mechanisms have been proposed by the researchers. The classical thermal expansion mismatch theory in toughening states that the fracture toughness is determined by the residual stress that can control the interaction between the composite microstructure and crack propagation;¹⁴⁷ the residual stress is caused because of the mismatch of thermal expansion coefficients between matrix and the second phase or inclusions. The release of residual stress plays an effective role in the improvement of fracture toughness. For B₄C-SiC ceramics, the residual stress is generated by a difference in the thermal expansion coefficients of B₄C and SiC. Zhang et al.⁹⁸ stated that the difference in thermal expansion coefficients of B_4C (5.73 \times 10⁻⁶ $^{\circ}C^{-1}$) and SiC (4.50 \times 10⁻⁶ $^{\circ}C^{-1}$) is not obvious, leading to the minimal residual thermal stress at their interface, which is inadequate to cause crack deflection or intergranular fracture. Hwang et al.⁸⁷ calculated the theoretical residual stress between the B4C matrix and SiC particulate and verified experimentally by the Raman mapping that the compressive residual stress developed in the B₄C matrix around SiC particulates is small, whose value is between 27–64 MPa for ΔT (temperature range over which stress is not relieved by a diffusive process) = 800–1900 °C. This means that the contribution of residual thermal stress to the toughening of B₄C-SiC ceramics is quite limited; thereby, the microstructure is responsible for the marked increase in fracture toughness. Small residual stress explains why cracks cross the B₄C and SiC grains, rather than crack deflection at the B₄C-SiC interface. Zhang et al.⁹⁸ claimed that the increased fracture toughness is attributed to the crack impeding mechanism rather than the crack deflection mechanism, and the SiC content is a more important factor than the residual stress. The fracture toughness of SiC is higher

than that of B₄C, and cracks consume more energy when crossing SiC grains. This hypothesis was demonstrated by the observation of Wu et al.¹¹¹ that the SiC grains are rougher than B₄C grains on the fracture surface of the spark plasma sintered B₄C-20 vol% SiC ceramics (Fig. 11b). Therefore, the fracture toughness of B₄C-SiC ceramics is higher than that of pure B₄C ceramics. However, Moradkhani and Baharvandi⁸⁰ argued that the increased fracture toughness is related to residual stress. They observed that the fracture toughness of pressureless solid-state sintered B₄C-SiC ceramics increases with the addition of SiC from 2.5 to 10 vol%, and the fracture mode of B4C-SiC ceramics changes from intergranular fracture to transgranular fracture with the increase in SiC content, which is ascribed to the formation of compressive residual stress around the reinforcing SiC particles and tensile stress in the matrix B₄C phase due to the unequal thermal expansion coefficients between B4C and SiC. First, the compressive stress is transferred to the phase boundary between B4C and SiC. When cracks move toward the phase boundary, the existing compressive stress at the phase boundary will divert the cracks toward the grain interior, consuming the energy of the crack. The compressive stress can increase the fracture toughness for B₄C-SiC ceramics by preventing crack nucleation and growth. Second, the release of residual stress will lead to the formation of dislocations around the reinforcing SiC particles and microcracks within grains. The generation of dislocations can make it difficult for cracks to propagate; the emergence of microcracks can increase the fracture toughness by microcrack toughening mechanism.

For the reaction-bonded B_4C –SiC ceramics produced *via* liquid-phase sintering, the crack propagation mode is different from that of B_4C –SiC ceramics with a clean phase boundary prepared by solid-state sintering. Crack bridging and crack branching, both of which are considered to enhance the fracture toughness of materials, are observed in the reaction-bonded B_4C –SiC ceramics (Fig. 11c and d).¹¹⁷ SiC particles cause crack branching and also play a bridging role. Both crack branching and crack bridging can consume more energy and thus increase the resistance to crack propagation for B_4C –SiC ceramics.

4.1.2. Grain morphology. Grain morphology affects the mechanical properties of B_4C -SiC ceramics. The grain morphology of B_4C -SiC ceramics is mainly influenced by the raw material size, raw material specie, and parameters during sintering.

Moradkhani and Baharvandi⁸⁰ observed cleavage surfaces within grains (Fig. 2k and l) in the pressureless sintered B_4C -SiC ceramics. These cleavage surfaces can act as a crack path diverter, the generation of which is beneficial for improving the fracture toughness of B_4C -SiC ceramics.

As mentioned in Section 3.5.2, the grain morphology in the reaction-bonded B_4C –SiC ceramics is complex, which depends primarily on the C source, the addition of SiC, and the processing method. In the case of the conventional reaction-bonded sintering route, B_4C grains show a core–rim structure characteristic. There is a debate on the effect of the $B_{12}(B, C, Si)_3$ phase in the form of rims generated on B_4C cores on the mechanical properties of B_4C –SiC ceramics. Hayun *et al.*^{84,138} claimed that

Young's modulus and hardness of the $B_{12}(B, C, Si)_3$ phase are slightly higher than those of B₄C. Jannotti et al.¹³⁹ reported that the B₁₂(B, C, Si)₃ phase can yield improved mechanical properties for B_4C -SiC ceramics. However, Song *et al.*^{60,85} argued that the $B_{12}(B, C, C)$ Si)₃ phase has high brittleness, which can be proved by the obvious grooves formed on the surface, resulting from the peeling off of the B₁₂(B, C, Si)₃ phase during polishing. Therefore, the generation of a large number of $B_{12}(B, C, Si)_3$ phases may increase the brittleness of B₄C-SiC ceramics, which is not conducive to improving the fracture toughness of the ceramics.¹¹⁵ The contribution of the B₄C grains with a core-rim structure to the mechanical properties of B₄C-SiC ceramics needs to be further elucidated. Furthermore, from the view of grain size, coarse B₄C grains become the crack source during the fracture process; thus large-sized B₄C grains are unfavorable to improving the bending strength of B₄C-SiC ceramics.⁹⁹ On the other hand, when the reaction-bonded B4C-SiC ceramics are prepared by a microwave-assisted processing method, no core-rim structure of B₄C is observed.⁶³ The hardness (22 GPa) of B₄C-SiC ceramics prepared by the microwave-assisted processing method is comparable to that prepared by the conventional reaction-bonded process, but Young's modulus (309 GPa) is lower than that obtained using the conventional process.

The C source (free C addition or C originating from B_4C) directly affects the morphology of SiC grains formed in situ (Section 3.5.2.2), which in turn controls the mechanical properties of reaction-bonded B₄C–SiC ceramics.¹⁴⁸ Compared with the SiC with polygonal morphology, the SiC with plate-like morphology can provide higher bending strength, fracture toughness, and compressive strength for B4C-SiC ceramics. The volume fraction of SiC formed is not dependent on the C source. The SiC grains with a polygonal morphology are coarser than those with platelike morphology; thus, the density of plate-like SiC grains is higher than that of polygonal SiC grains. Therefore, the number of inter-particle boundaries which have to be crossed by a propagating crack is large in the B₄C-SiC ceramics with platelike SiC grains, leading to increased fracture toughness. Dariel and Frage99 also mentioned that the morphology of SiC grains has a strong effect on the bending strength and fracture toughness of B₄C-SiC ceramics. The B₄C-SiC ceramics with plate-like shaped SiC possess higher bending strength and fracture toughness than the B_4C -SiC ceramics with polygonal SiC. This phenomenon is attributed to the strengthening and toughening effects of SiC particles with a plate-like shape. The SiC particles with a plate-like shape have a high aspect ratio, and SiC grains with a plate-like morphology likely cause crack deflection compared to those with a polygonal morphology. These plate-like shaped SiC particles can affect crack propagation through the B4C-SiC ceramics via a large number of boundaries that are crossed by cracks, which can cause larger crack energy losses. Although the plate-like morphology of SiC grains can improve the fracture toughness and bending strength of B₄C-SiC ceramics, it does not affect the hardness and stiffness of B₄C-SiC ceramics.

4.2. Phase composition

The mechanical properties of B₄C–SiC ceramics depend on the relative amount of phases present. For example, the intrinsic

hardness of the individual phase affects the hardness of B_4C -SiC ceramics. For B_4C -SiC ceramics prepared by solid-state sintering using B_4C and SiC as raw materials, an unexpected phase does not form during sintering. However, there are some unexpected residual phases in the B_4C -SiC ceramics prepared by reaction-bonded sintering, and these residual phases can affect the mechanical properties of B_4C -SiC ceramics.

4.2.1. Ratio of B₄C to SiC. The mechanical properties of B₄C-SiC ceramics are influenced by the ratio of B₄C to SiC. The intrinsic hardness of B₄C is higher than that of SiC; thus, according to the rule of mixture, B4C-SiC ceramics with higher ratios of B₄C to SiC possess a higher hardness theoretically on the condition that the samples have the same relative density, and vice versa. On the other hand, the ratio of B₄C to SiC affects the sintering performance and microstructure of the ceramics (Section 3.1). B₄C-SiC ceramics with higher ratios of B₄C to SiC are prone to have more pores, and pores play a detrimental role in the mechanical properties; refined grains and dense microstructure, both of which are beneficial in improving the mechanical properties of B4C-SiC ceramics, can be obtained by adjusting the ratio of B_4C to SiC. Therefore, the ratio of B_4C to SiC affects the mechanical properties of B4C-SiC ceramics by regulating the microstructure and following the rule of mixtures, and it is necessary to balance the ratio of B₄C to SiC in order to obtain B4C-SiC ceramics with excellent mechanical properties.

For B₄C-SiC ceramics produced by pressureless sintering, Magnani et al.⁶⁸ reported that the fracture toughness of SiC-5 vol% B4C ceramics is similar to that of pure SiC ceramics; however, the hardness and bending strength of SiC-5 vol% B₄C ceramics are higher than those of pure SiC ceramics. Higher mechanical properties of SiC-5 vol% B4C ceramics are attributed to the finer microstructure and less strength-controlling flaws like porosity as compared to pure SiC ceramics. Cho et al.69 mentioned that the hardness reduces but the fracture toughness increases when the content of B₄C increases from 1 to 5 wt% in the SiC-B₄C ceramics. The reduced hardness is attributed to the increased porosity of the ceramics, while the increased fracture toughness is caused by the toughening mechanisms of crack bridging, crack deflection, and crack branching, resulting from the presence of increased B_4C at the grain boundary. Zhang et al.⁷⁰ studied the mechanical properties of B₄C-SiC ceramics with the change of the ratio of B_4C to SiC (3/97 < B_4C wt%/SiC wt% < 100/0). The fracture toughness of B_4C -SiC ceramics does not show an obvious difference with a difference in the ratio of B_4C to SiC under the same sintering conditions. The fracture toughness of B_4C -SiC ceramics varies between 3.1 and 3.7 MPa m^{1/2}, and the fracture toughness of B4C-SiC ceramics is slightly lower than that of pure B₄C ceramics. The hardness of B₄C-SiC ceramics varies between 27 and 33 GPa, and the hardness of B₄C-SiC ceramics is higher than that of pure B₄C ceramics. SiC-40 wt% B₄C ceramics exhibit the highest hardness. When B₄C content is more than 40 wt%, excessive porosity caused by the worse sintering performance of B₄C leads to the decreased hardness for B4C-SiC ceramics, despite the higher hardness of B₄C than SiC. Vandeperre and Teo¹⁰⁸ found that the nanohardness of B₄C–SiC ceramics (5/95 < B₄C wt%/ SiC wt% < 100/0) increases linearly from 29.3 to 33.3 GPa as the B₄C content increases. The measured nanohardness values of the B₄C–SiC ceramics are close to the average theoretical hardness of B₄C and SiC because the indents made are relatively small compared to the scale of the microstructure. Furthermore, Young's modulus of B₄C–SiC ceramics hardly varies with the increase in B₄C content (356–375 GPa), which is consistent with the similar Young's modulus values of single crystal SiC (450 GPa¹⁴⁹) and single crystal B₄C (467 GPa¹⁵⁰). The measured Young's modulus values are lower than the theoretical values, attributed to the residual porosity in the ceramics.

For B₄C-SiC ceramics prepared via hot-press sintering, So et al.⁷² noted that the hardness of B₄C-SiC ceramics slightly increases with the increase in B_4C content from 30 to 70 wt%; the fracture toughness decreases with the increase in B₄C content, which is attributed to the decrease in the content of SiC with relatively high toughness. When the B₄C content is 50 wt%, the ceramics achieve the highest bending strength, which is attributed to the smallest grain size, as mentioned in Section 3.1. Chen et al.⁷⁹ observed that the bending strength and fracture toughness of B₄C-SiC ceramics increase with the increase in SiC content from 0 to 20 wt%, but the hardness of the ceramics slightly decreases. Tomohiro et al.78 reported that the hardness of B₄C-SiC ceramics decreases with the increase in SiC addition from 0 to 50 vol%, resulting from the lower hardness of SiC compared to B₄C. However, both the bending strength and fracture toughness of the ceramics are maximum when the SiC content is 20 vol%. Crack deflection, bridging, and branching by SiC grains are the main toughening mechanisms for the B₄C-SiC ceramics. Meanwhile, the microcrack caused by the difference in thermal expansion coefficients between B₄C and SiC is also responsible for the increased fracture toughness. When the SiC content is more than 20 vol%, the grain size of SiC gradually increases from 2-3 µm to 5-6 µm; also, SiC grains agglomerate, leading to inhomogeneous dispersion of SiC grains in the ceramics. Thus, the bending strength and fracture toughness of the ceramics decrease. Keçeli et al.¹⁵¹ found that the bending strength and hardness of SiC-B₄C ceramics increase with the increase in B4C content from 0 to 15 wt%, which is attributed to the finer microstructure of the ceramics with the increased B₄C content.

For spark plasma sintered B_4C -SiC ceramics, Moshtaghioun *et al.*¹¹² found that the fracture toughness of B_4C -15 wt% SiC ceramics is higher than that of pure B_4C ceramics, which is attributed to the smaller grain sizes of B_4C and SiC in the B_4C -SiC ceramics than the grain size of B_4C in pure B_4C ceramics. Meanwhile, the addition of SiC changes the fracture mode of the ceramics from transgranular fracture to a mixture of transgranular and intergranular fracture. Crack bridging by the SiC grains is the main toughening mechanism. However, the hardness of B_4C -15 wt% SiC ceramics is slightly lower than that of pure B_4C ceramics because SiC is softer than B_4C . Sahin *et al.*⁹⁶ observed that the hardness of B_4C -SiC ceramics is SiC ceramics from 34.4 to 31.1 GPa with the increase in SiC content from 5 to 15 vol%. Yaşar and Haber⁷¹ found that with

the content of B_4C in the composite ceramics increasing from 10 to 50 wt%, the hardness of SiC- B_4C ceramics increases, but the fracture toughness, Poisson's ratio, and elastic modulus decrease.

For B₄C-SiC ceramics fabricated by reaction-bonded sintering, Lee et al.¹⁵² reported that the hardness of SiC-B₄C ceramics increases from 15.4 to 30.0 GPa as the B_4C content in the preform increases from 0 to 50 wt%. The increased hardness of SiC-B₄C ceramics with an increase in B₄C content is attributed to two aspects. First, B₄C has higher hardness. Second, B₄C provides more C due to partial decomposition during the reaction bonding because a locally exothermic reaction with Si and C will cause the temperature to exceed the heating temperature, reducing the residual Si content in the matrix by the reaction of C and Si. Han et al.¹⁵³ found that the reactionbonded SiC-B₄C ceramics exhibit higher hardness, bending strength, and fracture toughness compared to the reactionbonded SiC ceramics; the mechanical properties of the reaction-bonded SiC-B4C ceramics linearly increase with an increase in B₄C content from 5 to 30 wt%. Lin and Fang¹⁵⁴ researched the mechanical properties of SiC-B₄C ceramics when the content of B_4C in the green body varies between 20 and 40 wt%. It was also found that the hardness of SiC-B₄C ceramics gradually increases with the increase in B₄C content. Furthermore, the fracture toughness and bending strength first increase and then decrease with the increase in B_4C content, both of which show the maximum values when the B4C content is 30 wt%. The decreased fracture toughness and bending strength are attributed to the higher porosity when the B₄C content is more than 30 wt%, which is caused by the sintering difficulty of B₄C. Sun et al.¹¹⁶ also noted that the hardness of B₄C-SiC ceramics increases with the increase in B₄C content from 10 to 70 wt%; however, both the bending strength and the fracture toughness increase first and then decrease. The decreased bending strength is ascribed to the destruction of the continuous phase. The SiC phase in the ceramics is continuous, but the B₄C phase is not bonded, existing in the form of a dispersion phase. Therefore, the SiC phase contacting each other in the form of a bridge is decreased with the increase in the non-bonded B₄C phase, reducing the bending strength.

In addition, Matović *et al.*⁶⁴ reported that despite the highest relative density achieved for the ultra-high pressure sintered B_4C -SiC ceramics with the equal-weighted contributions of B_4C and SiC, the highest hardness is obtained for the B_4C -SiC ceramics with the highest B_4C content when the B_4C content ranges from 25 to 75 wt%.

Some previous studies on the effect of the ratio of B_4C to SiC on the mechanical properties of B_4C -SiC ceramics are tabulated in Table 7.

4.2.2. Residual phase. For B_4C -SiC ceramics produced by reaction-bonded sintering, there is some residual phase in the resulting ceramics, eventually in the presence of a C or Si excess. The addition of excessive C in the green body will lead to insufficient Si to completely react with C, forming residual C. In contrast, residual Si is formed when free C added is insufficient or Si is excessive. In the case of introducing free C, the

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Table 7 Effect of the ratio of B₄C to SiC on the mechanical properties of B₄C-SiC ceramics

			Sintering		Dolotino	IIonchuoII	Fracture		Young's
Ceramics	Raw material	Sintering method	(°C)	Sintering aid	density (%)	(GPa)	$(MPa m^{1/2})$	(MPa)	(GPa)
SiC ⁶⁸	α-SiC (0.6 μm)	Pressureless	2150	0.6 wt% B + 2 wt% carbon black	93.5	27.5	4.25	333	
SiC-5 vol% B ₄ C ⁶⁸	α -SiC (0.6 µm), B ₄ C (0.7–0.9 µm)	Pressureless	2150	1 wt% carbon black	96.0	30.2	4.19	422	
${ m B}_4{ m C}^{70}$	$B_4C (0.8 \ \mu m)$	Pressureless	2300	3 wt% carbon black	94.4	26.9	3.70	240	
$B_4C-20 \text{ wt\% SiC}^{70}$	(0.8 μm), α-SiC (0.4	Pressureless	2300	3 wt% carbon black	93.8	29.7	3.22	I	
$B_4C-40 \text{ wt\% SiC}^{70}$	B ₄ C (0.8 μm), α-SiC (0.4 μm)	Pressureless	2300	3 wt% carbon black	93.5	30.4	3.19	390	
$B_4C-60 \text{ wt}\% \text{ SiC}^{70}$	(0.8 μm), α-SiC (0.4	Pressureless	2300	3 wt% carbon black	95.6	33.1	3.33		
$B_4C-80 \text{ wt\% SiC}^{0}$	(0.8 μm), α-SiC (0.4	Pressureless	2300	3 wt% carbon black	96.5	29.2	3.13		
$B_4C-97 \text{ wt\% SiC}^{70}$	(0.8 μm), α-SiC (0.4	Pressureless	2300	3 wt% carbon black	0.06	28.3	3.18		
$B_4C-70 \text{ wt\% SiC}^{/2}$	(0.8 μm), α-SiC (0.5	Hot-press (40 MPa)	2000	No	100.0	30.3	3.60	590	
$B_4C-50 \text{ wt\% SiC}^2$		Hot-press (40 MPa)	2000	No	9.99	30.5	3.02	645	
$B_4C-30 \text{ wt\% SiC}^{/2}$		Hot-press (40 MPa)	2000	No	99.8	30.8	2.82	560	
$B_4C^{\prime 3}$		Hot-press (40 MPa)	1900	6 wt% $A_2O_3 + 4$ wt% Y_2O_3	98.2	38.7	6.44	394	
$B_4C-10 \text{ wt\% SiC}^{\prime 9}$			1900	6 wt% $A_2O_3 + 4$ wt% Y_2O_3	98.7	34.9	6.78	407	
B_4C-20 wt% SiC ⁷		Hot-press (40 MPa)	1900	6 wt% $Al_2O_3 + 4$ wt% Y_2O_3	99.0	32.6	7.21	448	
$B_4C^{\prime \circ}$	$B_4C (0.72 \ \mu m)$	Hot-press (30 MPa)	2200	No	9.9	28.9	3.90	620	
B_4C-10 vol% SiC ⁷⁸	$(0.72 \ \mu m), \beta-SiC$		2200	No	99.9	26.5	4.50	628	
B4C-15 VOI% SIC ⁷⁸	$(0.72 \ \mu m), \beta-SiC$	Hot-press (30 MPa)	2200	NO	9.99 00.0	25.9	4./1	6/4 740	
B4C-20 VOI% SIC	B4C (0.72 µm), p-SIC (0.3 µm)	HOT-Press (30 MPa)	2200	NO Mo	9.99	25.4	4.90	740	
D4C-30 V01% SIC	D4C (0.72 µIII), P-SIC (0.3 µIII) D C (0.72) B-SiC (0.2)	HOL-PLESS (30 MPa)	0022	NO	9.99	4.07 7 7 0	4.00	019 019	
Cic ¹⁵¹	0.12 µm), p-orc	Hot-press (50 MDa)	2100	No	0.55	4.04		070 65	
SiC-5 urt 06 B C ¹⁵¹	SiC $(0.11 \mu m)$ B C $(2.51 \mu m)$	Hot-press (50 MDa)	2100	No	0.77			115 115	
SiC-10 wt% D40		Hot-press (50 MDa)	2100	No	0.11			173	
SiC-15 wt% B.C ¹⁵¹		Hot-press (50 MPa)	2100	No	0.67			130	
B.C ¹¹²		Shark nlasma (75 MDa)	2100 1700 (×3 min)	No	00.0 100.0	30.3	3 50	000	
B.C.15 wt06 SiC ¹¹²		Spark plasma (75 MDa)	< S	No No	0.001	36.7	3.30 5 70		
B.C.5 volo6 SiC ⁹⁶		amend	о и < >	No	0.80	34.4	0/10		
B.C-10 volok SiC ⁹⁶		Spark plasma (40 MDa) Spark plasma (40 MDa)	С, к	No	0.00	33.1 32.1			
B.C-15 vol% SiC ⁹⁶		lasma	Ś	No	0.06 97.8	31.1 31.1			
SiC-10 wt% B.C ⁷¹	B.C. 2-SiC	of) amand (50	у и () У	1 5 Wt % C	90.6	26.1	2.80		415
$SiC-20$ wt% B, C^{71}		Shark plasma (50 MDa)	с С.Х	1 5 wt% C	00 2	28.8	0.79		409
SiC-20 wt% B40		lasma	с С	1 5 Wt % C	2.2C	20.0	67.2 7 T A		407
SiC-40 wr% B.C ⁷¹		plasma (50	с С	wt //	0.0 9 80	30.0	2./ 1 2.66		307
SiC_50 wt% B C^{71}) () ()	1 5 Wt% C	08.0	30.3	2.00		388
SiC ¹⁵²	a-c, ∝ sic α-SiC (44 µm - 3 µm), carbon black.	Reaction	1650 1650			15.4			2
				2					
$SiC-50 wt\% B_4 C^{152}$		Reaction	1650	No		30.0			
SiC^{153}	α-SiC (44 μm, 3 μm), carbon black,	Reaction	1650	No		15.0		108	
ato = 100 m 0153	Si powder (1 mm)	;		;					
SIC-2 WT% B4C	α-SIC (44 μm, 3 μm), B ₄ C (15 μm), carbon block Si nourder (1 mm)	keaction	1650	NO		c.81		129	1
SiC-10 wt% B_4C^{153}		Reaction	1650	No	I	20.9	I	143	
•									
SiC-20 wt% B_4C^{153}		Reaction	1650	No		24.4		200	
SiC-30 wt% B_4C^{153}		Reaction	1650	No		27.5		289	
SiC-20 wt% B_4C^{154}	siC-20 wt% B₄C ¹⁵⁴ B₄C (5 μm), SiC (11 μm), carbon black Reactio	Reaction	1600	No	6.66	31.0	3.60	458	I
	$(10 \ \mathrm{\mu m}), \mathrm{Si}$								
SiC-30 wt% B ₄ C ¹⁵⁴		Reaction	1600	No	8.66	32.0	3.80	475	

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Materials Advances

[able 7 (continued]

Ceramics	Raw material	Sintering method	Sintering temperature (°C)	Sintering aid	Relative Hardnee density (%) (GPa)	Hardness (GPa)	FractureBending Young'sHardnessstrength modulus(GPa)(MPa m ^{1/2})(GPa)(GPa)	Bending strength (MPa)	Bending Young's strength modulus (MPa) (GPa)
	B ₄ C (5 μm), SiC (11 μm), carbon black (10 μm). Si	y							
SiC-40 wt% B_4C^{15}	SiC-40 wt% B_4C^{154} $B_4C(5\mu)$, SiC (11 μ m), carbon black Reaction (10 μ m), Si	k Reaction	1600	No	99.7	32.5	3.10	400	
SiC-10 wt% B_4C^{11}	SiC-10 wt% B_4C^{116} B_4C (1.5 µm), α -SiC (7 µm), phenolic Reaction resin, carbon black, Si powder	Reaction	1750	No		28.4	4.15	423	
SiC-20 wt% B ₄ C ¹¹	SiC-20 wt% B_4C^{116} B_4C (1.5 µm), α -SiC (7 µm), phenolic Reaction resin, carbon black, Si powder	Reaction	1750	No	I	I	4.71	458	
SiC-30 wt% B ₄ C ¹¹	SiC-30 wt% B_4C^{116} B_4C (1.5 µm), α -SiC (7 µm), phenolic Reaction resin, carbon black, Si powder	Reaction	1750	No	I	30.2	5.07	487	
SiC-50 wt% B ₄ C ¹¹	SiC-50 wt% B_4C^{116} B_4C (1.5 µm), α -SiC (7 µm), phenolic Reaction resin, carbon black, Si powder	Reaction	1750	No	I	34.0	4.50	430	
SiC-70 wt% B ₄ C ¹¹	SiC-70 wt% B_4C^{116} B_4C (1.5 µm), α -SiC (7 µm), phenolic Reaction resin, carbon black, Si powder	Reaction	1750	No	Ι	35.5	3.85	394	I
B4C-75 wt% SiC ⁶⁴ B4C-50 wt% SiC ⁶⁴		Ultra-high pressure (4 GPa) 1500 (×1 min) Ultra-high pressure (4 GPa) 1500 (×1 min)	$1500 (\times 1 \text{ min})$ $1500 (\times 1 \text{ min})$	No No	96.4 98.0	23.1 27.0			
B_4C -25 wt% SiC ⁶⁴	B ₄ C (2.5 μm), β-SiC (0.6 μm)	Ultra-high pressure (4 GPa) 1500 $(\times 1 \text{ min})$	$1500 (\times 1 \min)$	No	96.9	31.2	I	I	Ι

presence of residual Si means the complete consumption of C initially added to the green body, and the quantity of infiltrated Si is enough to react with the introduced free C. The amount of Si introduced is related to the original porosity present in the preform before infiltration; thus, the amount of residual Si mainly depends on the amount of C and initial porosity of the preform.

The content and distribution of residual Si play an important role in the mechanical properties of B₄C-SiC ceramics. First, Si is a brittle phase with lower hardness (7 GPa) and strength than B₄C and SiC. Second, the thermal stress is developed by the thermal expansion coefficient mismatch between the matrix and Si at weak interfacial sites during cooling.¹⁵⁵ Third, the bonding strength of the interface in the ceramics is reduced due to the existence of residual Si, which does not help in improving the bending strength of B4C-SiC ceramics. Fourth, large-sized Si pools that are crack sources will be generated from residual Si, which can reduce the strength of B₄C-SiC ceramics. Havun et al.156 found that the mechanical properties of B4C-SiC ceramics depend on the amount of residual Si. The B₄C preforms without the addition of free C achieve 30 and 20 vol% porosity after pre-infiltration sintering at 2000 and 2100 °C, respectively. For the B₄C preform with 20 vol% porosity, the amount of residual Si in the resulting ceramics is 7 vol%. For the B₄C preform with 30 vol% porosity, the amount of residual Si in the resulting ceramics is 13 vol%. The B₄C-SiC ceramics with less residual Si amount has higher hardness and Young's modulus, which is attributed to the increased fraction of the ceramic phases within the ceramics. Chhillar et al.¹⁵⁷ reported that the hardness, bending strength, and Young's modulus of the B4C-SiC ceramics decrease with the increase in residual Si content, but its fracture toughness increases as the residual Si content increases. The decreased hardness and Young's modulus are attributed to the relatively low hardness and stiffness of residual Si, respectively; the decreased bending strength is caused by the larger critical flaw size in the ceramics with greater Si content; the increased fracture toughness results from ductile-like failure of the Si phase, and more tortuous fracture paths and more Si phase deformation occur in the ceramics with more Si content. Hayun et al.¹⁴⁸ pointed out that the amount of residual Si affects not only the static mechanical properties but also the dynamic mechanical properties. The stress at the Hugoniot elastic limit of the B4C-SiC ceramics monotonically reduces with the increasing amount of residual Si. In addition, as armor materials, the compressive strength of ceramics is also an important parameter. Patel et al.¹⁵⁸ reported that the reaction-bonded B₄C-SiC ceramics fail in a typical brittle failure under compressive load, and the compressive strength of the reaction-bonded B₄C-SiC ceramics increases with the increase in the strain rate, the trend of which is similar to that of hot-pressed B₄C ceramics. However, the compressive strength of the reaction-bonded B₄C-SiC ceramics (700 MPa) is lower than those of hot-pressed B₄C ceramics (3.52 GPa) and hot-pressed SiC ceramics (5.46 GPa),¹⁵⁹ which is attributed to 20 vol% residual Si. The weak residual Si interface between the B₄C grains is the main reason for the low compressive strength of the reaction-bonded B4C-SiC ceramics.

Besides the amount of residual Si, the size of residual Si also affects the mechanical properties of B₄C–SiC ceramics. When the Si region is small (<5 µm), the Si phase is under a state of residual compressive stress due to thermal mismatch between Si and the matrix during the cooling, which can improve the fracture toughness because of increased resistance to crack propagation in the Si phase.¹⁰⁰ In contrast, when the Si region is large (>5 µm) and irregularly shaped, the Si phase attains a state of tensile stress, promoting easy transgranular cracking with the Si region as the size of residual Si increases beyond a critical level.¹⁰⁰ Li *et al.*⁷⁶ reported that the hardness of B₄C–SiC ceramics increases with a decrease in residual Si size.

Although B₄C-SiC ceramics can be produced by reactionbonded sintering, due to the inhomogeneous structure and presence of abundant residual Si, the reliability and mechanical properties of products, especially at high temperatures, are inferior. For example, soft spots left by residual Si can detract from the overall ballistic efficiency of B₄C-SiC ceramics. The products lose the partial superior properties of B₄C-SiC ceramics. Therefore, it is meaningful to decrease the amount of residual Si in the reaction-bonded B₄C-SiC ceramics. Several approaches have been attempted, such as the use of a powder mixture with an appropriate multimodal particle size distribution to decrease the initial porosity of the green body (Section 3.2.1),^{76,84} infiltration of the partially sintered preform to increase the relative density of the preform,^{142,156} the addition of elements that react with Si to form stable silicides,¹⁶⁰ and addition of elements (Ti and Fe) or compounds (TiC) that react with B₄C and release an additional amount of free C.¹⁶¹⁻¹⁶³

As to the effect of residual C, Lin and Fang¹⁵⁴ reported that the residual C in the B₄C–SiC ceramics produced *via* the addition of free C can worsen the mechanical properties of B₄C–SiC ceramics even more seriously than residual Si. The mechanical properties of reaction-bonded B₄C–SiC ceramics first increase and then decrease with the increase in carbon black addition from 10 to 30 wt%.

In order to improve the mechanical properties of B_4C -SiC ceramics, the amount of residual phase needs to be reduced as much as possible. Some previous studies on the effect of the residual phase on the mechanical properties of reaction-bonded B_4C -SiC ceramics are tabulated in Table 8.

4.3. Raw material

As mentioned in Section 3.2, the characteristics of raw materials affect the sintering performance and microstructure of B_4C -SiC ceramics, which in turn can affect the mechanical properties of B_4C -SiC ceramics. The particle size and species of raw materials have a great influence on the mechanical properties of B_4C -SiC ceramics.

4.3.1. Particle size. For the B_4C -SiC ceramics produced by reaction-bonded sintering, the particle size of initial B₄C powders significantly affects the mechanical properties of B₄C-SiC ceramics.¹⁶⁴ Various findings have been put forward. Hayun et al.⁸⁴ reported that using B₄C powders with a suitable particle size distribution as raw materials can improve the relative density of the green body and reduce the amount of residual Si; thus, the mechanical properties of the obtained B₄C-SiC ceramics are increased. Dariel and Frage⁹⁹ mentioned that coarse B₄C grains are unfavorable for improving the bending strength of B4C-SiC ceramics, while the effect of initial size of the B₄C particles on fracture toughness is minor. Zhai et al.¹⁶⁵ found that the hardness, fracture toughness, and bending strength of B4C-SiC ceramics increase first and then decrease with the increase in particle size of B_4C (1, 2.5, 8, 15, 17, and 34 μ m). When the particle size of B₄C is 17 μ m, the mechanical properties of B₄C-SiC ceramics reach the maximum, which is attributed to the closed packing effect of the green body. Barick et al.¹⁶⁶ noted that the smaller the particle size of B₄C powders in the range of 18.7–63.4 μ m, the greater the fracture toughness and bending strength of B₄C-SiC ceramics will be. For the fracture toughness of reaction-bonded SiC ceramics, Chakrabarti et al.¹⁶⁷ stated that the number of grains for crack propagation that will pass through is dependent on the average grain size and intergranular Si thickness. Similarly, the ratio of grain size to Si thickness decreases with the increase in particle size of B₄C powders in the reaction-bonded B₄C-SiC ceramics, which indicates that the crack propagates a longer distance for the B₄C-SiC ceramics with smaller particle size. Furthermore, the interfacial debonding mechanism dominates over transgranular fracture as the grain size decreases, and the debonding at B₄C-Si and SiC-Si interfaces can further improve fracture toughness for B₄C-SiC ceramics as compared to transgranular fracture. Therefore, the B₄C-SiC ceramics produced from the

Ceramics	Raw material	Sintering temperature (°C)	Relative density (%)		Content of residual phase		Fracture toughness (MPa m ^{1/2})		0
B4C-13 vol% SiC156	B ₄ C, Si	1480	_	Si	7 vol%	22.5	5.5	390	410
B ₄ C-17 vol% SiC ¹⁵⁶	B ₄ C, Si	1480	_	Si	13 vol%	20.3	7.9	415	370
B_4C-SiC^{157}	B ₄ C, resin, Si	_	_	Si	5 vol%	19.5	4.4	324	432
B_4C-SiC^{157}	B ₄ C, resin, Si			Si	10 vol%	16.7	4.8	280	406
B ₄ C-SiC ¹⁵⁷	B ₄ C, resin, Si	_	_	Si	14 vol%	15.3	5.0	276	380
B_4 C-70 wt% SiC ¹⁵⁴	B ₄ C (5 μm), SiC (11 μm), 10 wt% carbon black (10 μm), Si	1600	99.9	Si	_	30.0	3.4	415	—
B ₄ C-60 wt% SiC ¹⁵⁴		1600	99.9	Si	_	31.0	3.6	458	_
B ₄ C-50 wt% SiC ¹⁵⁴	B_4C (5 µm), SiC (11 µm), 30 wt% carbon black (10 µm), Si	1600	99.8	С	_	28.5	2.1	370	_

B₄C powders with smaller particle sizes exhibit higher fracture toughness. As to bending strength, residual thermal stress formed due to thermal expansion mismatch between the matrix and Si during cooling can generate flaws or cracks in weak interfacial zones. On the one hand, the probability of the formation of flaws with larger sizes is higher for the B₄C-SiC ceramics with larger grain size owing to the larger scale of the interfacial area between B₄C and Si grains; on the other hand, these flaws can propagate maximum up to one-grain size. Thereby, the B₄C-SiC ceramics with a larger grain size have flaws with a larger size. According to the Griffith equation:

$$\sigma_{\rm f} = (2\gamma Y / \Pi C)^{1/2} \tag{9}$$

where $\sigma_{\rm f}$ is the bending strength (MPa), γ is the fracture surface energy (J m⁻²), Y is Young's modulus (GPa), and C is half of the crack length (μm) ;¹⁶⁸ the larger the flaw size, the lower the bending strength is. As a result, the B₄C-SiC ceramics produced from B₄C powders with larger particle sizes show lower bending strength. However, the hardness of B₄C-SiC ceramics decreases with the decrease in particle size of B₄C powders. This is because the reaction-bonded B₄C-SiC ceramics with fine particle size have a larger interface boundary area, which is a weak zone. The larger the interface boundary area, the larger the volume fraction of the weak interfacial zone is. Therefore, the B₄C-SiC ceramics produced from B₄C powders with a smaller particle size exhibit lower hardness.¹⁶⁶ Furthermore, the smaller size of B₄C grains is beneficial for increasing the compressive strength of the reaction-bonded B₄C-SiC ceramics.¹⁴⁸ Based on these findings, adjusting the size of raw materials is one of the effective means to control the mechanical properties of B₄C-SiC ceramics.

Some previous studies on the effect of particle size of raw materials on the mechanical properties of reaction-bonded B₄C-SiC ceramics are tabulated in Table 9.

4.3.2. Species. As mentioned in Section 3.2.3, the species of raw materials control the microstructure of the obtained B₄C-SiC ceramics, which in turn gives rise to different mechanical properties of B₄C-SiC ceramics.

When β -SiC is used as the raw material, the microstructure of the resulting B₄C-SiC ceramics is different from that of B₄C-SiC ceramics prepared using α -SiC as the raw material; due to the partial transformation of $\beta \rightarrow \alpha$ -SiC during sintering, platelet-shaped SiC grains are formed. Excessive plateletshaped SiC grains in B₄C-SiC ceramics are not favorable for improving the densification of the ceramics; however, these platelet-shaped SiC grains can act as a factor for enhancing the fracture toughness of B4C-SiC ceramics, which plays an equally important role in obtaining lightweight ballistic material.

In addition to directly mixing commercial B₄C and SiC raw powders to fabricate B4C-SiC ceramics, other raw materials can also be used to prepare B₄C-SiC ceramics.

PCS is widely used as the precursor of SiC. The generation of fine SiC grains from PCS can reduce the size and density of structural defects that deteriorate the mechanical properties of B₄C-SiC ceramics by filling the pores and voids. Also, these fine SiC grains affect the crack propagation; when a crack

on income of the second s		Particle size of	Relative density green b	intering emperature	Rela dens	Hardness	Tracture oughness	Bending strength	Young's modulus
Ceramics		ليتنبا كهط	(%)	c)	(0%)	(Dra)	MPa III)	(MFa)	Uraj
B ₄ C–SiC ⁸⁴ B ₄ C, Si	B₄C, Si	66 vol%130.0 + 74.2	74.2	1450	6.99	22.6		318	400
		15 vol%13.0 +							
		19 vol%1.0							
B_4C-SiC^{165}	B_4C-SiC^{165} B_4C , α -SiC (9 µm), carbon black (0.56 µm), phenolic resin, Si powder (50 µm)	1.0	Ι	1560		18.6	3.03	274	I
B4C-SiC ¹⁶⁵	B₄C, α-SiC (9 μm), carbon black (0.56 μm), phenolic resin, Si powder (50 μm)	2.5		1560		18.9	3.56	289	I
B_4C-SiC^{165}	B_4C , α -SiC (9 µm), carbon black (0.56 µm), phenolic resin, Si powder (50 µm)	8.0	Ι	1560		21.5	3.84	319	I
B_4C-SiC^{165}	B_4C , α -SiC (9 μ m), carbon black (0.56 μ m), phenolic resin, Si powder (50 μ m)	15.0		1560		24.6	4.20	346	I
B_4C-SiC^{165}	B₄C, α-SiC (9 μm), carbon black (0.56 μm), phenolic resin, Si powder (50 μm)	17.0		1560		28.2	4.49	376	I
B ₄ C–SiC ¹⁶⁵	B₄C, α-SiC (9 μm), carbon black (0.56 μm), phenolic resin, Si powder (50 μm)	34.0		1560		24.3	3.89	340	I
B ₄ C-SiC ¹⁶⁶	B ₄ C, phenolic resin, carbon black	18.7	55.9	1550		12.4	5.76	403	1
B_4C-SiC^{166}	B4C, phenolic resin, carbon black	33.7	58.9	1550		13.6	5.00	359	I
B_4C-SiC^{166}	B4C, phenolic resin, carbon black	63.4	62.7	1550		16.4	3.40	265	1

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encounters these fine SiC grains, either it has to break them or bypass them to continue the propagation, both of which consume the crack propagation energy. On the other hand, the thermal decomposition of PCS yields not only SiC but also free C. The C impurity has an effect on the hardness, strength, and oxidation resistance of B₄C-SiC ceramics. Therefore, different from the direct use of SiC powders, the use of PCS will have a certain impact on the mechanical properties of B₄C-SiC ceramics. Du et al.91 used B4C and PCS as raw materials to prepare B₄C-SiC ceramics by hot-press sintering. The hardness and fracture toughness of B₄C-15 wt% SiC ceramics are higher than those of pure B₄C ceramics. The improvement in hardness is attributed to the reduction of residual porosity in B₄C-SiC ceramics. The enhancement of fracture toughness is ascribed to two aspects. First, the layered structure and dislocation defects are generated in SiC grains (Fig. 3). Dislocation has a passivated effect on the crack tip. When cracks propagate to the dislocation zone, dislocation can absorb partial crack propagation energy by self-deformation and pin the crack, which is similar to microcrack toughening. Thereby, the layered structure and dislocation can consume much crack propagation energy, forming effective barriers for crack propagation. Second, SiC grains formed from the pyrolysis of PCS have a particle size in the range of nanometers to micrometers. Although transgranular fracture is still the main fracture mode of B4C-SiC ceramics, SiC grains of micron size cause crack bridging and nano-sized SiC grains within B4C grains induce crack deflection, both of which increase the fracture toughness of B4C-SiC ceramics. Crack deflection is related to the tensile residual stress field induced by nano or quasi-nano SiC grains in the B₄C matrix. B₄C and SiC have similar thermal expansion coefficients; however, the thermal expansion properties of SiC may be changed greatly because of the nanometer size effect as SiC grain size reduces to nanoscale or quasi-nanoscale. As a result, a thermal residual stress field around nano or quasi-nano SiC grains is induced by the mismatch in the thermal expansion coefficients between the B4C matrix and SiC grains during cooling. Hwang et al.87 also observed the layered microstructure (or planar defects) and/or subgrains in the PCS pyrolyzed SiC grains. This microstructure can further improve the fracture toughness of the spark plasma sintered B₄C-SiC ceramics because cracks frequently deflect within SiC grains generated from PCS pyrolysis (Fig. 12a), which results from either the grain boundary between subgrains or the layered structure of grains (Fig. 12b). As a result, the toughening mechanism of SiC grains generated from PCS pyrolysis for the B4C-SiC ceramics is a combination of crack deflection within SiC grains and crack impeding by SiC grains. It is noteworthy that the fracture toughness (indentation K_{IC}) of spark plasma sintered B_4C -SiC ceramics (2.7 MPa m^{1/2}) prepared from the pyrolysis of PCS is lower than the fracture toughness reported for the spark plasma sintered B_4C -SiC ceramics (5.7 MPa m^{1/2}) produced from SiC powders (Table 7), which is attributed to the residual C from the conversion of PCS to SiC, the difference in grain size, or other unknown factors; however, it is not recommended to compare the values of fracture toughness between different ceramic systems due to the complex crack tip arrest environment.169 Furthermore, the hardness of spark plasma

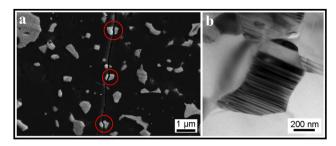


Fig. 12 (a) Cracks in spark plasma sintered B_4C -SiC ceramics whose SiC is generated from PCS pyrolysis showing frequent deflection and (b) SiC grain generated from PCS pyrolysis in the B_4C -SiC ceramics showing a layered structure (or planar defects)⁸⁷ (reprinted with permission, Copyright 2018, Elsevier).

sintered B₄C-SiC ceramics decreases with the increased content of SiC formed by PCS pyrolysis. Besides the rule of mixtures that the hardness of SiC is lower than that of B₄C, the amount of residual C generated accompanied by the pyrolysis of PCS to form SiC also gradually increases, which can also lead to the reduction of hardness. Meanwhile, the hardness of spark plasma sintered B_4C -SiC ceramics (~29 GPa) prepared from the pyrolysis of PCS is lower than the hardness reported for the spark plasma sintered B₄C-SiC ceramics (31-36 GPa) produced from SiC powders (Table 7), resulting from the residual C accompanied by the PCS conversion to SiC. The introduction of an appropriate amount of Si can convert residual C into SiC, thus increasing the hardness of B₄C–SiC ceramics.⁹¹ In addition, Zhou *et al.*¹⁷⁰ utilized PCS as a SiC precursor to prepare reaction-bonded B4C-SiC ceramics from the green body composed of graded B4C powders and PCS. Compared with the reaction-bonded B₄C-SiC ceramics produced from the green body composed of B₄C without the addition of PCS, the reaction-bonded B4C-SiC ceramics prepared from the green body composed of B4C with the addition of 5-10 wt% PCS exhibit higher bending strength, which is attributed to their lower porosity. The formed β-SiC and C particles by PCS pyrolysis can segment the large pores in the preform, decreasing the median pore diameter, which can increase the capillary force and is beneficial for the infiltration process. However, the excessive addition of PCS will reduce the bending strength of reaction-bonded B4C-SiC ceramics because Si accumulation areas are generated in the ceramics, leading to the formation of residual stress in weak interfacial zones and flaws with large sizes. The layered structure of SiC derived from PCS pyrolysis is also observed in the reaction-bonded B₄C-SiC ceramics.¹¹⁷

Moreover, SiC can be formed *in situ* through some chemical reactions of two raw materials, which can cause a different effect on the mechanical properties of B_4C –SiC ceramics. Zhang *et al.*^{94,95} used B_4C , Si, and amorphous carbon powders to produce B_4C –SiC ceramics *via* high-energy ball milling by hotpress sintering or spark plasma sintering. It was found that the hardness and fracture toughness of the obtained B_4C –SiC ceramics are higher than those of B_4C –SiC ceramics produced from B_4C and PCS as raw materials⁹¹ or produced directly from B_4C and SiC powders *via* high-energy ball milling.⁹⁸ For the B_4C –SiC ceramics made from B_4C , Si, and amorphous carbon

via hot-press sintering, a number of nano-sized SiC and B₄C grains (100–200 nm) exist within the B_4C grains (1–3 μ m). During high-energy ball milling, some smaller SiC and B₄C particles are embedded into the larger B₄C particles. Thereby, these smaller SiC and B₄C particles are trapped into the larger B_4C particles during sintering because of the fast diffusion speed, which is attributed to the disordered structure of B₄C-SiC composite powders formed during high-energy ball milling. This intragranular structure, which can generate intracrystalline boundaries and stress, is helpful in improving the mechanical properties of B₄C–SiC ceramics, especially the fracture toughness. The transgranular fracture is still the main fracture mode; however, when cracks cross the B₄C grains and reach intragranular particles within B₄C grains, the cracks are deflected along the intracrystalline boundary, rather than crossing the intragranular particles, which is ascribed to the small-size and highstrength intragranular crystals that can consume crack extension energy. Therefore, the intragranular grains (including B4C and SiC grains) induce crack deflection; the intragranular structure changes the fracture mode from the single transgranular fracture to a combination of transgranular fracture and intergranular fracture, improving the fracture toughness of B₄C-SiC ceramics. Furthermore, the hardness and fracture toughness of B₄C-SiC ceramics produced from B₄C, Si, and amorphous carbon powders via spark plasma sintering are slightly higher than those of B₄C-SiC ceramics produced from the same raw materials via hot-press sintering, which is attributed to the smaller grain size resulting from the lower sintering temperature and shorter holding time as well as to the sufficient utilization of high sintering activity of B₄C and SiC composite powders produced via high-energy ball milling resulting from the fast heating rate by the spark plasma sintering, which can lead to the production of abundant energy from the disorder-order transformation of SiC and B4C to induce densification. Wei *et al.*^{171,172} used Si powders ($D_{50} = 1 \mu m$) and B_4C containing free C (0.9%) powders ($D_{50} = 1.5 \mu m$) as raw materials to produce B4C-SiC ceramics. At high temperatures, free C can react with Si, synthesizing SiC in situ. Only B4C and SiC phases are detected in the resulting B₄C-SiC ceramics, which indicates that no free Si exists in the ceramics after adding different contents of Si powders (4-12 wt%). The residual Si after reaction with free C is fully solid soluted into the B₄C lattice, resulting in increased lattice parameters of B₄C. The Si powders can melt above 1400 °C; thus the existence of a liquid phase promotes the sintering and improves the densification, reducing the number and size of pores acting as the origin of fracture. Therefore, the bending strength of B₄C–SiC ceramics is higher than that of pure B₄C ceramics without adding Si powders. The formation of SiC in B₄C ceramics, on the one hand, is beneficial for increasing the relative density of the ceramics, and on the other hand, changes the fracture mode of the ceramics from transgranular fracture to a combination of transgranular fracture and intergranular fracture, resulting in the increased fracture toughness compared to pure B4C ceramics. However, the addition of excessive Si powders (12 wt%) will cause a certain degree of decrease in the strength and toughness of B₄C-SiC ceramics because the excessive SiC particles formed in situ aggregate,

leading to a much bigger grain size. Sahin *et al.*⁹⁶ used B_4C , SiO_2 , and carbon black as raw materials to produce B_4C -SiC ceramics *via* spark plasma sintering according to reaction (1). The formation of SiC using SiO_2 and carbon black as raw materials is accompanied by the generation of gas; thus, the hardness of the resulting B_4C -SiC ceramics decreases with the increase in *in situ* formed SiC content from 5 to 20 vol%, which is attributed to the gradually decreased relative density.

SiC whiskers (SiC_w) with high strength and high elastic modulus are considered to be an excellent toughening phase; different researchers studied the effect of SiC addition in the form of whiskers (SiCw) on the mechanical properties of B₄C-SiC ceramics. To improve the mechanical properties of reaction-bonded B₄C-SiC ceramics, Wang et al.¹⁷³ added SiC in the form of a whisker into the green body composed of B₄C and C. The stacking density of the mixed powders in the preform decreases with the increase in SiC_w addition from 0 to 24 wt%, resulting in the gradually decreased relative density of the preform. The fracture roughness of the reaction-bonded B4C-SiC ceramics increases with the increase in SiCw content from 0 to 24 wt%; the main toughening mechanism is the pulling out of SiC_w from the matrix, which is an energy-consuming process. However, the hardness and bending strength of the reaction-bonded B4C-SiC ceramics decrease with the increase in SiCw content from 0 to 24 wt%. The reduced hardness is attributed to the decreased proportion of B₄C in the ceramics; the decreased bending strength is ascribed to the dissolution of SiC_w and transformation to SiC particles during molten Si infiltration, the formation of microcracks within the ceramics resulting from the mismatch of thermal expansion coefficients between B₄C and SiC_w, and the weakening of interface bonding strength between B₄C and SiC_w due to the increased defects such as the porosity and the non-uniformity distribution of SiC_w. Tamari et al.174 studied the effect of SiC whisker content in the range of 10 to 30 vol% on the mechanical properties of hot-press sintered B4C-SiCw ceramics. There was no pulling-out of the SiC whiskers and no crack deflection during fracture, which is opposite to what Wang et al.¹⁷³ found; thus, the fracture toughness of B₄C–SiC_w ceramics increases slightly with the increase in SiC whisker content. In contrast, the bending strength of B₄C-SiCw ceramics decreases with the increase in SiC whisker content. The hardness and elastic modulus are independent of SiC whisker content.

Some previous studies on the effect of species of raw material on the mechanical properties of B_4C -SiC ceramics are tabulated in Table 10.

4.3.3. Use of C/SiC in the reaction-bonded B₄C–SiC ceramics. The addition of free C in the preform will help control the morphology of SiC grains formed (Section 3.5.2.2) and SiC phase volume fraction, which in turn will affect the mechanical properties of reaction-bonded B₄C–SiC ceramics. Furthermore, the use of C can affect the sintering performance and microstructure of reaction-bonded B₄C–SiC ceramics; thus, the mechanical properties of B₄C–SiC ceramics can be enhanced by adjusting the initial free C content. Gao *et al.*,¹⁴⁴ Zhang *et al.*,⁷⁵ and Lin *et al.*¹⁷⁵ reported that the addition of 5–10 vol% carbon powders, 8–10 wt%

 Table 10
 Effect of species of raw material on the mechanical properties of B₄C-SiC ceramics

B4C(B4C(B4C(B4C(B4C(B4C(B4C(B4C(n), Si powder n), 5 wt% PCS, Si powder n), 10 wt% PCS, Si powder n), 15 wt% PCS, Si powder	Hot-press (30 MPa) Hot-press (30 MPa) Hot-press (30 MPa) Spark plasma (50 MPa) Spark plasma (50 MPa) Spark plasma (50 MPa)			(n/)	(ura)	$(MPa m^{1/2})$	(MFa)	(MPa) (GPa)
			0661	No	91.7	24.1	3.34		
			1950	No	96.1	26.6	4.98		I
			1950	8 wt% Si	99.1	33.5	5.57		I
SiC ⁸⁷ SiC ⁸⁷ SiC ⁹⁴ SiC ⁹⁴			1900 (×5 min)	No		29.7	2.00	-	409
SiC ⁹⁴ SiC ⁹⁴ SiC ⁹⁵		spark plasma (50 MPa)	$1900 (\times 5 \text{ min})$	No	99.7	29.1	2.36	1	416
SiC ⁹⁴ SiC ⁹⁴ SiC ⁹⁵			$1900 (\times 5 min)$	No	99.5	28.5	2.68	1	408
SiC ⁹⁴ SiC ⁹⁴ SiC ⁹⁵		Reaction	1500	No	99.1	15.1	4.26	260	348
SiC ⁹⁴ SiC ⁹⁴ SiC ⁹⁵		Reaction	1500	No	99.8	17.3	4.35	319 4	402
51C ⁹⁴ 51C ⁹⁴ 51C ⁹⁵		Reaction	1500	No	90.8	17.2		281	393
SiC ⁹⁴ SiC ⁹⁵		Reaction	1500	No	9.66	16.9		242	403
	(un	Hot-press (30 MPa)	1900	No	97.2	30.1	6.10		I
	(un	Hot-press (30 MPa)	1950	No	98.6	34.3	6.00		I
	μm)	Spark plasma (30 MPa)	$1700 (\times 5 min)$	No	96.7	28.8	5.75		I
	(uni	Spark plasma (30 MPa)	$1750 (\times 5 \text{ min})$	No	98.3	33.4	6.50		I
	hm)	Spark plasma (30 MPa)	$1800 (\times 5 min)$	No	99.2	35.8	6.80		I
wt% SiC ⁹⁸		Hot-press (30 MPa)	006	No	96.4	24.0	4.60	430 -	1
B_4C^{171} $B_4C(1 \ \mu m)$		Hot-press (60 MPa)	1850	No			4.25	175 -	1
B_4C-SiC^{171} $B_4C(1 \ \mu m)$, Si (1.5 μ		Hot-press (60 MPa)	1850	4 wt% Si			4.37	283 -	1
B_4C-SiC^{171} $B_4C(1 \ \mu m)$, Si (1.5 μ		Hot-press (60 MPa)	1850	8 wt% Si			5.04	354 -	I
B_4C-SiC^{171} $B_4C(1 \mu m)$, Si (1.5 μm)		Hot-press (60 MPa)	1850	12 wt% Si			4.76	302 -	I
$B_4C-5 \text{ vol}\% \text{ SiC}^{96}$ $B_4C, \text{ SiO}_2 (1 \ \mu\text{m}), \text{ car}$		Spark plasma (40 MPa)	$1750 (\times 5 min)$	No	97.7	35.0			1
$B_4C-10 \text{ vol}\% \text{ SiC}^{96} B_4C, \text{ SiO}_2 (1 \ \mu\text{m}), \text{ car}$		Spark plasma (40 MPa)		No	93.8	34.5			1
$B_4C-15 \text{ vol}\% \text{ SiC}^{96}_{-2} B_4C, \text{SiO}_2 (1 \ \mu m), \text{ car}$		Spark plasma (40 MPa)	$(750 (\times 5 min))$	No	91.2	33.1			1
$B_4C-20 \text{ vol}\% \text{ SiC}^{96} B_4C, \text{ SiO}_2 (1 \ \mu\text{m}), \text{ car}$		Spark plasma (40 MPa)	$1750 (\times 5 min)$	No	88.3	32.1			1
B_4C-SiC^{173} B_4C (125 µm: 12.8 µr		Reaction	1500	No		31.2	4.49	322 -	I
B_4C-SiC^{173} B_4C (125 µm: 12.8 µr	1% SiC whisker, Si	Reaction	1500	No		31.0	4.64	285 -	I
B_4C-SiC^{173} B_4C (125 µm: 12.8 µr	ol% SiC whisker, Si	Reaction	1500	No	Ι	30.4	4.67	265 -	I
B_4C-SiC^{173} B_4C (125 µm: 12.8 µI	ol% SiC whisker, Si	Reaction	1500	No		28.9	4.73	254 -	I
B_4C-SiC^{173} B_4C (125 µm: 12.8 µr	ol% SiC whisker, Si	Reaction	1500	No		27.6	4.88	243 -	I
B_4C-SiC^{174} B_4C (0.24 µm), 10 vol ⁹	μm , length = 45 μm)	Hot-press (30 MPa)	2100	No	> 99%	30.0	3.89	877	439
	1.1 μ m, length = 45 μ m)	Hot-press (30 MPa)	2100	No	> 99%	31.1	3.89	812 4	429
	B_4C (0.24 µm), 30 vol% SiC whisker (diameter = 1.1 µm, length = 45 µm) F	Hot-press (30 MPa)	2100	No	%66 <	30.0	4.23	260	426

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nano-carbon black, or microporous carbon can improve the mechanical properties of reaction-bonded B4C-SiC ceramics, respectively. The addition of C can promote the sintering of B₄C-SiC ceramics; therefore, the increase in hardness and bending strength is attributed to the decrease in porosity of B₄C-SiC ceramics and a more uniform microstructure. The fracture mode of B₄C-SiC ceramics changes from a combination of intergranular and transgranular fracture to transgranular fracture only with the increase in C content from 0 to 10 vol%. However, excessive C (>10 vol% or >10 wt%) will lead to a decrease in mechanical properties for B₄C-SiC ceramics. The excessive C leads to the formation of larger-sized individual particles resulting from the aggregation of SiC and the formation of holes, which is attributed to the blockage of the channels from Si infiltration caused by the aggregation of SiC. Both the increase in grain size and the formation of holes deteriorate the mechanical properties of B4C-SiC ceramics. Different from the research results mentioned above, Lee et al.¹⁵² found that the hardness of SiC-30 wt% B₄C ceramics increases linearly with the increase in carbon black from 10 to 40 wt%. The increase in C content can increase the reactivity with Si, reducing the residual Si content in the final B₄C-SiC ceramics. Zhang et al.¹⁰¹ introduced C in the form of a C layer deposited on B₄C particles into the preform. The mechanical properties of B₄C-SiC ceramics prepared from the C-coated B₄C particles are higher than those prepared from the mixture of uncoated B₄C and nano-carbon black. The C layer on B₄C particles can prevent the dissolution and reaction of B4C grains in molten Si effectively; thus, the better mechanical properties of B₄C-SiC ceramics prepared from the C-coated B4C particles are attributed to the higher relative density, higher B4C content, the smaller grain size of B₄C, and the formation of many nano-SiC grains as well as a continuous ceramic skeleton of the nano-SiC grains-coated and -bonded B₄C grains, as mentioned in Section 3.5.2.3.

Furthermore, C can also be introduced in the form of fibers. On the one hand, carbon fibers can be used as a C source, and on the other hand, carbon fibers can also be used as a toughening phase. B₄C-SiC ceramics exhibit isotropic mechanical properties due to the homogeneous dispersion of the chopped carbon fibers. The main toughening mechanisms of carbon fibers in B₄C-SiC ceramics are considered to be fiber pullout and fiber debonding. Carbon fibers not only provide sufficient C for forming a ceramic skeleton structure but also control the distribution of residual Si. Song et al.⁸⁵ noted that the fracture toughness and bending strength of B₄C-SiC ceramics increase with an increase in carbon fibers content from 0 to 40 vol%. Carbon fibers can completely react with molten Si during Si infiltration, and there are no carbon fibers in the final B4C-SiC ceramics. The residual Si content is decreased with the increase in carbon fibers content; also, the residual Si particles occupy the original positions of carbon fibers, forming fiberlike extensions, which is beneficial for lowering the defect sensitivity of the residual Si and controlling the size of the formed Si islands. However, the addition of an excess of carbon fibers (50 vol%) will generate too many β -SiC particles, causing a relatively high volume expansion, leading to the blockage of Si capillary channels and the formation of residual carbon fibers;

thus, the mechanical properties are reduced. It is worth noting that if carbon fibers are only used as a C source, it is unnecessary to take measures to protect the carbon fibers. In contrast, if carbon fibers are used as a toughening material, the structure and mechanical properties of carbon fibers are inevitably degraded due to the interfacial reaction during the infiltration; adding carbon black in the preform can protect the carbon fibers from erosion to some extent since the molten Si will preferentially react with the carbon black due to its higher specific surface area.¹⁷⁶

Moreover, the addition of SiC in the preform can form the core–rim structure of primary α -SiC surrounded by a secondary β -SiC rim (Section 3.5.2.1). Song *et al.*⁶⁰ mentioned that the mechanical properties of B₄C–SiC ceramics produced from the preform with the addition of SiC are higher than those of B₄C–SiC ceramics produced from the preform without the addition of SiC. This is because the formed SiC cannot nucleate and grow on the B₄C particles in the preform without the addition of SiC; thus, SiC formed and B₄C particles are distributed independently; a continuous ceramic skeleton is not formed. In contrast, in the preform with the addition of SiC, SiC formed can connect the original SiC particles to form a continuous ceramic skeleton, improving the mechanical properties.

Although better mechanical properties of reaction-bonded B_4C -SiC ceramics are achieved by generating the plate-like shaped SiC grains without adding free C in the preform, the addition of free C can improve the mechanical properties of B_4C -SiC ceramics by promoting the sintering performance and enhancing the microstructure. Therefore, the effect of free C on the mechanical properties of reaction-bonded B_4C -SiC ceramics is a competitive factor, which depends on the amount, form, *etc.* Some previous studies on the effect of C/SiC added in the preform on the mechanical properties of reaction-bonded B_4C -SiC ceramics are tabulated in Table 11.

4.4. Preparation process

In addition to optimizing raw material formulations, some efforts have been devoted to studying how to improve the mechanical properties of B_4C -SiC ceramics by adjusting process parameters. The preparation process affects the mechanical properties of B_4C -SiC ceramics mainly by changing the microstructure.

4.4.1. Preparation of the green body. Pores in the green body affect the mechanical properties of the obtained B_4C -SiC ceramics. Compaction pressure can control the porosity and pore size of the green body. Meanwhile, adjusting the porosity and pore size of the green body can help control the content and size of residual Si in the reaction-bonded B_4C -SiC ceramics. Zong *et al.*¹⁷⁷ investigated the effect of forming pressure on the mechanical properties of reaction-bonded B_4C -SiC ceramics. With the increase in forming pressure from 50 to 200 MPa, the porosity of the green body decreases, leading to the decreased porosity of the obtained reaction-bonded B_4C -SiC ceramics and the decreased content of free Si filled in the remaining pores, both of which are beneficial for improving the mechanical properties of B_4C -SiC ceramics. However, when the forming pressure exceeds 200 MPa, the pores in the

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Table 11 Effect of C/SiC added in the preform on the mechanical properties of reaction-bonded B₄C-SiC ceramics

Ceramics	Raw material	Amount of C/SiC added	Sintering temperature Residual (°C) Si conter	It	Relative density (%)	Hardness (GPa)	FractureBendiHardnesstoughnessstreng(GPa)(MPa m^{1/2})(MPa)	Bending Young's strength modulus (MPa) (GPa)	Young's modulus (GPa)
	8₄C (5 μm), Si	0 vol% C	1650	Ι	99.7	17.1	2.70	268	
	B₄C (5 μm), carbon black, Si	5 vol% C	1650		9.66	18.9	3.96	305	
	B₄C (5 μm), carbon black, Si	10 vol% C	1650		99.8	19.6	3.83	358	
	B₄C (5 μm), carbon black, Si	20 vol% C	1650		99.2	15.3	3.10	226	
	$B_{4}C$ (4.08 µm), Si	0 wt% C	1550	1	9.90	19.2	3.65	267	
	B_4C (4.08 µm), carbon black, Si	6 wt% C	1550		9.99	21.3	4.30	318	
	B_4C (4.08 µm), carbon black, Si	8 wt% C	1550	1	99.4	24.0	4.74	336	
	B_4C (4.08 µm), carbon black, Si	10 wt% C	1550		99.1	24.4	4.41	361	
	B_4C (4.08 µm), carbon black, Si	12 wt% C	1550		98.7	19.0	4.20	275	
B_4C-SiC^{175} I	B₄C, microporous carbon, Si powder (200 mesh)		1600		98.4	22.6	4.74	286	332
SiC-30 wt% B_4C^{152} (x-SiC (77 μ m: 3 μ m = 7: 3), B_4C (15 μ m), carbon black, Si powder (1 mm)	10 wt% C	1650			25.0		Ι	
SiC-30 wt% B_4C^{152} (SiC-30 wt% B ₄ C ¹⁵² &SiC (77 μm: 3 μm = 7:3), B ₄ C (15 μm), carbon black, Si powder (1 mm)	20 wt% C	1650			27.6		Ι	
SiC-30 wt% B_4C^{152} (SiC-30 wt% B ₄ C ¹⁵² α-SiC (77 μm:3 μm = 7:3), B ₄ C (15 μm), carbon black, Si powder (1 mm)	30 wt% C	1650			34.5		1	
SiC-30 wt% B ₄ C ¹⁵² (x-SiC (77 μ m: 3 μ m = 7: 3), B ₄ C (15 μ m), carbon black, Si powder (1 mm)	40 wt% C	1650			37.3		I	
B_4C-SiC^{101}	C-coated B_4C particles prepared via the pyrolysis and carbonization	10 wt% C	1600		9.9	24.0	4.80	316	
	of phenolic resin, Si lump (5–10 mm)								
	B_4C (2.14 µm), carbon black (22 nm), Si lump (5–10 mm)	10 wt% C	1600		99.7	19.0	3.50	457	
	x -SiC (14 µm), B_4C (1.5 µm), Si	0 wt% C	1600	39.0 wt%	I		2.83	291	
	x-SiC (14 μ m), B ₄ C (1.5 μ m), carbon fibers (diameter = 6 μ m, length = 3 mm), Si	10 wt% C	1600	28.6 wt%	Ι		3.24	320	
	x-SiC (14 μ m), B ₄ C (1.5 μ m), carbon fibers (diameter = 6 μ m, length = 3 mm), Si	20 wt% C	1600	19.9 wt%	I		4.50	375	
	x-SiC (14 μ m), B ₄ C (1.5 μ m), carbon fibers (diameter = 6 μ m, length = 3 mm), Si	30 wt% C	1600	14.2 wt%	I		6.58	414	
	x-SiC (14 µm), B_4C (1.5 µm), carbon fibers (diameter = 6 µm, length = 3 mm), Si	40 wt% C	1600	7.1 wt%	Ι		7.50	465	
B_4C^{85}	α -SiC (14 µm), B ₄ C (1.5 µm), carbon fibers (diameter = 6 µm, length = 3 mm), Si	50 wt% C	1600	5.3 wt%				262	
	B_4C (14 µm), phenolic resin, Si	0 wt% SiC	1600					332	
	B_4C (14 µm), $\ddot{\alpha}$ -SiC (14 µm), carbon black, phenolic resin, Si	68 wt% SiC	1600	15.6 vol%			4.06	325	
_	B_4C (14 µm), α -SiC (14 µm), carbon black, phenolic resin, Si	58 wt% SiC	1600	14.8 vol%	Ι		4.35	357	
	B_4C (14 µm), α -SiC (14 µm), carbon black, phenolic resin, Si	48 wt% SiC	1600	13.2 vol%		I	4.58	407	
	B_4C (14 µm), α -SiC (14 µm), carbon black, phenolic resin, Si	38 wt% SiC	1600	13.7 vol%			4.80	379	
	B_4C (14 µm), α -SiC (14 µm), carbon black, phenolic resin, Si	28 wt% SiC	1600	14.9 vol%	Ι	Ι	5.12	367	Ι

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green body become too narrow to be penetrated by molten Si because of the occupation of the newly formed SiC particles, increasing the porosity of the obtained reaction-bonded B_4C -SiC ceramics, thus decreasing the bending strength and fracture toughness. Besides the number of pores in the green body, the pore size in the green body can also affect the mechanical properties of reaction-bonded B_4C -SiC ceramics. Li *et al.*⁷⁶ stated that the porosity and pore size of the green body correspond to the volumetric fraction and size of the Si phase, respectively; the hardness of B_4C -SiC ceramics increases with the decrease in residual Si size. Therefore, decreasing the pore size in the green body can also increase the mechanical properties of reaction-bonded B_4C -SiC ceramics.

Moreover, preliminary sintering for preforms before infiltration with molten Si can increase the relative density of preforms;142,156 an additional step, namely, the preliminary sintering of preforms, is added, and a product with decreased Si content is obtained. However, Dariel and Frage⁹⁹ found that the preliminary sintering of preforms has little effect on the mechanical properties of the obtained reaction-bonded B_4C -SiC ceramics, which is attributed to the rim structure connecting the original B₄C grains in both the preliminary sintered preforms and the green preforms. Hayun et al.¹⁴⁸ also noted that the preliminary sintering of preforms has no effect on the static mechanical properties and on the dynamic response of the resulting reaction-bonded B₄C-SiC ceramics, although preliminary sintering can lead to the formation of a continuous preform skeleton. This phenomenon is attributed to the similar final microstructures between the B4C-SiC ceramics produced from the preforms with and without preliminary sintering, *i.e.*, the rim regions composed of $B_{12}(B, C, Si)_3$ connect the B_4C grains in both types of reaction-bonded B₄C-SiC ceramics.

In addition, the forming technique for the green body can affect the mechanical properties of the resulting B₄C-SiC ceramics. Xu et al.100 used the conventional compression molding method and gel-casting method to produce preforms composed of B4C and C, respectively, and found that the mechanical properties of the obtained reaction-bonded B₄C-SiC ceramics produced by the gel-casting method are higher than those of the reaction-bonded B₄C-SiC ceramics produced by the conventional compression molding method after the same liquid Si infiltration process. The higher mechanical properties are attributed to the microstructure of the obtained B₄C-SiC ceramics, *viz.*, the continuous SiC-bonded B_4C skeleton structure and decreased size of residual Si in the ceramics, resulting from the 3D-interconnected porous structure in the preform produced via the gel-casting route. Furthermore, residual Si inevitably exists in the reaction-bonded B₄C-SiC ceramics; however, it is possible to improve their mechanical properties as far as possible by controlling the size of residual Si. Non-uniform residual stress distributes throughout if the residual Si size is larger than 5 µm, leading to defect generation due to the presence of anomalous tensile stress in the interior of residual Si.178 Ren et al.103 observed that adjusting the content of the catalyst Na₂CO₃ in the resorcinol-formaldehyde gel system can help control the pore characteristics of the preform prepared by gelcasting, which can improve the mechanical properties of the reaction-bonded B4C-SiC ceramics by controlling the content and size of residual Si. With an increase in catalyst content, on the one hand, the residual Si content is reduced; on the other hand, carbon particle size in the preform decreases, resulting in the decreased size of the SiC particles formed. However, as the size of carbon particles decreases to a nanometre size, nano-sized carbon particles undergo aggregation, leading to the formation of large-sized SiC particles and subsequent deterioration of mechanical properties due to the large residual stress during cooling. Also, the pore structure of the preform changes from a single macroporous or mesoporous structure to a hierarchical macroporousmesoporous structure with the increase in catalyst content. The preform with a single mesoporous structure exhibits the best mechanical properties. Using the gel-casting method to produce the green body is a feasible and novel way to improve the mechanical properties of reaction-bonded B₄C-SiC ceramics.

Some previous studies on the effect of forming pressure and forming technique for the green body on the mechanical properties of reaction-bonded B₄C–SiC ceramics are tabulated in Table 12.

4.4.2. Parameters during sintering. Parameters during sintering mainly affect the mechanical properties of B_4C -SiC ceramics by changing their microstructure. Generally, fine grains are helpful in improving the mechanical properties of B_4C -SiC ceramics. Meanwhile, high relative density, which can be achieved by increasing sintering temperature, prolonging holding time, and enhancing sintering pressure (if any), allows B_4C -SiC ceramics to achieve better mechanical properties. It is worth noting that increasing the sintering temperature or prolonging the holding time can lead to grain coarsening, which is not conducive to improving the mechanical properties of B_4C -SiC ceramics.

4.4.2.1. Sintering temperature. For B₄C-SiC ceramics produced via pressureless sintering, Zhu et al.¹⁰⁷ reported that the hardness, bending strength, and fracture toughness of B₄C-15 wt% SiC ceramics first increase and then decrease with an increase in sintering temperature in the range of 2100 to 2200 °C. When the sintering temperature is 2150 °C, the mechanical properties of B₄C-SiC ceramics reach the maximum. With the increase in sintering temperature to 2150 °C, the improvement in mechanical properties of B4C-SiC ceramics is attributed to the following aspects: (1) the porosity of the ceramics is reduced, and the pores are mostly round or regular polygons, the characteristics of which can reduce stress concentration and increase the bending strength; (2) clean phase boundaries between B4C and SiC grains indicate that the bonding between B_4C and SiC is strong (Fig. 8b), which has an vital influence on the mechanical properties of B_4C -SiC ceramics; (3) graphite formed due to the crystallisation of the sintering aid of carbon black can hinder the movement of grain boundaries at the high temperature stage, improving the mechanical properties; (4) the phase boundary between B_4C and graphite is clean and narrow, and such a semi-coherent interface with low stress results in a high bending strength; (5) the existence of SiC particles can cause crack deflection (Fig. 13a)

Table 12 E	Table 12 Effect of forming pressure and forming technique for the		on the mec	green body on the mechanical properties of reaction-bonded $B_4C\mbox{-SiC}$ ceramics	s of reaction-bo	onded B ₄ C	-SiC ceramic	S			
		Forming technique of		Open porosity of the green	Sintering temperature	Open porosity	Residual Si content	Hardness	Fracture toughness	Bending strength	Young's modulus
Ceramics	Ceramics Raw material	preform	(MPa)	body $(\widetilde{\%})$	_(O_)	(%) ,	(vol%)	(GPa)	$(MPa m^{1/2})$	(MPa)	(GPa)
B ₄ C–SiC ¹⁷⁷ I	B ₄ C, carbon black, Si lump	Compression molding	50	49.4	1550	0.95	38.5	16.8	3.80	246	
B_4C-SiC^{177}	B_4C , carbon black, Si lump	Compression molding	100	46.3	1550	0.40	32.8	18.2	4.05	263	
$\mathrm{B_4C-SiC^{177}}$	B ₄ C, carbon black, Si lump	Compression molding	150	44.3	1550	0.23	30.6	21.9	4.28	283	
$\mathrm{B_4C-SiC^{177}}$	B ₄ C, carbon black, Si lump	Compression molding	200	42.3	1550	0.19	28.8	24.0	4.90	319	
$\mathrm{B_4C-SiC^{177}}$	B ₄ C, carbon black, Si lump	Compression molding	250	41.7	1550	0.30	26.8	24.6	4.59	310	
B_4C-SiC^{100}	B_4C (2.41 µm), carbon black, Si lump	Compression molding	200	39.1	1480			17.4	3.61	330	
B_4C-SiC^{100}	B_4C (2.41 µm), carbon black, Si lump	Gel-casting	Ι	37.7	1480			19.4	4.37	389	

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that may occur because of the layered structure within SiC grains, crack branching (Fig. 13b), and crack bridging (Fig. 13c), prolonging the crack-propagation, inhibiting crack-tip propagation, and increasing the energy consumption; thus, the fracture toughness of the B₄C-SiC ceramics is increased. However, a higher sintering temperature will lead to abnormal grain growth and increased porosity caused by the rapid movement of grain boundaries, which can deteriorate the mechanical properties of B₄C-SiC ceramics.

For B₄C-SiC ceramics prepared by hot-press sintering, Shi et al.⁸³ found that the hardness and bending strength of B_4C -20 vol% SiC ceramics increase with an increase in sintering temperature from 1900 to 2100 °C, which is attributed to the reduced porosity with an increase in sintering temperature. The bending strength of B₄C-SiC ceramics strongly depends on porosity, and the relationship between porosity (θ) and bending strength (σ_w) of B₄C-20 vol% SiC ceramics can be expressed as $\sigma_{\rm w} = 257 \exp(-2.18\theta)$. Compared with pure B₄C ceramics, the B₄C-20 vol% SiC ceramics exhibit higher hardness after different sintering temperatures; however, the bending strength of B₄C-20 vol% SiC ceramics is higher than that of pure B₄C ceramics only after sintering at 1900 °C, and the bending strength of B₄C-20 vol% SiC ceramics is slightly lower than that of pure B4C ceramics after sintering at 2000 and 2100 °C. Zhang et al.⁹⁸ stated that the hardness and bending strength of B₄C-50 wt% SiC ceramics increase linearly with the increase in sintering temperature in the range of 1800-1950 °C, which is attributed to the gradually increased densification; however, the fracture roughness of the ceramics first increases and then decreases. When the sintering temperature is 1850 °C, the fracture toughness reaches the maximum because there are a number of pores inside the ceramics sintered at that temperature and these pores can consume fracture energy when cracks pass through them. Chen et al.¹¹⁰ reported that the mechanical properties of B4C-20 wt% SiC ceramics increase with the increase in sintering temperature from 1800 to 1900 °C, which is attributed to the smaller grains and denser microstructure at higher sintering temperatures. The B₄C-20 wt% SiC ceramics exhibit better mechanical properties than the pure B₄C ceramics. The fracture mode of the B₄C-20 wt% SiC ceramics is mainly transgranular fracture at any temperature; however, partial crack deflection and grain pullout are enhanced with an increase in sintering temperature (Fig. 14).

For spark plasma sintered B_4C -SiC ceramics, Wu et al.¹¹¹ observed that the hardness and fracture toughness of B₄C-20 vol% SiC ceramics increase with the increase in sintering temperature from 1900 to 2000 °C. The improved mechanical properties are attributed to the increased relative density with the increase in sintering temperature, independent of the phase change because no new phases are formed during sintering. When the sintering temperature is higher than 2000 °C, the change in mechanical properties of B₄C-20 vol% SiC ceramics is not obvious. The increased sintering temperature does not change the mode of crack propagation, that is, the fracture mechanism of the ceramics sintered at different sintering temperatures is the transgranular fracture. However, the number of

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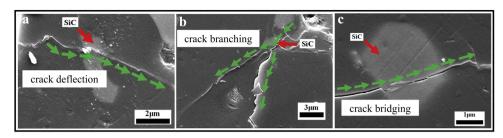


Fig. 13 Crack propagation on the surface of pressureless sintered B_4C-15 wt% SiC ceramics: (a) crack deflection, (b) crack branching, and (c) crack bridging¹⁰⁷ (reprinted with permission, Copyright 2019, Elsevier).

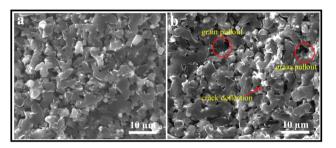


Fig. 14 Fracture surfaces of hot-press sintered B₄C-20 wt% SiC ceramics at different sintering temperatures: (a) 1800 $^\circ C$ and (b) 1900 $^\circ C.^{110}$

pores in the ceramics gradually decreases with the increase in sintering temperature; thus, the crack propagation is more hindered. Also, the reduction of porosity can increase the probability of cracks passing through the SiC grains, resulting in a significant increase in fracture toughness.

For B_4C -SiC ceramics fabricated by reaction-bonded sintering, sintering temperature can alter phase volume fractions. Zhang *et al.*¹¹⁷ found that the hardness, fracture toughness, and bending strength of B_4C -SiC ceramics increase with the increase in infiltration temperature from 1450 to 1600 °C. The improved hardness and bending strength are attributed to the gradually decreased porosity, and the increased fracture toughness is caused by the increased *in situ* formed SiC with a layered structure. When the infiltration temperature is more than 1600 °C, the fracture toughness increases continuously; however, the hardness and bending strength decrease, resulting from the increased porosity and the larger flaws due to the increased grain size of B_4C particles and the presence of large SiC zones.

4.4.2.2. Holding time. Tomohiro et al.⁷⁸ reported that the bending strength and fracture toughness of the hot-press sintered B₄C-15 vol% SiC ceramics decrease with the increase in holding time from 0.5 to 2 h when the sintering temperature is 2200 °C, which is attributed to the increased grain size and the increased flaw size in the ceramics with the increase in holding time.

4.4.2.3. Sintering pressure. Chen et al.¹²² noted that the mechanical properties of hot-press sintered B_4C -20 wt% SiC ceramics increase with the increase in sintering pressure from 30 to 40 MPa, which is attributed to the increased relative density and decreased grain size of the B_4C -SiC ceramics with the increase in sintering pressure. The fracture mode of the B_4C -SiC ceramics

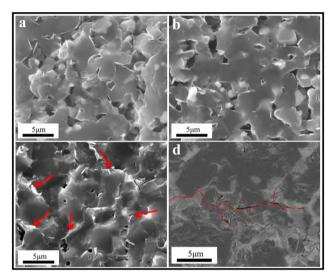


Fig. 15 Fracture surfaces of hot-press sintered B₄C-20 wt% SiC ceramics produced at different sintering pressures: (a) 30 MPa, (b) 35 MPa, and (c) 40 MPa.¹²² (d) Indentation crack deflection in hot-press sintered B₄C-20 wt% SiC ceramics produced at a sintering pressure of 40 MPa.¹²²

is mainly transgranular fracture at different sintering pressures (Fig. 15a–c); however, cracks tend to deflect with the increase in sintering pressure. The residual stress is caused due to different thermal expansion coefficients between B_4C and SiC during hotpress sintering, forming the microcracks at the weak interface between B_4C and SiC because the hot-press sintering with Al_2O_3 and Y_2O_3 as sintering aids. When the sintering pressure is low, the microstructure is loose; thus, it is difficult to generate a crack deflection effect, leading to lower fracture toughness. However, under high sintering pressure, when the fracture crack extends to the microcrack (Fig. 15d), so that the fracture crack will deflect and bifurcate, improving the fracture toughness.

Some previous studies on the effect of parameters during sintering on the mechanical properties of B_4C -SiC ceramics are tabulated in Table 13.

4.5. Sintering aids

The addition of sintering aids can promote the sintering of B_4C -SiC ceramics *via* solid-state sintering or liquid-phase sintering

Table 13 Effect of parameters during sintering on the mechanical properties of B4C-SiC ceramics

Ceramics	Raw material	Sintering method	Sintering temperature (°C)	Holding time	Sintering pressure (MPa)	Sintering aid	Relative density (%)	Hardness (GPa)	Fracture toughness (MPa m ^{1/2})	Bending strength (MPa)	Bending Young's strength modulus (MPa) (GPa)
$B_{4}C-15 \text{ wt\% SiC}^{107}$	B ₄ C (0.8 μm), SiC (0.5 μm)	Pressureless	2100	1 h	No	2 wt% carbon black	91.6	16.2	2.20	145	
$B_4C-15 \text{ wt\% SiC}^{107}$		Pressureless	2125	1 h	No	2 wt% carbon black	93.6	22.1	2.60	231	
$B_4C-15 \text{ wt\% SiC}^{107}$		Pressureless	2150	1 h	No	2 wt% carbon black	95.3	25.5	2.81	296	
B_4C-15 wt% SiC ¹⁰⁷		Pressureless	2175	1 h	No	2 wt% carbon black	93.1	22.0	2.40	193	
${ m B_4C}^{83}$		Hot-press	1900	1 h	20	No	71.9	3.2		134	
B_4C-20 vol% SiC ⁸³	B_4C (10.22 µm), β -SiC (1.07 µm)	Hot-press	1900	1 h	20	No	73.7	3.7		150	
${ m B}_4{ m C}^{83}$	$B_4C(10.22 \mu m)$	Hot-press	2000	1 h	20	No	77.0	5.0		164	
B_4C-20 vol% SiC ⁸³	B_4C (10.22 µm), β -SiC (1.07 µm)	Hot-press	2000	1 h	20	No	77.8	6.1		153	
${ m B_4C^{83}}$	$B_4C (10.22 \mu \text{m})$	Hot-press	2100	1 h	20	No	87.9	11.5		196	
B_4C-20 vol% SiC ⁸³	B_4C (10.22 µm), β -SiC (1.07 µm)	Hot-press	2100	1 h	20	No	87.0	12.8		194	
B_4C -50 wt% SiC ⁹⁸	B_4C , SiC, mean particle size of 0.7 µm		1800	0.5 h	30	No	74.0	6.0	3.20	214	
B_4C -50 wt% SiC ⁹⁸	B_4C , SiC, mean particle size of 0.7 μ m		1850	0.5 h	30	No	79.2	8.0	5.20	263	
B_4C -50 wt% SiC ⁹⁸	B_4C , SiC, mean particle size of 0.7 μ m		1900	0.5 h	30	No	89.2	18.0	4.90	366	
B_4C -50 wt% SiC ⁹⁸	B_4C , SiC, mean particle size of 0.7 μ m		1950	0.5 h	30	No	96.4	24.0	4.60	430	
$\mathrm{B_4C^{110}}$			1800	0.5 h	30	$10 \text{ wt\%} (\text{Al}_2\text{O}_3 + \text{Y}_2\text{O}_3)$	97.2	8.2	2.58	257	
$B_4C-20 wt\% SiC^{110}$		Hot-press	1800	0.5 h	30	10 wt% $(Al_2O_3 + Y_2O_3)$	94.0	12.0	3.28	237	
$\mathrm{B_4C^{110}}$		Hot-press	1900	0.5 h	30	10 wt% $(Al_2O_3 + Y_2O_3)$		20.0	4.01	264	
$B_4C-20 \text{ wt\% SiC}^{110}$			1900	0.5 h	30	$10 \text{ wt\%} (\text{Al}_2\text{O}_3 + \text{Y}_2\text{O}_3)$	98.5	17.0	4.79	313	
B_4C-20 vol% SiC ¹¹¹	B_4C (3.5 µm), SiC (0.5 µm)		1900	10 min	40	No	90.1	16.7	3.93		
$B_4C-20 \text{ vol}\% \text{ SiC}^{111}$	B_4C (3.5 µm), SiC (0.5 µm)	Spark plasma	1950	10 min	40	No	91.0	17.2	4.12		
B ₄ C-20 vol% SiC ¹¹¹	B_4C (3.5 µm), SiC (0.5 µm)	Spark plasma	2000	10 min	40	No	96.3	32.4	4.78		
B_4C-20 vol% SiC ¹¹¹		Spark plasma	2050	10 min	40	No	96.6	32.9	4.74		
$B_4C-20 \text{ vol}\% SiC^{111}$		Spark plasma	2100	10 min	40	No	96.8	33.4	4.68		
B_4C-SiC^{117}		Reaction	1450	$1 \mathrm{h}$	No	No	99.8	15.0	3.33	312	
$B_4C-SiC^{11/2}$	B_4C (4.08 µm), carbon black, Si lump	Reaction	1500	$1 \mathrm{h}$	No	No	99.8	16.9	3.63	315	
B_4C-SiC^{117}	B_4C (4.08 µm), carbon black, Si lump	Reaction	1550	1 h	No	No	9.99	17.0	3.66	319	
B_4C-SiC^{117}	B_4C (4.08 µm), carbon black, Si lump	Reaction	1600	1 h	No	No	9.99	19.0	3.80	344	
B_4C-SiC^{117}	B_4C (4.08 µm), carbon black, Si lump	Reaction	1650	1 h	No	No	99.8	13.7	3.97	290	
B_4C-15 vol% SiC ⁷⁸	$B_4C (0.72 \ \mu m), \beta$ -SiC (0.3 $\mu m)$	Hot-press	2200	0.5 h	30	No	99.7		4.73	680	
B_4C-15 vol% SiC ⁷⁸	$B_4C (0.72 \ \mu m), \beta$ -SiC (0.3 $\mu m)$	Hot-press	2200	1 h	30	No	99.7		4.70	553	
B_4C-15 vol% SiC ⁷⁸	$B_4C (0.72 \ \mu m), \beta$ -SiC (0.3 $\mu m)$	Hot-press	2200	2 h	30	No	99.7		4.20	396	
B ₄ C-20 wt% SiC ¹²²		Hot-press	1900	0.5 h	30	$10 \text{ wt\%} (\text{Al}_2\text{O}_3 + \text{Y}_2\text{O}_3)$	98.5	17.0	4.79	313	
B ₄ C-20 wt% SiC ¹²²		Hot-press	1900	0.5 h	35	10 wt% $(Al_2O_3 + Y_2O_3)$	98.6	25.7	6.94	366	
$B_4C-20 wt\% SiC^{122}$		Hot-press	1900	0.5 h	40	10 wt% $(Al_2O_3 + Y_2O_3)$	0.06	32.6	7.21	448	Ι

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(Section 3.4). In general, under the liquid-phase sintering mechanism, amorphous secondary phases remain at the phase boundary of the composite ceramics. Accordingly, numerous processes, such as creep, diffusion, crack growth, oxidation, and corrosion will occur during the applications depending on the amount and the composition of boundary phases, which can affect the performance, especially at high temperatures, and even shorten the service life of ceramics.¹⁷⁹ Compared with liquid-phase sintering, the ceramics can achieve better high-temperature performance under the solid-state sintering mechanism. Different sintering aids have different effects on the mechanical properties of B_4C –SiC ceramics. Some types of sintering aids benefit only the densification of B_4C –SiC ceramics, not their mechanical properties.

4.5.1. C. Moshtaghioun *et al.*¹¹² reported that the graphite sintering aid can promote the densification of the spark plasma sintered B_4C -15 wt% SiC ceramics; however, the addition of graphite increases the sizes of both B_4C and SiC grains, thus decreasing the hardness and fracture toughness of the ceramics. Meanwhile, the residual graphite softens the B_4C -SiC ceramics and weakens the interface between the B_4C and SiC grains.

In addition, the graphite sintering aid also has an effect on the creep resistance of B₄C–SiC ceramics at high temperatures.¹²⁶ The total deformation of B₄C-SiC ceramics with 2 wt% graphite and without graphite is 25% and 30%, respectively. In the case of B₄C-SiC ceramics with graphite after deformation, the cavitation that is created during deformation occurs in the ceramics; however, the complicated networks of dislocations, twinning, and trapped dislocations in twins are the main characteristics in the B₄C-SiC ceramics without graphite. In the absence of graphite, the B₄C-SiC ceramics show a similar plastic behavior as pure B₄C polycrystalline ceramics. In the presence of graphite, the deformation of B₄C-SiC ceramics is controlled by either solution-precipitation or grain sliding controlled by the viscosity of the glassy phase. The creep resistance of B4C-SiC ceramics is strongly dependent on the presence of a graphite layer along the grain boundary. For the B₄C-SiC ceramics with graphite, grain boundary sliding is a more favorable process under creep, permitting ductility to be increased to a greater strain value. Therefore, due to an enhanced creep resistance, B₄C-SiC ceramics with graphite opens up new perspectives of structural materials with complex shapes for high-temperature applications.

4.5.2. Oxide. Jamale and Kumar¹²⁷ studied the effect of Al_2O_3 addition on the mechanical properties of spark plasma sintered B_4C -10 wt% SiC ceramics. With an increase in the amount of relatively softer Al_2O_3 from 3 to 6 wt%, the hardness of B_4C -10 wt% SiC ceramics slightly decreases, but the fracture toughness increases. Transgranular fracture is still the dominant fracture mode in the B_4C -10 wt% SiC ceramics after the addition of Al_2O_3 , resulting from the minor difference in thermal expansion coefficients between B_4C and SiC. Sahin *et al.*⁹⁶ observed that the addition of 5 wt% Y_2O_3 can slightly enhance the hardness of spark plasma sintered B_4C -SiC ceramics, which is attributed to the improved relative density resulting from the formation of glassy phases. Rocha and Melo⁸⁸ found that the pressureless sintered B_4C -10 wt% SiC ceramics with the addition

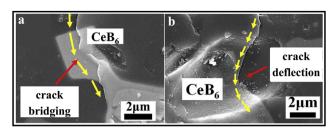


Fig. 16 Crack propagating on the surface of pressureless sintered B_4C-15 wt% SiC ceramics with the sintering aid of 5 wt% CeO₂: (a) crack bridging and (b) crack deflection¹²⁹ (reproduced with permission, Copyright 2013, Elsevier).

of sintering aids of AlN-Y2O3 can achieve higher hardness than that with the addition of sintering aids of Al₂O₃-Y₂O₃, which is attributed to the higher relative density of B4C-10 wt% SiC ceramics after the addition of AlN-Y₂O₃. Zhu et al.¹²⁹ reported that an appropriate amount of sintering aid CeO₂ can improve the mechanical properties of pressureless sintered B₄C-15 wt% SiC ceramics. On the one hand, CeB₆ grains formed in situ via the reaction between B_4C and CeO_2 disperse on the B_4C grain boundaries; these CeB₆ grains can inhibit the movement of grain boundary, which is beneficial for inhibiting grain growth and refining grains. On the other hand, a residual stress field is formed around the CeB6 grains during the cooling process due to the higher thermal expansion coefficient of CeB₆ than that of SiC and B4C,180 contributing to improved fracture toughness for B₄C-SiC ceramics. The toughening mechanisms are crack deflection owing to the thermal expansion mismatch between CeB₆ and B_4C and crack bridging at the crack tip by the CeB_6 grain (Fig. 16). However, the addition of excessive CeO_2 will increase the porosity of B₄C-SiC ceramics, leading to the reduction in mechanical properties.

4.5.3. Si. Du *et al.*¹³² stated that the addition of sintering aid Si can improve the mechanical properties of hot-press sintered B₄C-15 wt% SiC ceramics, in which SiC is obtained from PCS after pyrolyzing. On the one hand, Si forms a liquid phase at high temperatures, promoting densification and decreasing residual porosity; on the other hand, Si can react with residual C generated from the pyrolysis of PCS to form SiC, removing the soft C-rich phase that can reduce the hardness of B₄C-SiC ceramics. However, Sahani and Chaira¹³¹ found that the addition of sintering aid Si in the range of 2-20 wt% cannot enhance the hardness of B4C-60 wt% SiC ceramics produced by pressureless sintering or spark plasma sintering, although the relative density of the B₄C-60 wt% SiC ceramics is increased after the addition of Si. The hardness of B₄C-60 wt% SiC ceramics containing 10 wt% Si is close to that of B₄C-60 wt% SiC ceramics without Si, which is attributed to the reduced pore size and refined microstructure resulting from the sufficient Si addition. The addition of excessive Si will produce a large amount of residual Si in the matrix, reducing the hardness of the B₄C-60 wt% SiC ceramics.

Some previous studies on the effect of sintering aids on the mechanical properties of B_4C -SiC ceramics are tabulated in Table 14.

 Table 14
 Effect of sintering aids on the mechanical properties of B4C–SiC ceramics

	Ceramics	Raw material	Sintering aid	Sintering method	Sintering temperature (°C)	Relative density (%)	Hardness (GPa)	Fracture toughness (MPa m ^{1/2})	Bending strength (MPa)	Young's modulus (GPa)
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	$B_4C-15 \text{ wt\% SiC}^{112}$	B ₄ C (0.5 μm), β-SiC (0.5 μm)	No	Spark plasma (75 MPa)	$1650 (\times 3 min)$	96.6	30.3	6.0	Ι	
	$B_4C-15 wt\% SiC^{112}$	B ₄ C (0.5 μm), β-SiC (0.5 μm)	2 wt% graphite	Spark plasma (75 MPa)	$1650 (\times 3 \text{ min})$	98.8	25.7	5.5		
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	$B_4C-15 \text{ wt\% SiC}^{112}$	B ₄ C (0.5 μm), β-SiC (0.5 μm)		Spark plasma (75 MPa)		99.4	36.2	5.7		
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	$B_4C-15 \text{ wt\% SiC}^{112}$	B_4C (0.5 µm), β-SiC (0.5 µm)	2 wt% graphite	Spark plasma (75 MPa)		100.0	29.3	5.3		
P. B.C. SiC 6 wt% Al_0A, B.C. SiC Spark plasma (0. MPa) B.C. arSiC 1800 (<10 min) Suff plasma (0. MPa) B.C. arSiC 90.1 33.7 B.C. arSiC 5 wt% Y_2O_3 Spark plasma (0. MPa) B.C. arSiC 1750 (<5 min) Suff plasma (0. MPa) B.C. arSiC 90.1 33.4 B.C. arSiC 5 wt% Y_2O_3 Spark plasma (0. MPa) B.C. arSiC 1750 (<5 min) Suff plasma (0. MPa) B.C. arSiC 91.7 92.1 33.4 B.C. arSiC 5 wt% Y_2O_3 Spark plasma (0. MPa) B.C. arSiC 1750 (<5 min) Suff plasma (0. MPa) 1750 (<5 min) 92.3 93.3 33.4 B.C. prot 10 vol% (AlX): $Y_2O_3 = 51.3$ Spark plasma (0. MPa) 1750 (<5 min) 92.0 92.4 30.3 B.C. prot 10 vol% (AlX): $Y_2O_3 = 31.2$, Pressureless Pressureless 2100 93.4 30.3 B.C. (0.8 µm), SiC (0.5 µm) No Pressureless 2150 92.4 30.3 B.C. (0.8 µm), SiC (0.5 µm) No Pressureless 2150 92.4 30.3 B.C. (0.8 µm), SiC (0.5 µm) No Pressureless 2150 92.4 30.3 B.C. (0.8 µm), SiC (0.5 µm) No	${ m B_4C-10}~{ m wt\%}~{ m SiC}^{127}$	B ₄ C, SiC	$3 \text{ wt\% Al}_2 \hat{O}_3$	Spark plasma (40 MPa)		99.5	35.1	5.9		
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	${ m B_4C-10}~{ m wt\%}~{ m SiC^{127}}$	B_4C , SiC	$6 \text{ wt}\% \text{ Al}_2 \text{O}_3$	Spark plasma (40 MPa)		99.1	33.7	6.5		
BG, 5-SiC5 wt% Y_2O_3 Spark plasma (40 MPa)1756 (×5 min)98.335.3B, Q, c×SiCNo5 wt% Y_2O_3 Spark plasma (40 MPa)1756 (×5 min)98.331.4B, Q, c×SiC5 wt% Y_2O_3 Spark plasma (40 MPa)1756 (×5 min)98.831.4B, Q, c×SiC10 vol% (AJO_3) , Y_2O_3 Spark plasma (40 MPa)1756 (×5 min)97.831.4B, Q, p, SiC10 vol% (AJO_3) , Y_2O_3 51.3Pressureless200091.430.3B, Q, p, SiC10 vol% (AJN) , Y_2O_3 31.2Pressureless200091.430.3B, C (B3 µm), SiC (0.5 µm)nolar ratio)ressureless215091.226.0B, C (0.8 µm), SiC (0.5 µm)3 wt% CCO_3Pressureless215091.430.3B, C (0.8 µm), SiC (0.5 µm)3 wt% CCO_3Pressureless215091.430.3B, C (0.8 µm), SiC (0.5 µm)3 wt% CCO_3Pressureless215091.430.3B, C (0.8 µm), SiC (0.5 µm)9 wt% CCO_3Pressureless215091.430.4B, C (0.8 µm), SiC (0.5 µm)9 wt% CCO_3Pressureless215091.430.3B, C (0.8 µm), SiC (0.5 µm)9 wt% CCO_3Pressureless2150<	$B_4C-5 \text{ vol}\% \text{ SiC}^{96}$	B_4C , α -SiC	No	Spark plasma (40 MPa)	\sim	98.0	34.4			
Bc, q_{-5} SiC No Spark plasma (40 MPa) 1750 (×5 min) 98.0 33.4 B,C, q_{-5} SiC No Spark plasma (40 MPa) 1750 (×5 min) 98.0 33.4 B,C, q_{-5} SiC No Spark plasma (40 MPa) 1750 (×5 min) 98.0 33.4 B,C, q_{-5} SiC No Spark plasma (40 MPa) 1750 (×5 min) 98.2 33.0 B,C, q_{-5} SiC 10 vol% (Aly, q_{1} , y_{2} , y_{3} = 5:3, Pressureless 2000 91.5 29.5 B,C, q_{-5} IC 10 vol% (AlN): y_{2} O ₃ = 3:2, Pressureless 2150 93.4 30.3 B,C (0.8 µm), SiC (0.5 µm) No No Pressureless 2150 91.5 26.0 B,C (0.8 µm), SiC (0.5 µm) 30.6 CO_2 Pressureless 2150 91.4 27.2 B,C (0.8 µm), SiC (0.5 µm) 30.8 No Pressureless 2150 91.4 27.0 B,C (0.8 µm), SiC (0.5 µm) No Pressureless 2150 91.4 27.0 B,C (0.8 µm), SiC (0.5 µm) No Pressureless 2150 <td< td=""><td>$B_4C-5 \text{ vol}\% \text{ SiC}^{96}$</td><td>$B_4C$, α-SiC</td><td>$5 \text{ wt}\% \text{ Y}_2 \text{O}_3$</td><td>40</td><td></td><td>98.3</td><td>35.3</td><td> </td><td> </td><td> </td></td<>	$B_4C-5 \text{ vol}\% \text{ SiC}^{96}$	B_4C , α -SiC	$5 \text{ wt}\% \text{ Y}_2 \text{O}_3$	40		98.3	35.3			
Br, C. arSiC5 wt% Y_2O_3 Spark plasma (40 MPa)1750 (×5 min)98.834.4Br, C. arSiC5 wt% Y_2O_3 5 wt% $Y_2O_3 = 5:3$,Spark plasma (40 MPa)1750 (×5 min)97.831.1Br, C. p.SiC10 vol% (Al_JO_3; Y_2O_3 = 5:3,Pressureless200091.529.5Br, G (as µm), SiC (0.5 µm)10 vol% (Al_JO_3; Y_2O_3 = 3:2,Pressureless200093.430.3Br, G (as µm), SiC (0.5 µm)10 vol% (Al_JO_3; Y_2O_3 = 3:2,Pressureless215091.529.6Br, G (as µm), SiC (0.5 µm)1 wt% GCO_3Pressureless215091.430.3Br, G (as µm), SiC (0.5 µm)3 wt% GCO_3Pressureless215091.430.3Br, G (as µm), SiC (0.5 µm)3 wt% GCO_3Pressureless215091.432.2Br, G (as µm), SiC (0.5 µm)3 wt% GCO_3Pressureless215091.432.2Br, G (as µm), SiC (0.5 µm)3 wt% GCO_3Pressureless215091.422.0Br, G (as µm), SiC (0.5 µm)9 wt% GCO_3Pressureless215091.422.0Br, G (as µm), SiC (0.5 µm)9 wt% GCO_3Pressureless215091.422.0Br, G (as µm), SiC (0.5 µm)9 wt% GCO_3Pressureless215091.423.2Br, G (as µm), SiC (0.5 µm)9 wt% GCO_3Pressureless215091.424.0Br, G (as µm), SiC (0.5 µm)9 wt% GCO_3Pressureless215091.424.0Br, G (as µm), PCS11 wt% SiHotpress (0 MPa)<	$B_4C-10 \text{ vol}\% \text{ SiC}^{96}$	B_4C , α -SiC	No	Spark plasma (40 MPa)		98.0	33.4			
Br, C = CSIC No Spark plasma (40 MPa) 1750 (×5 min) 97.8 31.1 Br, G = CSIC 5 w/9 Y_Q_3 51.3, Pressureless 2000 91.5 29.5 Br, G = SIC 10 vol% (AlyO_3: Y_2O_3 = 51.3, Pressureless 2000 91.5 29.5 Br, G = SIC 10 vol% (AlyO_3: Y_2O_3 = 31.2, Pressureless 2000 93.4 30.3 Br, G (0.8 µm), SIC (0.5 µm) No Pressureless 2150 91.2 29.4 Br, G (0.8 µm), SIC (0.5 µm) 3 wt% CeO_3 Pressureless 2150 91.2 29.4 Br, G (0.8 µm), SIC (0.5 µm) 3 wt% CeO_3 Pressureless 2150 91.2 29.4 Br, G (0.8 µm), SIC (0.5 µm) 3 wt% CeO_3 Pressureless 2150 91.2 29.4 Br, G (0.8 µm), SIC (0.5 µm) 3 wt% CeO_3 Pressureless 2150 91.4 30.3 Br, G (0.8 µm), SIC (0.5 µm) 3 wt% CeO_3 Pressureless 2150 91.4 27.0 Br, G (0.8 µm), SIC (0.5 µm) No No Pressureless 2150	$B_4C-10 \text{ vol}\% \text{ SiC}^{96}$	B_4C , α -SiC	$5 \text{ wt}\% \text{ Y}_2 \text{O}_3$	Spark plasma (40 MPa)		98.8	34.4			
Br, c xSIC5 wt% Y_{0,3}Spatk plasma (40 MPa)1750 ($\times 5 \min$)98.233.0Br, C, P-SIC10 vol% (Al ₂ O ₃ : Y ₂ O ₃ = 5:3,Pressureless200091.529.5Br, C (0.8 \min) SIC (0.5 \min)NOPressureless215085.819.8Br, C (0.8 \min) SIC (0.5 \min)NOPressureless215091.529.4Br, C (0.8 \min) SIC (0.5 \min)NOPressureless215091.529.4Br, C (0.8 \min) SIC (0.5 \min)3 wt% CeO2Pressureless215091.529.4Br, C (0.8 \min) SIC (0.5 \min)3 wt% CeO2Pressureless215091.427.0Br, C (0.8 \min) SIC (0.5 \min)3 wt% CeO2Pressureless215091.427.0Br, C (0.8 \min) SIC (0.5 \min)9 wt% CeO2Pressureless215091.427.0Br, C (3.5 \min) PCS11.4 wt% SIHot-press (30 MPa)195094.429.0Br, C (3.5 \min) PCS11.4 wt% SIHot-press (30 MPa)195094.429.0Br, C (3.5 \min) PCS11.4 wt% SIHot-press (30 MPa)195094.429.0Br, C (3.5 \min) PCS11.4 wt% SIHot-press (30 MPa)195094.429.0Br, C (3.5 \min) PCS11.4 wt% SIHot-press (30 MPa)195094.429.0Br, C (3.5 \min) PCS11.4 wt% SIHot-press (30 MPa)195094.429.0Br, C (3.5 \min) PCS11.4 wt% SIHot-press (30 MPa)195094.429.0Br, C (3.5 \min) PCS11.4 wt% SI <td< td=""><td>$B_4C-15 \text{ vol}\% \text{ SiC}^{96}$</td><td>$B_4C$, α-SiC</td><td>No</td><td>Spark plasma (40 MPa)</td><td></td><td>97.8</td><td>31.1</td><td> </td><td> </td><td> </td></td<>	$B_4C-15 \text{ vol}\% \text{ SiC}^{96}$	B_4C , α -SiC	No	Spark plasma (40 MPa)		97.8	31.1			
Br, bitBr, bitDouble ratioPressureless200091.529.5Br, bitBr, bitDouble ratioMolar ratioPressureless200091.529.5Br, bitDouble ratioMolar ratioPressureless215091.226.0Br, bitSiC (0.5 µm)SiC (0.5 µm)WebPressureless215091.226.0Br, C (0.8 µm), SiC (0.5 µm)WebPressureless215091.226.0Br, C (0.8 µm), SiC (0.5 µm)WebPressureless215091.226.0Br, C (0.8 µm), SiC (0.5 µm)WebPressureless215091.427.0Br, C (0.8 µm), SiC (0.5 µm)WebPressureless215092.424.0Br, C (0.8 µm), SiC (0.5 µm)Pressureless210.093.427.0Br, C (0.8 µm), SiC (0.5 µm)Pressureless210.093.427.0Br, C (0.8 µm), SiC (0.5 µm)Pressureless210.093.231.0 <td< td=""><td>$B_4C-15 \text{ vol}\% \text{ SiC}^{96}$</td><td>$B_4C$, α-SiC</td><td>$5 \text{ wt}\% \text{ Y}_2 \text{O}_3$</td><td>Spark plasma (40 MPa)</td><td></td><td>98.2</td><td>33.0</td><td> </td><td> </td><td> </td></td<>	$B_4C-15 \text{ vol}\% \text{ SiC}^{96}$	B_4C , α -SiC	$5 \text{ wt}\% \text{ Y}_2 \text{O}_3$	Spark plasma (40 MPa)		98.2	33.0			
Br.C, β SiCmolar ratiomolar ratioBr,C, β SiC10 vol% (MN: Y_2O_3 = 3:2)Pressureless200093.430.3Br,C (0.8 µm), SiC (0.5 µm)NoPressureless215091.226.0Br,C (0.8 µm), SiC (0.5 µm)3 wt% CeC_2Pressureless215091.226.0Br,C (0.8 µm), SiC (0.5 µm)3 wt% CeC_2Pressureless215092.629.4Br,C (0.8 µm), SiC (0.5 µm)3 wt% CeC_2Pressureless215092.629.4Br,C (0.8 µm), SiC (0.5 µm)7 wt% CeC_2Pressureless215094.629.0Br,C (0.8 µm), SiC (0.5 µm)9 wt% CeC_2Pressureless215094.629.0Br,C (3.5 µm), PCS11.4wt% CeC_2Pressureless215094.629.0Br,C (3.5 µm), PCS11.4wt% SiHot-press (30 MPa)195097.820.0Br,C (3.5 µm), PCS11.4wt% SiH	$\mathrm{B_4C} ext{-10} \mathrm{wt\%} \mathrm{SiC}^{88}$	B_4C , β -SiC	$10 \text{ vol}\% (\text{Al}_2\text{O}_3; \text{Y}_2\text{O}_3 = 5:3,$	Pressureless	2000	91.5	29.5			
B4C, β -SiCD vol% (AIN: Y_2O_3 = 3:2, Messureless200093.430.3B4C (0.8 µm), SiC (0.5 µm)NoPressureless215091.226.0B4C (0.8 µm), SiC (0.5 µm)NoPressureless215091.226.0B4C (0.8 µm), SiC (0.5 µm)NoPressureless215092.629.4B4C (0.8 µm), SiC (0.5 µm)NoPressureless215094.427.0B4C (0.8 µm), SiC (0.5 µm) 3 wt% CeO2Pressureless215094.427.0B4C (0.8 µm), SiC (0.5 µm) 9 wt% CeO2Pressureless215094.427.0B4C (0.8 µm), SiC (0.5 µm)9 wt% CeO2Pressureless215094.427.0B4C (3.5 µm), PCS9 wt% CeO2Pressureless215094.427.0B4C (3.5 µm), PCS11.4 wt% SiHot-Press (30 MPa)195095.424.0B4C (3.5 µm), PCS11.4 wt% SiHot-Press (30 MPa)195097.324.4B4C (3.5 µm), PCS11.4 wt% SiHot-Press (30 MPa)195097.320.0B4C (3.5 µm), PCS11.4 wt% SiHot-Press (30 MPa)195097.324.4B4C (3.5 µm), PCS11.4 wt% SiHot-Press (30 MPa)195092.018.1B4C (3.5 µm), PCS11.4 wt% SiHot-Press (30 MPa)195092.324.4B4C (3.5 µm), PCS11.4 wt% SiPressureless195092.018.1B4C (3.5 µm), PCS11.4 wt% SiHot-Press (30 MPa)195092.018.1			molar ratio)	-						
	$B_4C-10 wt\% SiC$	B4C, 5-SiC	10 vol% (AIN : $Y_2O_3 = 3 : 2$, molar ratio)	Pressureless	2000	93.4	30.3			I
$ B_{4} C (0.8 \ {\rm m}), \ {\rm SiC} (0.5 \ {\rm m}) \ \ 1 \ {\rm wt}^{6} \ {\rm CeO}_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 3 \ {\rm wt}^{6} \ {\rm CeO}_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 3 \ {\rm wt}^{6} \ {\rm CeO}_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 3 \ {\rm wt}^{6} \ {\rm CeO}_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 3 \ {\rm wt}^{6} \ \ {\rm CeO}_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 3 \ {\rm wt}^{6} \ \ {\rm CeO}_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 3 \ {\rm wt}^{6} \ \ {\rm CeO}_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 0.5 \ \ 0.5 \ {\rm m}) \ \ 0.6 \ \ 3.5 \ \ 0.5 \ {\rm m}) \ \ 0 \ {\rm wt}^{6} \ \ CO_2 \ \ {\rm Pressureless} \ \ 2150 \ \ 0.5 \ {\rm m}) \ \ 0.5 \ \ 0.5 \ {\rm m}) \ \ 0 \ 0 \ \ 0 \ \ 0 \ 0 \ \ 0 \ 0 \ $	${ m B_4C-15}~{ m wt\%}~{ m SiC}^{129}$	$B_4C (0.8 \ \mu m)$, SiC (0.5 μm)	No	Pressureless	2150	85.8	19.8	2.40	194	
$ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ B_4 C (0.8 \ \mum), SiC (0.5 \ \mum) \\ N \\ $	$B_4C-15 wt\% SiC^{129}$	B_4C (0.8 µm), SiC (0.5 µm)	1 wt\% CeO_2	Pressureless	2150	91.2	26.0	3.25	270	
	$B_4C-15 wt\% SiC^{129}$	B_4C (0.8 µm), SiC (0.5 µm)	3 wt\% CeO_2	Pressureless	2150	92.6	29.4	3.59	330	
	$B_4C-15 wt\% SiC^{129}$	B ₄ C (0.8 μm), SiC (0.5 μm)	5 wt\% CeO_2	Pressureless	2150	96.4	32.2	4.32	380	
$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	$B_4C-15 \text{ wt\% SiC}^{129}$	B ₄ C (0.8 μm), SiC (0.5 μm)	7 wt\% CeO_2	Pressureless	2150	94.6	29.0	4.19	350	
$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	B_4C-15 wt% SiC ¹²⁹	B ₄ C (0.8 μm), SiC (0.5 μm)	9 wt\% CeO_2	Pressureless	2150	93.4	27.0	4.00	330	
$ \begin{array}{cccccccccccccccccccccccccccccccccccc$	$B_4C-15 \text{ wt\% SiC}^{132}$	B_4C (3.5 µm), PCS	No	Hot-press (30 MPa)	1950	95.4	24.0	4.96	265	
$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	$B_4C-15 wt\% SiC^{132}$	B_4C (3.5 µm), PCS	4 wt% Si	Hot-press (30 MPa)	1950	95.8	26.4	5.06	260	
$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	$B_4C-15 \text{ wt\% SiC}^{132}$	B_4C (3.5 µm), PCS	8 wt% Si	Hot-press (30 MPa)	1950	97.8	29.8	5.34	324	
$ \begin{array}{c ccccccccccccccccccccccccccccccccccc$	$B_4C-15 \text{ wt\% SiC}^{132}$	B_4C (3.5 µm), PCS	11.4 wt% Si	Hot-press (30 MPa)	1950	99.2	33.2	5.64	389	
B_4C , SiCNoPressureless195089.0 B_4C , SiC2 wt% SiPressureless195088.0 B_4C , SiC5 wt% SiPressureless195088.0 B_4C , SiC10 wt% SiPressureless195099.0 B_4C , SiC20 wt% SiPressureless195099.0 B_4C , SiC20 wt% SiPressureless195094.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)94.6 B_4C , SiC2 wt% SiSpark plasma (50 MPa)1350 (×5 min)96.3 B_4C , SiC10 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0	$B_4C-15 \text{ wt\% SiC}^{132}$	B_4C (3.5 µm), PCS	15 wt% Si	Hot-press (30 MPa)	1950	98.3	31.0	5.40	350	
B_4C , SiC2 wt% SiPressureless195088.0 B_4C , SiC5 wt% SiPressureless195089.0 B_4C , SiC10 wt% SiPressureless195099.0 B_4C , SiC20 wt% SiPressureless195094.0 B_4C , SiC20 wt% SiPressureless195094.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.0 B_4C , SiC2 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.0 B_4C , SiC10 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.0	$B_4C-60 \text{ wt\% SiC}^{131}$	B_4C , SiC	No	Pressureless	1950	89.0	20.0			
B_4C , SiC5 wt% SiPressureless195089.0 B_4C , SiC10 wt% SiPressureless195092.0 B_4C , SiC20 wt% SiPressureless195094.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)94.0 B_4C , SiC2 wt% SiSpark plasma (50 MPa)1350 (×5 min)94.0 B_4C , SiC2 wt% SiSpark plasma (50 MPa)1350 (×5 min)94.0 B_4C , SiC10 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0	$B_4C-60 wt\% SiC^{131}$	B_4C , SiC	2 wt% Si	Pressureless	1950	88.0	14.0			
B_4C , SiC10 wt% SiPressureless195092.0 B_4C , SiC20 wt% SiPressureless195090.0 B_4C , SiC20 wt% SiPressureless195090.0 B_4C , SiCNoSpark plasma (50 MPa)1600 ($\times 5 \min$)94.0 B_4C , SiC2 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.6 B_4C , SiC5 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.6 B_4C , SiC5 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)96.3 B_4C , SiC10 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)98.0	$B_4C-60 wt\% SiC^{131}$	B_4C , SiC	5 wt% Si	Pressureless	1950	89.0	16.2			
B_4C , SiC20 wt% SiPressureless195090.0 B_4C , SiCNoSpark plasma (50 MPa)1600 ($\times 5 \min$)94.0 B_4C , SiC2 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.6 B_4C , SiC5 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.6 B_4C , SiC5 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)94.6 B_4C , SiC10 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 ($\times 5 \min$)98.0	$B_4C-60 wt\% SiC^{131}$	B_4C , SiC	10 wt% Si	Pressureless	1950	92.0	18.1			
B4C, SiC No Spark plasma (50 MPa) 1600 (×5 min) 94.0 B4C, SiC 2 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 94.6 B4C, SiC 5 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 94.6 B4C, SiC 5 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 96.3 B4C, SiC 10 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 98.0 B4C, SiC 20 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 98.0	$B_4C-60 \text{ wt\% SiC}^{131}$		20 wt% Si	Pressureless	1950	90.0	15.0			
B_4C , SiC2 wt% SiSpark plasma (50 MPa)1350 (×5 min)94.6 B_4C , SiC5 wt% SiSpark plasma (50 MPa)1350 (×5 min)96.3 B_4C , SiC10 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0 B_4C , SiC20 wt% SiSpark plasma (50 MPa)1350 (×5 min)98.0	$B_4C-60 wt\% SiC^{131}$		No	Spark plasma (50 MPa)	$1600 (\times 5 min)$	94.0	28.0			
B ₄ C, SiC 5 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 96.3 B ₄ C, SiC 10 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 98.0 B ₄ C, SiC 20 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 98.0	$B_4C-60 wt\% SiC^{131}$	B_4C , SiC	2 wt% Si	Spark plasma (50 MPa)	$1350 (\times 5 min)$	94.6	22.0			
B4C, SiC 10 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 98.0 B4C, SiC 20 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 97.0	$B_4C-60 wt\% SiC^{131}$	B_4C , SiC	5 wt% Si	Spark plasma (50 MPa)	$1350 (\times 5 min)$	96.3	24.4			
SiC ¹³¹ B ₄ C, SiC 20 wt% Si Spark plasma (50 MPa) 1350 (×5 min) 97.0	$B_4C-60 \text{ wt\% SiC}^{131}$		10 wt% Si	Spark plasma (50 MPa)	$1350 (\times 5 min)$	98.0	27.8			
	$B_4C-60 wt\% SiC^{131}$		20 wt% Si	Spark plasma (50 MPa)	$1350 (\times 5 min)$	97.0	24.0			

5. Future development trend

 B_4C -SiC composite ceramics have emerged as a novel structural ceramic material for engineering applications. Looking forward, several aspects need to be further researched to enhance the understanding and fulfill their wide applications.

5.1. Investigation of high-temperature performance and other properties

 B_4C -SiC ceramics are dimensionally and structurally stable against a wide range of temperature variations due to chemical inertness and high-temperature resistance. High-temperatureresistant ceramics have the potential to have a significant impact on improving energy efficiency. The application of lightweight ceramics can lead to energy saving in various fields like the chemical industry, environment, automobile, aircraft engine parts, and power. As a potential high-temperature structural component, the mechanical properties of B_4C -SiC ceramics at high temperatures need to be further investigated.

Currently, the investigation for B₄C-SiC ceramics is mostly focused on conventional mechanical properties evaluation, and other mechanical properties are seldom reported. For example, as bulletproof materials, B4C-SiC ceramics are used against highspeed armor-piercing projectiles and hard steel-core bullets; thus, the compressive strength and impact strength of B₄C-SiC ceramics also need to be investigated deeply. Although the bending strength and hardness of the SiC-B₄C ceramics increase with the increase in B₄C content from 0 to 15 wt%, their impact strength exhibits the highest value as the B₄C content is 5 wt%.¹⁵¹ Therefore, all the mechanical property parameters need to be considered comprehensively. In addition, B4C-SiC ceramics have received considerable scientific attention for direct conversion between thermal and electric energy applications.^{181,182} Accordingly, the thermal properties and electrical properties of B₄C-SiC ceramics need to be evaluated.

5.2. Development of new sintering aids

To date, the sintering performance of B_4C -SiC ceramics can be enhanced by using sintering aids. However, some sintering aids only benefit densification or fracture toughness, not strength or hardness, and even deteriorate mechanical properties. To mitigate or overcome this disadvantage, new sintering aids should be developed to increase the fracture toughness while maintaining a high hardness for B_4C -SiC ceramics. Moreover, the use of current sintering aids may cause a reduction in the high-temperature mechanical properties of B_4C -SiC ceramics. Therefore, the development of new sintering aids for high-performance applications of B_4C -SiC ceramics at low and high temperatures is still a severe challenge.

5.3. Research on B₄C-SiC nanocomposite ceramics

Due to the nanometer size effect, B_4C -SiC nanocomposite ceramics exhibit better performance and have wider application prospects. However, one of the problems is that it is difficult and costly to produce B_4C -SiC nanocomposite ceramics by directly mixing commercial nano-sized B_4C and SiC powders and subsequent sintering. New ways and technologies should be explored to fabricate B_4C -SiC nanocomposite ceramics, enabling us to further broaden the application fields of B_4C -SiC ceramics. From the point of view of special properties and potential applications, the research on B_4C -SiC nanocomposite ceramics is meaningful.

5.4. Preparation of new forms of ceramics composed of B_4C -SiC

In addition to the traditional dense B_4C -SiC block ceramics with uniform composition, the B_4C -SiC component can also be used to prepare other forms of ceramic materials, such as gradient ceramics, laminated ceramics, porous ceramics, and ceramic hollow microspheres. Furthermore, due to the excellent performance of the B_4C -SiC binary system, it is estimated that more and more new forms of ceramics composed of B_4C -SiC will gradually appear.

5.4.1. Gradient ceramics/laminated ceramics. Gradient ceramics are a kind of inhomogeneous composite ceramics with at least two phases. One of the important characteristics of gradient ceramics is that the microstructure and performance present gradual gradient change along the thickness direction due to the continuous change of the component.¹⁸³ As a result, the specific performance in a specific direction of the gradient ceramics is superior to homogeneous counterparts composed of similar components.¹⁸⁴ Therefore, gradient ceramics are a potential material that can be applied in a wide range of engineering fields, such as nuclear reactions, aerospace, and internal combustion engines.¹⁸⁵ B₄C and SiC are the preferred materials for producing gradient ceramics owing to their excellent properties. Zhang et al.¹⁸⁶ successfully prepared B₄C-SiC gradient ceramics with six layers structure. The composition of the prepared B₄C-SiC gradient ceramics exhibits obvious gradient characteristics, the interface between adjacent layers is well combined and there are no cracks at the interface, resulting from the good physical and chemical compatibility between B4C and SiC as well as their little difference in thermal expansion coefficients. Meanwhile, the mechanical properties of B4C-SiC gradient ceramics show the characteristics of gradient transition along the thickness direction of gradient layers. Especially, the B₄C-SiC gradient ceramics have excellent thermal shock resistance, which is ascribed to the tight bonding between different layers and the unique multi-layer gradient structure. Microcracks can be generated at the interface layer under the action of the shear stress between the gradient layers, which is caused by the different thermal expansion coefficients between layers due to the different composition ratios of each layer. When the main cracks formed during the thermal shock pass through the interface layer, these cracks can be passivated by the microcracks at the interface. The B₄C-SiC gradient ceramics can decrease the damage by enhancing thermal conductivity, thermal shock resistance, and brittleness under the condition of temperature gradients. Therefore, the B₄C-SiC ceramics in the form of composition gradient distribution have better effects on some properties than homogeneous B4C-SiC block ceramics.

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In order to improve the fracture toughness of ceramics, a laminated bionic design can be applied. Generally, there are two toughening mechanisms of laminated ceramics based on the bonding strength of the interface between the layers. One is the residual compressive stress owing to the thermal mismatch at the strong interface, and the other is the delamination and deflection of cracks at the weak interface. Sun et al.¹⁴¹ prepared a kind of laminated B₄C-SiC ceramics by tape casting. Compared with the fracture toughness of the block B₄C-SiC ceramics, the laminated B₄C-SiC ceramics possess higher fracture toughness, which is attributed to the strong interface bond between the layers resulting from the residual compressive stress in the laminated ceramics; also, the laminated B₄C-SiC ceramics have bending strength than the block B₄C-SiC ceramics. Therefore, the layered structure design can improve the mechanical properties of B₄C-SiC ceramics.

5.4.2. Porous ceramics. Porous ceramics are a kind of material with open pores and high open porosity. It is suitable for precise filtration and separation of various media; thus, it is often prepared as ceramic membranes. Compared with traditional porous ceramic membrane supports, membrane supports composed of SiC–B₄C porous ceramics can exhibit better corrosion resistance in hot acidic and alkaline solutions.¹⁸⁷ Also, SiC–B₄C porous ceramics, which is attributed to the microstructure of interpenetrated networks formed by large plate-like SiC grains interpenetrating with equiaxed SiC grains in the SiC–B₄C porous ceramics, SiC–B₄C porous ceramics, are a new form of SiC–B₄C composites.

5.4.3. Ceramic hollow microspheres. The ceramic hollow microspheres are an important engineering material, which can be applied as fillers in composites, ignition targets for inertial confinement fusion, and catalyst supports.¹⁸⁸ In particular, inertial confinement fusion is a sustainable, clean energy and is considered as an effective solution to energy crisis. The ignition target, a vital component for inertial confinement fusion, needs to meet many strict requirements in term of material, surface roughness, and sphericity.^{189,190} Due to their high melting point, high thermal conductivity, and excellent thermal stability, B4C and SiC are estimated as the ignition target materials for inertial confinement fusion.¹⁹¹ Yan et al.¹⁹² used a combination of slurry-coating and precursor conversion methods to prepare B4C-SiC hollow microspheres with a smooth surface and high crush load. The obtained B₄C-SiC hollow microspheres possess a diameter of 1.6-1.9 mm and a wall thickness of 10–60 μ m; the B₄C-SiC hollow microspheres have a high sphericity of 99.6%. Compared with pure B_4C hollow microspheres prepared by the CVD method, whose wall thickness can hardly reach 20 µm, the B4C-SiC hollow microspheres obtained through a combination of slurry-coating and precursor conversion method exhibit higher wall thickness. B4C-SiC ceramics with other complex shapes can also be produced by this method.

5.5. Exploration of new material of ternary systems or quaternary systems based on B₄C-SiC binary ceramics

 B_4C -SiC binary ceramics exhibit better sinterability and mechanical properties than pure B_4C and SiC ceramics. Recently, the performance of ternary or quaternary systems based on B₄C–SiC binary ceramics has attracted much attention, such as B₄C–SiC–TiB₂,^{193–205} B₄C–SiC–CrB₂,²⁰⁶ B₄C–SiC–NbB₂,²⁰⁷ B₄C–SiC–MoB₂,²⁰⁸ B₄C–SiC–HfB₂,^{209,210} B₄C–SiC–ZrB₂,^{211,212} B₄C–SiC–WC,²¹³ B₄C–SiC–Al₂O₃,²¹⁴ B₄C–SiC–rGO,²¹⁵ B₄C–SiC–carbon nanotubes,²¹⁶ B₄C–SiC–carbon fiber,²¹⁷ B₄C–SiC–Si,^{218,219} B₄C–SiC–Mo,²²⁰ B₄C–SiC–Al,^{221–223} B₄C–SiC–Al₂O₃–MgB₂,²²⁴ and B₄C–SiC–Si–TiB₂.²²⁵ The demand for B₄C–SiC with good performance promotes further exploration of new materials of ternary or quaternary systems with improved properties based on B₄C–SiC binary ceramics.

5.6. Study on the combination of mechanical properties and tribological properties

As a novel ceramic material with low friction and low wear, B_4C -SiC ceramics exhibit satisfactory tribological properties under both unlubricated and water-lubricated sliding conditions.^{226–232} However, the tribological properties of the solid-state sintered B_4C -SiC ceramics under high load need to be further improved due to the relatively low fracture toughness.²³³ Therefore, how to improve the tribological properties of B_4C -SiC ceramics under harsh conditions by controlling their mechanical properties remains to be further studied.

6. Conclusions

B₄C-SiC composite ceramics are a very promising alternative to pure B₄C ceramics and pure SiC ceramics. B₄C-SiC ceramics exhibit a combination of the desirable performance of B4C and SiC. The mechanical properties of B₄C-SiC ceramics are determined by a number of factors, as mentioned in this review. Some values of mechanical properties of B4C-SiC ceramics reported in the literature vary considerably, and some research conclusions are not uniform so far. The measurement of mechanical properties is strongly dependent on the measuring method, instrument, and operator. The comparison of mechanical properties reported in different literature studies can only be regarded as a reference, even for the B4C-SiC ceramics prepared by the same preparation process. Design and exploration of novel advanced ceramic materials for high-performance applications are important to accelerate the development of modern material engineering. B4C-SiC ceramics are a potentially promising material for a variety of applications. This review is of practical significance for the promotion and application of B4C-SiC ceramics.

Conflicts of interest

There are no conflicts to declare.

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